

[www.mne2019.org](http://www.mne2019.org)



# MNE 2019

# 45<sup>th</sup> International Conference on Micro & Nano Engineering

# GOING NANO IN HOMER'S LAND

- # Advanced Patterning Nanofabrication for functionality Nanodevices-MEMS Lab-on-a-chip

# 23-26 September 2019

# RODOS PALACE HOTEL

Rhodes  
**Greece**

- ει- Ανδρα μοι ένωσε μάσσα πολύτρο τον δέ μάλι  
πολλά πλευρή, έπειτα Τροινίσαρόν πολλά σον λημποτάκ  
πολλάδιν διαθέραπων θεραπεύεις πολλά  
πολλάδιν διαθέραπων θεραπεύεις πολλά

Τον άντρα, Μάσα, τον παλιότερο τραγουδέα μας, που πάρα  
διάβημα τόπους είχε πάντας της Τραύες το κέστοιο το δύνα-  
και παθητικό πολλάς εγγένειας, πολλών βουλής ανθρώπων  
κι αριστούργητα ψαράνια που έζησε στην πατέρα της η μαρτυρία

- 5 Αόρνυκ  
άλι οὐδεί  
απέδων γέ  
νήματα, ε  
ήσθιαν  
10 τῶν ἀπό<sup>τ</sup>  
της ἀλο<sup>τ</sup>  
ακαι δασαν



αναγνωρίζει την αυτός πολύτιμοις και θεώρει του  
τοπίοντας την άμεση δέσμην της γενικότερης στρατηγικής της  
πολιτικής της χρήσης των πόλεων της στην περιοχή.  
Επίσημη παραγγελία της Επιτροπής της Κομισιόν  
επέδειξε την απόφαση της για την επένδυση στην περιοχή  
την προτεραιότητά της στην ανάπτυξη της οικονομίας της  
περιοχής. Η προτεραιότητα της Επιτροπής της Κομισιόν  
επέδειξε την απόφαση της για την επένδυση στην περιοχή  
την προτεραιότητά της στην ανάπτυξη της οικονομίας της

# **FINAL PROGRAM**



## Evolving in the 70TH YEAR

70 years since our founding in 1949.

Starting with the development of the electron microscope,  
we at JEOL have continued to create unrivaled, world-leading technology.

Based on this core technology, we have developed a variety of scientific and  
metrology instruments, as well as industrial and medical equipments.



In 2019, the phrase adopted as a new key concept for guiding company is  
“Evolving in the 70th Year”. Based on the spirit of our founding philosophy, "Creativity"  
and "Research and Development", we will continue to pursue  
world-leading technology.



# **45<sup>th</sup>** International Conference on **Micro & Nano Engineering**

# Table of Contents

Welcome Address	<b>4</b>
Committees	<b>5</b>
General Information	<b>9</b>
Instructions to Presenters and Chairpersons	<b>14</b>
Plenary Speakers	<b>15</b>
Invited Speakers	<b>18</b>
Rodos Palace Floor Plan	<b>19</b>
Program at a Glance	<b>20</b>
Scientific Program (Oral presentations)	<b>23</b>
Monday 23 - 09 - 2019	<b>24</b>
Tuesday 24 - 09 - 2019	<b>25</b>
Wednesday 25 - 09 - 2019	<b>35</b>
Thursday 26 - 09 - 2019	<b>45</b>
Scientific Program (Poster Presentations)	<b>55</b>
Exhibition and Poster Area Plan	<b>86</b>
Exhibitors' List	<b>86</b>
Exhibitors - Sponsors	<b>87</b>
Authors' Index	<b>90</b>



# Welcome Address

We welcome you to the Micro and Nano Engineering (MNE) 2019 and in Rhodes, Greece! It will be the 45<sup>th</sup> Conference in a series that started in Cambridge in 1975, and was held most recently in Vienna (2016), Braga (2017) and Copenhagen (2018). MNE is the core international conference focusing on: a) micro/nanofabrication and manufacturing techniques, and b) application of the fabricated micro/nanostructures, devices and microsystems into electronics, photonics, energy, environment, chemistry and the life sciences.

This year we have chosen a 3-day conference format that includes 4 parallel sessions A, B, C, D, corresponding to the 4 thematic areas of MNE2019: One parallel session (A) is dedicated to Nanopatterning, a second (B) is dedicated to Nanofabrication and Functional Nanostructured Surfaces, a third (C) is focusing on Nanoelectronic and other devices, Sensors, and Microsystems, and a forth (D) is focusing on Lab on a Chip with applications in Life Sciences, Chemistry, Food and Environmental safety.

The program features 10 outstanding Plenary talks including two presentations from the Award Winning MNE2019 fellow and Young Investigator, 13 presentations from world-leading Invited speakers, oral and poster presentations (evaluated by an exceptional International Program Committee), an ancient Greek Music artist and scholar, and a Nanotechnology artist. More specifically, the conference program comprises 174 oral and 367 poster presentations (including the plenary and invited presentations). The distribution among the MNE thematic areas reflects the main interests of our community and the long-term evolution of the field. The thematic area Advanced Nanopatterning represents 21% of all submissions, Nanofabrication for functionality 23%, Nanodevices-MEMS and applications 34%, and Nanofabrication for life science applications 22%.

MNE poster papers have equal weight to oral presentations. The MNE Committees encourage authors to submit papers (regular, accelerated publications, reviews or news and opinions) to 4 open thematically focused issues of Microelectronic Engineering (MEE by Elsevier) related to the conference topics.

The conference includes several awards, including the MNE fellow and the Young Investigator Award (Thursday morning), the micrograph contest, and the best poster awards per topic to be presented during the Gala dinner.

In addition, MNE 2019 offers exciting Tutorials on the fundamentals of Wetting, Nanogenerators, and Innovation Management, designed for scientists, professionals, company engineers, entrepreneurs and graduate students.

Finally, MNE 2019 hosts 34 exhibitors and is grateful to numerous sponsors which we sincerely acknowledge as the conference is made possible through their strong support. Returning to Greece after 11 years, the conference takes place in a majestic island, Rhodes, one of the most popular destinations in Greece, with long multicultural history and rich natural environment. We have implemented a rich social program including welcome reception, visit and Homer singing performance in the Knights Palace on Monday, Beach Party on Tuesday, Gala dinner on Wednesday featuring art and nanotechnology, and Excursion to Lindos on Thursday.

We warmly thank the numerous authors, delegates, exhibitors and sponsors, program and session chairs, members of the international program committee, guest editors for the Microelectronic Engineering special issues, our students and staff participating, for promising to make this conference a memorable event.

We hope that you will enjoy the conference and have some time to spend with friends and enjoy yourself. We want to thank all of you for coming, and express our thanks and appreciation for the many exhibitors and sponsors that have helped make all this happen.

Καλώς ήλθατε!

On behalf of the MNE2019 Organizing Committee

**Evangelos Gogolides**  
Conference Chair

**Angeliki Tserepi**  
Program Chair

**MNE 2019 LOCAL ORGANIZING COMMITTEE**

**Evangelos Gogolides**  
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**Angeliki Tserepi**  
*Program Chair*

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**Lithography / Etching**

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**Nikos Kehagias**  
**George Kokkoris**

**Nanofabrication**

**Eleni Makarona**  
**Nikos Papanikolaou**  
**Vasilis Vamvakas**  
**Kosmas Ellinas**

**Nanodevices / MEMS**

**Panagiotis Dimitrakis**  
**Nikos Glezos**  
**Pascal Normand**  
**Christos Tsamis**  
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**Life Sciences Devices**

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**Kostas Misiakos**  
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# 45<sup>th</sup> International Conference on Micro & Nano Engineering

23-26 September 2019  
Rhodes, Greece

## Committees

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## CONFERENCE INFORMATION

MNE 2019 is organized around 4 main topics. Topic A (Advanced Nanopatterning (lithography & etching), Topic B (Nanofabrication / Manufacturing for Functional Structures / Surfaces), Topic C (Micro-Nano Devices and Systems (MEMS/NEMS) for physical applications, electronics, photonics and energy), and topic D (Micro & Nano Devices and Systems for Life Sciences, Chemistry, and Agrofood Sectors).

MNE 2019 has attracted approximately 700 participants. The MNE Committees encourage authors to submit papers (regular, accelerated publications, reviews or news and opinions) to 4 open thematically focused issues of Microelectronic Engineering (MEE by Elsevier) related to the conference topics. MEE also sponsors the annual Young Investigator Award, which will be presented at the conference. MNE has two related conferences (EIPBN) in the USA, and (MNC) in Japan.

## STRUCTURE

The MNE scientific program begins on Tuesday, September 24<sup>th</sup>, and ends in the afternoon of September 26<sup>th</sup>.

Prior to the Scientific Program, on Monday, September 23<sup>rd</sup>, there will be three Tutorials for those registered, followed by the Welcome Reception and Opening of the Conference and Exhibition, as well as a visit to the Old Town of Rhodes.

The Program features 4 parallel sessions, plenary talks, invited presentations, oral and poster presentations (evaluated by the International Program Committee), and a commercial exhibition. MNE poster papers have equal weight to oral presentations. Two Poster sessions (I, II) will be held respectively on the 24<sup>th</sup> and the 25<sup>th</sup> of September.

## CONFERENCE VENUE

### RODOS PALACE HOTEL

Iraklidon Avenue (Trianton), Ixia,  
 85100 Rhodes, Greece,  
 T: +30 22410 97222  
[www.rodos-palace.gr](http://www.rodos-palace.gr)

## REGISTRATION & HOSPITALITY DESK - OPENING HOURS

The Registration and the Hospitality Desk will be open the following hours:

Monday, 23 <sup>rd</sup> September 2019	12:00 - 17:00
Tuesday, 24 <sup>th</sup> September 2019	08:00 - 19:00
Wednesday, 25 <sup>th</sup> September 2019	08:00 - 18:00
Thursday, 26 <sup>th</sup> September 2019	08:00 - 18:00



# Conference Information

## ON SITE REGISTRATION FEES

Standard Attendees	€ 850
Student Attendees	€ 500
1 day registration *	€ 450
Accompanying persons	€ 285
Cost of 1 Tutorial	€ 100
Cost of 2 Tutorials	€ 150

## Registration Fees Include

- deer Admission to all technical sessions, poster exhibition and industry exhibition
- deer Conference Material
- deer Lunch breaks during the conference
- deer Coffee breaks during the conference
- deer Welcome reception
- deer Conference dinner

\* 1 Day pass does not include Conference Dinner

Accompanying person's registration fee includes all social events  
(Welcome reception, Conference dinner and Excursion to Lindos)

## EXHIBITION

The MNE2019 Commercial Exhibition will commence on Monday, September 23<sup>rd</sup>, and will be open throughout all Conference days. The Commercial exhibition runs throughout the foyer of Jupiter Hall, Salon De Roses Hall and also the Atrium Lobby. The list of companies can be found in page 87.

Detailed information about the companies can be found on the mne2019 conference website by clicking on the logo of each company.

The list of companies can be found in page <https://www.mne2019.org/confirmed-exhibitors>

Detailed information about the companies can be found on the mne2019 conference website by clicking on the logo of each company.

## MICROGRAPH CONTEST

A micrograph contest is organized by the MNE Organizing Committee. Winners will be awarded During the gala dinner. Participants are kindly asked to submit their micrograph until Wednesday at the following web page <https://www.zyvexlabs.com/contests/2019-3/>. You can vote for the best micrograph using the mobile application. The awards are sponsored by the Micro&Nano Society of Greece (<http://micro-nano.gr/>)

## POSTER PRESENTATIONS

There are two poster sessions on Tuesday 24<sup>th</sup> and Wednesday 25<sup>th</sup>.

Each poster will be displayed during the whole conference from Tuesday 24<sup>th</sup> until morning of Thursday 26<sup>th</sup>.

The posters are grouped according to the thematic areas A, B, C, and D in the program. Each poster board will have a poster identification number. Please leave them on display and do not block them in order to provide a means for orientation for visitors of the poster session.

Posters will be placed on the panels with double sided tape to be supplied by the Congress Secretariat.

It is the Presenter's obligation to put up and also remove the poster from the panel. Posters left after the end of the congress will be destroyed. The Congress Secretariat bares no responsibility for posters left behind.

## POSTER SESSION I Even Numbers

Please be at your Poster area, ready for a presentation on Tuesday, September 24<sup>th</sup>, 14:15 - 16:15

## POSTER SESSION II Odd numbers

Please be at your Poster area, ready for a presentation on Wednesday, September 25<sup>th</sup>, 14:15 - 16:15

## BEST POSTER AWARDS

The MNE conference gives much weight and importance to the poster session. Contributions selected for poster presentation do not have less scientific quality than contributions selected for oral presentation, but their contents are expected to be more suitable for communication in poster form. To highlight the importance of the poster session, awards are given to the best posters.

The posters will be evaluated per topic and four Best Poster Awards will be given out, one for each topic:

- Advanced Nanopatterning,
- Nanofabrication for functionality,
- Nanodevices - MEMS and their applications, and
- Lab-on-a-chip /Nanofabrication for life science applications.

The evaluation will be based on the assessment of the abstract reviewers and by the poster examination from the jury during the conference.

Winner announcement: The Best Poster Award Winners will be announced during the conference dinner on September 25<sup>th</sup>. Poster Awards are sponsored by Raith.

## REHEARSAL AND PRESENTATION LOADING ROOM / TECHNICAL SECRETARIAT / SPEAKER'S READY ROOM

All speakers are advised to rehearse their presentations prior to presenting them so as to avoid technical difficulties. A Speaker's Ready room will be available for you opposite to the Congress Secretariat, equipped with all necessary audiovisual aids. You are advised to present your material to the Technical Secretariat at least 2 hours prior to your presentation.

## PUBLICATION OF THE MNE2019 SPECIAL ISSUES

The MNE2019 Organizing Committee invites MNE2019 participants to submit papers to four (4) OPEN to all and FOCUSED THEMATICALLY special issues of Micro and Nano Engineering Journal (Gold open access mirror journal of Microelectronic Engineering, Elsevier) entitled:

- Nanopatterning 2019
- Nanofabrication 2019
- Devices-MEMS 2019
- Lab-on-Chip 2019

Please refer to the specific special issue to see the thematic areas and select the issue appropriate for you. Each special issue call is an 'open call'. This means that, while including selected papers presented at MNE2019, it is also open to other authors of the related scientific community.



# Conference Information

**Manuscript submission deadline:** October 21<sup>st</sup> 2019

Your paper and associated supplementary information should comprise a complete, novel and full description of your work. Manuscripts of the special issue will be submitted and reviewed via the online Elsevier Editorial System (EES). At submission, you are presented with a choice between the MEE and MNE journals. You will then receive a confirmation letter on the choice you have made. You will also have a chance to change your choice at revision. To be part of MNE2019 special issues you need to choose MNE journal. Articles will then be processed and published with the standard Elsevier publishing timeline for each individual manuscript following acceptance. Accepted papers will be freely available on ScienceDirect as OPEN ACCESS papers WITHOUT any article processing charges. This is a SPECIAL agreement between MNE2019 conference and MNE journal.

If you choose MEE instead of MNE journal at submission, your manuscript will be treated as a regular paper and will no longer be part of MNE special Issues, although it will still be handled by the same guest editors with the same procedure. Accepted papers in MEE will be published under subscription model only.

## SOCIAL EVENTS PROGRAM

### WELCOME RECEPTION

The Conference Welcome Reception will take place on Monday, September 23<sup>rd</sup>, at 16:30 throughout all Exhibition Halls.

### WELCOME VISIT TO THE OLD TOWN

Following the Welcome Reception, a Welcome visit to the Old Town of Rhodes and to the Knight's Palace, is a must. Within this medieval town you will be impressed by the Cultural welcome event: *The sound of Homer's singing*.

### BEACH PARTY ON TUESDAY, SEPTEMBER 24<sup>th</sup>

The Organizing Committee will host a Beach Party on the Beach area in front of Rodos Palace.

Please contact the Congress Secretariat for further information.

### GALA DINNER ON WEDNESDAY, SEPTEMBER 25<sup>th</sup>

The Conference Official Gala Dinner will be hosted at the SUPER DOME POOL BAR in Rodos Palace Hotel on Wednesday, September 25<sup>th</sup>, at 19:30.  
Dress: informal

### EXCURSION TO LINDOS ON THURSDAY, SEPTEMBER 26<sup>th</sup>

The buses will depart right after the end of the Scientific Program just outside the Reception Area of Rodos Palace Hotel.

Lindos is an archaeological site, a fishing village and a former municipality on the island of Rhodes. It lies on the east coast of the island. It is about 50 km south of the town of Rhodes and its fine beaches make it a popular tourist and holiday destination. Lindos is situated in a large bay and faces the fishing village and small resort of Charaki. Be fast to be able to see the sunset at Lindos. Please declare your participation in the event at the registration desk in order to arrange for the number of buses.

## OFFICIAL LANGUAGE

English will be the official language of the Conference and no simultaneous translation will be provided.

## CERTIFICATE OF ATTENDANCE

Certificates will be provided after the completion of the Scientific Program.

## BADGE

Please wear your name badge at all times. Entrance to the Conference area will only be permitted to guests wearing their name badge.

## CURRENCY

Greece's monetary unit is the Euro. No other currency is accepted and it is best to exchange dollars or other currency at a bank. The exchange rates are all the same throughout the country and you exchange money at a bank or official exchange shop where you will get the best running rates. Banks are open from 08:00 AM until 2:00 PM.

## INSURANCE

We cannot accept responsibility for any personal loss, accidents or damages to participants and/or accompanying persons. Participants are strongly advised to obtain personal insurance to cover any eventuality that may occur during the Congress.

## TRANSPORTATION

Rhodes is only a 40min flight from Athens International Airport. Rhodes International Airport, "Diagoras", is located, 15 km away (20min by taxi from the town center and the convention center. Public transportation is very well organized with frequent bus service. There are regular international flights as well as charter flights from most major cities worldwide.

## WEATHER

Rhodes in September is still very pleasant and warm, although the temperatures are starting to cool down a bit. The average daily temperature is 25°C. September enjoys an average of 11 hours of sunshine per day.

## PASSPORTS - VISAS

You will need valid, up-to-date passport and a Schengen visa, depending on your nationality. Regarding Schengen visa requirements, please visit the website of the Hellenic Ministry of Foreign Affairs at the following link: <https://www.mfa.gr/en/visas/visas-for-foreignerstraveling-togreece/countries-requiring-or-notrequiring-visa.html> in order to find out whether you need a Schengen visa to visit Greece.

## CONFERENCE SECRETARIAT



Valestra 2 Str., kallithea, Athens Greece  
 T: +30 210 3250260, F: +30 2310 247746  
 E: [info@globalevents.gr](mailto:info@globalevents.gr), W: [www.globalevents.gr](http://www.globalevents.gr)

## OPENING HOURS SPEAKERS' PREVIEW CENTER

Monday, 23 <sup>rd</sup> September 2019	12:00 - 18:30
Tuesday, 24 <sup>th</sup> September 2019	08:00 - 19:00
Wednesday, 25 <sup>th</sup> September 2019	08:00 - 19:00
Thursday, 26 <sup>th</sup> September 2019	08:00 - 17:00

## IF YOU ARE A CHAIRPERSON

Please locate your session room in due time. Please be at your session room at least 15 minutes prior to the start of the session.

We may remind you that speakers need to strictly observe the time schedule. Before the session starts, please check that all presenters are present. Before each presentation, please introduce the presenter by stating his/her name and affiliation.

## INSTRUCTIONS FOR ORAL PRESENTATIONS

Plenary speakers have 35 minutes plus 5-10 minutes of questions

Invited speakers have 25 minutes plus 5 minutes of questions

Contributed talks have 15 minutes. This includes approximately 2-3 min for questions. Therefore, time your presentation to 12-13 minutes.

**Please prepare your presentation with aspect ratio 16:9.**

Computers ARE AVAILABLE at the conference rooms, with the following technical characteristics:

### Hardware:

Processor: i3 or i5 4gen or 8gen, RAM 4-8 GB, Hard Disk: SSD 240GB TFT 15"-17" PC Remote Control

MAC: Retina, early 2015, i5 2,7GHz, RAM 8GBF or those having a Macintosh, a technician will help you to connect and use your laptop.

### Software:

Windows 10, Office 365

Bring your presentation in a memory stick. You do NOT need to bring a laptop. If you do, you should go in the conference room and with the help of the technician see how to connect your laptop. Try it the previous day if possible.

### Rehearsal and presentation loading room:

You are advised to try your presentation and load it with the help of the technicians in the computer room located at the Convention Pre Function Area of the Rodos Palace Hotel. Presentations should be loaded until the previous session, or as early as possible. Please allow enough time before your session, especially if you have videos in your presentation.

## INSTRUCTIONS FOR POSTER PRESENTATIONS

Recommended Poster Size is 120 cm high x 80 cm wide. (The poster board is 200 cm x 95 cm).

Posters will be hanged using double sided tapes, to be supplied by the Congress Secretariat.

**Even Poster Numbers:** Poster Session time: Tuesday September 24<sup>th</sup> at 14:15 - 16:15

**Odd Poster Numbers:** Poster Session time: Wednesday September 25<sup>th</sup> at 14:15 - 16:15

**Set up time:** Monday 23/09 from 16:00 to 18:30 or Tuesday September 25<sup>th</sup>, from 08:30 to 13:00

**Take down time:** Thursday 26/9 from 12:00 until 16:00

Be in front of your poster session on the appropriate day based on your poster number shown in the conference program.

\*Posters left on the poster boards after the take down time, will be removed by the conference personnel.

# Plenary Speakers

TUESDAY, 24<sup>TH</sup> SEPTEMBER 2019

08:45-09:30 **Jupiter Hall**



**Yan Borodovsky**

*Former Intel Senior Fellow, USA*

Moore's Law - Past, Present and Future

TUESDAY, 24<sup>TH</sup> SEPTEMBER 2019

09:30- 10:15 **Jupiter Hall**



**Dimos Poulikakos**

*Head of Energy Science Center (ESC), ETH Zurich,  
 Institut für Energietechnik, Switzerland*

How to arrest and transport biological nano-objects  
 one at a time: Nanovalving of individual Viruses and  
 Macromolecules in liquids

TUESDAY, 24<sup>TH</sup> SEPTEMBER 2019

16:15- 17:00 **Jupiter Hall**



**Shoji Takeuchi**

*Tokyo University, Japan*

Emerging Technologies for Biohybrid Devices

TUESDAY, 24<sup>TH</sup> SEPTEMBER 2019

17:00- 17:45 **Jupiter Hall**



**Fotis Filippopoulos**

*Curious Inc. and International Hellenic Univ., Greece*

Innovation Mindset: The top 10 critical insights every  
 technology entrepreneur should know



# Plenary Speakers

WEDNESDAY, 25<sup>TH</sup> SEPTEMBER 2019

08:45- 09:30 **Jupiter Hall**



**Emmanuel Delamarche**

*IBM Research Zurich, Switzerland*

Intelligent and precise flow control for next-generation microfluidic POC diagnostics

WEDNESDAY, 25<sup>TH</sup> SEPTEMBER 2019

09:30- 10:15 **Jupiter Hall**



**Michal Lipson**

*Eugene Higgins Professor,  
Columbia University, USA*

The Revolution of Silicon Photonics

WEDNESDAY, 25<sup>TH</sup> SEPTEMBER 2019

16:15- 17:00 **Jupiter Hall**



**Zhong Lin Wang**

*Hightower Chair, Georgia Tech, USA*

Nanogenerators for self-powered systems and sensors

# Plenary Speakers

THURSDAY, 26<sup>TH</sup> SEPTEMBER 2019

08:45- 09:30 **Jupiter Hall**



## MNE Fellow 2019

**Hella-Christin Scheer**

*University of Wuppertal, Germany*

More than nanoimprint - replication and combination

THURSDAY, 26<sup>TH</sup> SEPTEMBER 2019

09:30- 10:00 **Jupiter Hall**



## The MNE/MEE Elsevier Journal Young Investigator Award 2019

**Yuksel Temiz**

*IBM Research-Zurich*

The Young Investigator Award is sponsored by Elsevier for the Journals MNE (open access) and MEE (subscription journal)

THURSDAY, 26<sup>TH</sup> SEPTEMBER 2019

16:35- 17:20 **Jupiter Hall**



## George Malliaras

*Prince Philip Professor of Technology,  
University of Cambridge, UK*

New Materials and Devices for Interfacing with the Brain

## Invited Speakers



**Monday, 23<sup>rd</sup> September 2019**

**Chrēstos Terzēs**, *Ancient Music Artist*  
Reconstructing the sound of Homeric singing (Cultural welcome event to be presented at the Knight's palace)



**Tuesday, 24<sup>th</sup> September 2019**

10:45- 11:15, Jupiter Hall

**Thomas Anthopoulos**, *King Abdullah University of Science and Technology (KAUST) and KAUST Solar Centre, Saudi Arabia*

Flexible nano-electronics via large-area manufacturing paradigms



**Tuesday, 24<sup>th</sup> September 2019**

11:15- 11:45, Athena Hall

**Nicolas Voelcker**, *Monash University, Melbourne Center for Nanofabrication, Australia*

Nanomedicine with Silicon Nanostructures



**Tuesday, 24<sup>th</sup> September 2019**

13:00- 13:30, Delphi Hall

**Alidad Amirfazli**, *York University, Canada*

What can and cannot be done with Superhydrophobic, or Omniprophobic surfaces?



**Tuesday, 24<sup>th</sup> September 2019**

13:30- 14:00, Nefeli Hall

**Michal Danek**, *Lam Research Corporation, USA*

Applications of Atomic Layer Deposition (ALD) and Atomic Layer Etch (ALE) in Advanced Semiconductor Manufacturing



**Tuesday, 24<sup>th</sup> September 2019**

18:00- 18:30, Jupiter Hall

**Zheng Cui**, *Suzhou Institute of Nanotechnology, Chinese Academy of Sciences, China*

Printed flexible electronics for wearable applications Semiconductor Manufacturing



**Wednesday, 25<sup>th</sup> September 2019**

10:45- 11:15, Delphi Hall

**Constantine Megaridis**, *University of Illinois, Chicago, United States*

Wettability-Patterned Surfaces for Pumpless Handling of Fluid Microvolumes: Lab-on-Chip and Heat Transfer Applications



**Wednesday, 25<sup>th</sup> September 2019**

11:30- 12:00, Nefeli Hall

**Maria Farsari**, *Foundation for Research & Technology Hellas, Greece*

Laser-based 3D printing at the nanoscale



**Wednesday, 25<sup>th</sup> September 2019**

11:30- 12:00, Athena Hall

**Thomas Laurell**, *Lund University, Sweden*

Acoustofluidics - A sound approach to liquid biopsies



**Wednesday, 25<sup>th</sup> September 2019**

13:00- 13:30, Delphi Hall

**Tekla Tammelin**, *VTT Technical Research Center, Finland*

Patterned Structures and Nanolaminates Hybrid Architectures from Plant-sourced Nanocellulose for Optoelectronics



**Wednesday, 25<sup>th</sup> September 2019**

13:30- 14:00, Athena Hall

**José Antonio Plaza**, *Instituto de Microelectrónica de Barcelona-CNM, Spain*

From Cells-on-Chip to Chips-in-Cell: our fantastic "voyage"



**Wednesday, 25<sup>th</sup> September 2019**

14:00

*Nanotechnology Artist*

" - Sky am": mythologies & methodologies of a nanoartist (to be presented during the conference dinner)



**Thursday, 26<sup>th</sup> September 2019**

10:30- 11:00, Jupiter Hall

**Thomas Ernst**, *CEA-LETI, Grenoble, France*

Merging Computing and Sensing for Low power and Sustainable Edge Applications



**Thursday, 26<sup>th</sup> September 2019**

11:00- 11:30, Delphi Hall

**Martin Lopez**, *International Iberian Nanotechnology Laboratory-INL, Portugal*

Biomimetics of photosynthetic photonic structures. How natural light harvesting could become an inspiration for nanotechnology



**Thursday, 26<sup>th</sup> September 2019**

11:15- 11:45, Athena Hall

**Sungook Park**, *Louisiana State University, USA*

Design and Fabrication of Plastic Nanofluidic Devices for Single Molecule Detection



**Thursday, 26<sup>th</sup> September 2019**

12:45- 13:15, Nefeli Hall

**John Maltabes**, *Applied Materials, Germany*

The path to Roll to Roll Imprint Technology, an Enabling Technology

# Rodos Palace Floor Plan



Scale Ratio 1:333



# Program at a Glance

Monday, September 23<sup>rd</sup>, 2019

NEFELI  
HALL A

09:00-10:30	Tutorial 1 Nanogenerators <i>Zhong Lin Wang</i>	Tutorial 2 Fundamentals of Wetting, Droplets and related Applications <i>Ali/dad Amirfazli</i>	Coffee break	10:45-12:30	Nanogenerators <i>Zhong Lin Wang</i>	Fundamentals of Wetting, Droplets and related Applications <i>Ali/dad Amirfazli</i>	Light Lunch	12:30-13:00	13:00-13:45	Innovation Management Masterclass <i>Fotis Filippopoulos</i>	13:45-14:00	14:00-16:00	16:00-16:15	Registration	16:30-18:15	18:00-19:00	18:30-18:45	19:00-19:30	19:30-20:30	20:45-21:30	22:00					
10:30-10:45	Opening of Conference & Exhibition Welcome Reception	Plenary 1 Moore's Law - Past, Present and Future <i>Yan Borodovsky</i>	How to arrest and transport biological nano-objects one at a time: Nanovalving of individual Viruses and Macromolecules in liquids <i>Dimos Poulikakos</i>	10:45-12:00	EUV and Talbot Lithography	Nanostructured Surfaces	Coffee break	12:00-13:00	Session A1: Etching	Session B1: Nanostructured Surfaces	Session C1: Sensors & Actuators I	Session D1: Nanomedicine & Drug delivery	Lunch break	Session A2: Etching	Session B2: Wetting I	Session C2: Sensors & Actuators II	Session D2: Biosensors I	Poster Session I (Even Numbers)	Plenary 3 Emerging Technologies for Biohybrid Devices <i>Takeuchi Shoji</i>	Key-note on Innovation Mindset: the top 10 critical insights every technology entrepreneur should know <i>Fotis Filippopoulos</i>	Short Break	Opening of Conference & Exhibition Welcome Reception	Transport to the Old City	Visit at the Knights Palace	Cultural Event: The sound of Homeric Singing	Transport back to the Conference Venue
12:30-13:00	Coffee break	14:15-16:15	16:15-17:00	17:00-17:45	17:45-18:00	18:00-19:00	18:30-18:45	19:00-19:30	19:30-20:30	20:45-21:30	22:00															

# Program at a Glance

## Wednesday, September 25<sup>th</sup>, 2019

	NEFELI HALL	JUPITER HALL	ATHENA HALL	
08:30				
08:45-09:30	Plenary 4 Intelligent and precise flow control for next-generation microfluidic POC diagnostics <i>Emmanuel Delamarche</i>			
09:30-10:15	Plenary 5 The Revolution of Silicon Photonics <i>Michael Lipson</i>	Coffee break		
10:15-10:45	Session A4: EUV and Talbot Lithography	Session B4: Wetting II	Session C4: Physical Sensors	Session D4: Lab-on-a chip Technologies
12:00-12:15				Lunch break
12:15-12:30				
12:30-12:45				
12:45-13:00				
13:00-14:15	Session A5: Industrial	Session B5: Industrial	Session C5: Energy harvesting Devices	Session D5: Cells & Organ-on-chip II
14:15-16:15				POSTER SESSION II (ODD NUMBERS)
16:15-17:00	Plenary 6 Nanogenerators for self-powered systems and sensors <i>Wang, Zhong Lin</i>			
17:00-18:15	Session A6: NIL & Novel Lithographies	Session B6: Nanofab for Bioapplications	Session C6: Photonic Structures	Session D6: Industrial
18:15-19:30				
19:30-22:00			Gala dinner	

## Thursday, September 26<sup>th</sup>, 2019

	NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
08:30				
08:45-09:30	Plenary 7 MNE Fellow Award & Lecture <i>Hella-Christin Scheer</i>			
09:30-10:15	Young Investigator Award Invited Lecture <i>Yuksel/Temiz / Award Ceremony</i>	Coffee break		
10:15-10:45	Session A7: Electron and Ion Beam Lithography	Nanostructures for Photonics	Session B7: Nanostructures for Photonics	Session C7: Materials & Devices for nanoelectronics
12:00-13:00	Session A8: Industrial I	Session B8: Wetting III	Session C8: Materials for Nanoelectronics II	Session D7: Micro & Nano Fluidics
13:00-14:00				
14:00-14:15			Coffee break	Session D8: Devices for DNA studies
14:15-15:15	Session A9: Industrial II	Nanofabrication	Session C9: Materials for photonics	Session D9: Lab & Organ on-chip
15:15-15:30				Short break
15:30-16:30	Session A10: Resists	Microfabrication	Session C10: Sensors & MEMS	Session D10: Chem. Sensors & Biosensors II
16:30-16:35				Short break
16:35-17:20				
17:20-17:30			New Materials and Devices for Interfacing with the Brain <i>George Malliaras</i>	
17:30-21:00			Announcements & Closing Remarks	Excursion to Lindos





# Scientific Program

**Note:**

Papers are listed by Topic and by session.  
Short abstracts are available on the mobile  
application of the conference.

45<sup>th</sup> International Conference on  
**MNE** 2019



# Micro & Nano Engineering

23-26 September 2019 Rhodes, Greece

45<sup>th</sup> International Conference on

MONDAY SEPTEMBER 23<sup>RD</sup>, 2019

## Scientific Program

NEFELI HALL A		NEFELI HALL B	
09:00-10:30	<b>Tutorial 1</b> <b>Nanogenerators</b> Zhong Lin Wang Georgia Tech	<b>Tutorial 2</b> <b>Fundamentals of Wetting, Droplets and related Applications</b> Alidad Amirfazli York University	
10:30-10:45		COFFEE BREAK	
10:45-12:15	<b>Tutorial 1</b> <b>Nanogenerators</b> Zhong Lin Wang Georgia Tech	<b>Tutorial 2</b> <b>Fundamentals of Wetting, Droplets and related Applications</b> Alidad Amirfazli York University	
12:15-12:45		LIGHT LUNCH	
13:00-13:45		<b>Tutorial 3</b> <b>Innovation Management Masterclass</b> Fotis Filippopoulos Curious Inc. and International Hellenic Univ., Greece	
13:45-14:00		COFFEE BREAK	
14:00-16:00		<b>Tutorial 3</b> <b>Innovation Management Masterclass</b> Fotis Filippopoulos Curious Inc. and International Hellenic Univ., Greece	
16:30-18:15		OPENING OF CONFERENCE AND EXHIBITION	WELCOME RECEPTION

## TUESDAY SEPTEMBER 24<sup>TH</sup>, 2019

# Scientific Program

JUPITER HALL	
	<b>Opening Session</b> Chairs: V. Constantoudis, U. Staufer
08:45-09:30	<b>Plenary 1</b> <b>Moore's Law - Past, Present and Future</b> Yan Borodovsky <i>Former Intel Senior Fellow, USA</i>
09:30-10:15	<b>Plenary 2</b> <b>How to arrest and transport biological nano-objects one at a time: Nanovalving of individual viruses and Macromolecules in liquids</b> Dimos Poulikakos <i>ETH Zurich, Institut für Energietechnik, Switzerland</i>
10:15-10:45	<b>COFFEE BREAK</b>



# Micro & Nano Engineering

23-26 September 2019 Rhodes, Greece

TUESDAY SEPTEMBER 24<sup>TH</sup>, 2019

## Scientific Program

	NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
10:45	<b>SESSION A1:</b> <b>EUV AND TALBOT LITHOGRAPHY</b> Chairs: J. Randal, C. Mack	<b>SESSION B1:</b> <b>NANOSTRUCTURED SURFACES</b> Chairs: E. Makarona, G. lordache	<b>SESSION C1:</b> <b>SENSORS &amp; ACTUATORS I</b> Chairs: Z. Cui, I. Raptis	<b>SESSION D1:</b> <b>NANOMEDICINE &amp; DRUG DELIVERY</b> Chairs: A. Gerardino, JA Plaza
11:00	<b>A1-2</b> <b>Fundamental Research Activities of Extreme Ultraviolet Lithography at NewSUBARU Synchrotron facility</b> Takeo Watanabe <sup>1</sup> , Tetsuo Harada <sup>1</sup> <sup>1</sup> University of Hyogo, Akou-gun, Japan	<b>B1-1</b> <b>Extreme ultraviolet interference lithography for in-lab photore sist development and large-area nanopatterning</b> Sascha Brose <sup>1,2</sup> , Serhiy Danylyuk <sup>1,2</sup> , Christian Kaiser <sup>3</sup> , Maik Germgrob <sup>3</sup> , Jochen Stollenwerk <sup>1,2,4</sup> , Peter Loosen <sup>1,2,4</sup> , Matthias Schimme <sup>5</sup> , Peter Loosen <sup>1,2,4</sup> , RWTH Aachen University Aachen, Germany, JARA - Fundamentals of Future Information Technology, Jülich, Germany, <sup>4</sup> Fraunhofer Institute for Laser Technology, Aachen, Germany	<b>C1-1_INV</b> <b>UV-sensor made by capillary filling metal inks on prepatterned substrates</b> Helmut Schiff <sup>1</sup> , Ethouba Al Jassim-Al Hashemil <sup>2</sup> , Barbara Horváth <sup>1</sup> , Sami Bolat <sup>3</sup> , Paul Scherrer Institut (psi), Villigen Psi, Switzerland, <sup>2</sup> University of Basel, Basel, Switzerland, <sup>3</sup> Swiss Federal Laboratories for Materials Science and Technology (EMPA), Dübendorf, Switzerland	<b>D1-1</b> <b>Ultrasound-triggered PLGA-microplates degradation for on-command drug delivery</b> Elisa Sciuitti <sup>1,2</sup> , Rosita Primavera <sup>3</sup> , Martina Di Francesco <sup>3</sup> , Daniele Di Mascolo <sup>3</sup> , Alessandro Rizzo <sup>1,2</sup> , Antonio Balena <sup>2</sup> , Sanosh Kunjilakkal Padmanabhan <sup>2</sup> , Francesco Rizzi <sup>1</sup> , Paolo Decuzzi <sup>3</sup> , Massimo De Vittorio <sup>1,2</sup> <sup>1</sup> Center for Bio-Molecular Nanotechnologies, Istituto Italiano di Tecnologia, Arnesano, Italy, <sup>2</sup> Dipartimento di Ingegneria dell'Innovazione, Università del Salento, Lecce, Italy, <sup>3</sup> Laboratory of Nanotechnology for Precision Medicine, Istituto Italiano di Tecnologia, Genova, Italy
			<b>B1-2</b> <b>Direct Nanoimprinting of Colloidal Self-Organizing Nanowire/particule inks for Flexible, Transparent Electrodes</b> Lukas F. Engel <sup>1</sup> , Johannes H. M. Maurer <sup>1</sup> , Thomas Kister <sup>1</sup> , Lola González-García <sup>1</sup> , Tobias Kraus <sup>1,2</sup> <sup>1</sup> INM - Leibniz Institute for New Materials, Saarbrücken, Germany, <sup>2</sup> Colloid and Interface Chemistry, Saarland University, Saarbrücken, Germany	<b>D1-2</b> <b>Tumour spheroids formed in a caged space for drug and microfluidic based assays</b> Yong He <sup>1</sup> , Boxin Huang <sup>1</sup> , Elrade Rofaani <sup>1</sup> , Jie Hu <sup>1</sup> , Yuanhui Liu <sup>1</sup> , Gabriele Pitingolo <sup>1</sup> , Li Wang <sup>2</sup> , Jian Shi <sup>2</sup> , Carole Aimé <sup>1</sup> , Yong Chen <sup>1</sup> <sup>1</sup> École Normale Supérieure-PSL Research Univ Paris 06, CNRS UMR 8640 PASTEUR, Paris, France, <sup>2</sup> MesoBioTech, Paris, France

11:15	<b>A1-3</b> <b>Large-area resistless patterning on hydrogen-terminated Si using EUV lithography</b> Li-Ting Tseng <sup>1</sup> , Dimitrios Kazazis <sup>1</sup> , Prokopios Constantinou <sup>2</sup> , Taylor Stock <sup>3</sup> , Neil Curson <sup>3</sup> , Steven Schofield <sup>2</sup> , Gabriel Aepli <sup>1,4,5</sup> , Yasin Ekinç <sup>1</sup> <sup>1</sup> Paul Scherrer Institut, Villigen, Switzerland <sup>2</sup> Department of Physics and Astronomy, University College London, London, United Kingdom, <sup>3</sup> London Centre for Nanotechnology, University College London, London, United Kingdom, <sup>4</sup> EPFL, Lausanne, Switzerland, <sup>5</sup> ETH Zurich, Zurich, Switzerland	<b>B1-3</b> <b>Graphene on functional polymers - evaluation of stress and doping, and applications</b> Manuel Müller <sup>1</sup> , Rukan Nasri <sup>1,2</sup> , Fereshta Hafizi <sup>1</sup> , Jon Polensky <sup>1</sup> , Carmen Herrmann <sup>2</sup> , Mirko Lohse <sup>3</sup> , Manuel Thesen <sup>3</sup> , Gabi Grützner <sup>3</sup> , Irene Fernandez-Cuesta <sup>1</sup> University Of Hamburg, Institute for nanostructure and solidstate physics, Hamburg, Germany, <sup>2</sup> University of Hamburg, Department of Chemistry, Hamburg, Germany, <sup>3</sup> micro resist technology GmbH, Berlin, Germany	<b>C1-2</b> <b>Optimized magnet configurations for Lorentz actuation of a µ-Coriolis mass flow sensor</b> Thomas Schut <sup>1</sup> , Yannick Klein <sup>1</sup> , Remco Wiegerink <sup>1</sup> , Han Gardieniers <sup>1</sup> , Joost Löters <sup>1,2</sup> <sup>1</sup> University Of Twente, Enschede, Netherlands, <sup>2</sup> Bronckhorst High-tech BV, Ruurlo, Netherlands	<b>D1-3</b> <b>Fabrication and ex vivo retention study of biodegradable microcon- tainers for oral drug delivery</b> Zarmeena Abid <sup>1,2</sup> , Mette Mosgaard <sup>1,3</sup> , Giorgio Manfroni <sup>1,2</sup> , Ritika Singh <sup>1</sup> , Petersen <sup>1,2</sup> , Line Hagner Nielsen <sup>1,3</sup> , Anette Müllertz <sup>1,4</sup> , Anja Boisen <sup>1,3</sup> , Stephan Sylvest Keller <sup>1,2</sup> <sup>1</sup> The Danish National Research Foundation and Villum Foundation's Center for Intelligent Drug Delivery and Sensing Using Microcon- tainers and Nanomechanics (IDUN), Kgs. Lyngby, Denmark, <sup>2</sup> National Centre for Nano- fabrication and Characterization DTU Nanolab, Technical University of Denmark, Kgs. Lyngby, Denmark, <sup>3</sup> Department of Health Technology DTU Health Tech, Technical Uni- versity of Denmark, Kgs. Lyngby, Denmark, <sup>4</sup> Department of Pharmacy, Faculty of Health and Medical Sciences, University of Copen- hagen, 2100 Copenhagen, Denmark
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# 45<sup>th</sup> International Micro & Nano Engineering Conference on

23-26 September 2019 Rhodes, Greece

TUESDAY SEPTEMBER 24<sup>TH</sup>, 2019

## Scientific Program

<p>11:30</p> <p><b>A1-4 Simulation and nanofabrication of complex EUV achromatic Talbot lithography masks for high-resolution and high-throughput patterning</b> Dimitrios Kazazis<sup>1</sup>, Li-Ting Tseng<sup>1</sup>, Yasin Ekinci<sup>1</sup> <sup>1</sup>Paul Scherrer Institute, Villigen-PSI, Switzerland</p>	<p><b>B1-4 Fabrication of A Low-Noise Interchangeable Platform for Nanostructured Transport Measurements in Fluidic, Cryogenic, and In Situ Electron Microscopy Environments</b> Sanaz Rastgoo<sup>1</sup>, Randy Fechner<sup>1</sup>, Mirko Kötzl<sup>1</sup>, Manfred Kohl<sup>1</sup> <sup>1</sup>Karlsruhe Institute Of Technology (kit) / Institute Of Microstructure Technology (imt), Eggenstein-Leopoldshafen, Germany</p>	<p><b>C1-3 Optical Waveguide Based on a Co-Integrated SMA Biomorph Actuator</b> A. Mol<sup>1,3</sup> <sup>1</sup>University of Oxford, Oxford, United Kingdom, <sup>2</sup>Oak Ridge National Laboratory, Oak Ridge, United States, <sup>3</sup>Queen Mary University of London, London, United Kingdom</p>	<p><b>D1-4_INV Nanomedicine with Silicon Nano-structures</b> Nicolas Voelcker, Beatriz Prieto-Simo <sup>1</sup>Monash University, Melbourne Center for Nanofabrication, Australia</p>
<p>11:45</p> <p><b>A1-5 Displacement Talbot Lithography – an emerging technology for rapid nanopatterning on 8-inch scale</b> Konstantins Jefimovs<sup>1,2</sup>, Matias Kagijs<sup>1,2</sup>, Joan Vila-Comamala<sup>1,2</sup>, Zhitian Shi<sup>1,2</sup>, Christian Dais<sup>3</sup>, Harun Solak<sup>3</sup>, Lucia Romano<sup>1,2,4</sup>, Sijia Xie<sup>1</sup>, Helmut Schift<sup>1</sup>, Marco Stampaconi<sup>1,2</sup> <sup>1</sup>Paul Scherrer Institut, Villigen, Switzerland, <sup>2</sup>Institute for Biomedical Engineering, University and ETH Zürich, Zürich, Switzerland, <sup>3</sup>Eulitha AG, Kirchdorf, Switzerland, <sup>4</sup>Department of Physics and CNR-IMM- University of Catania, Catania, Italy</p>	<p><b>B1-5 Stable fabrication of anti-reflection with nano-structure for high-temperature application</b> Kazuma Kurihara<sup>1</sup>, Ryohei Hokai<sup>1</sup>, Kouji Miyake<sup>1</sup> <sup>1</sup>National Institute of Advanced Industrial Science and Technology (AIST), Tsukuba, Japan</p>	<p><b>C1-4 An optomechanical resonator with a plasmonic half bull's eye antenna and an aperture for wavelength detection</b> Reo Kometani<sup>1</sup>, Kodata Tanaka<sup>2</sup>, Shin'ichi Warisawa<sup>1</sup> <sup>1</sup>The University Of Tokyo, Chiba, Japan, <sup>2</sup>The University Of Tokyo, Tokyo, Japan</p>	<p><b>LUNCH BREAK</b></p>

12:00-13:00

	NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
	<b>SESSION A2: ETCHING</b> Chairs: J.A. Liddle, E. Gogolides	<b>SESSION B2: WETTING I</b> Chairs: K. Megaridis, K. Ellinas	<b>SESSION C2: SENSORS &amp; ACTUATORS II</b> Chairs: R. Komietani, J. Gaspar	<b>SESSION D2: BIOSENSORS I</b> Chairs: S. Chatzandroulis, H. Brueckl
13:00	<b>A2-1</b> <b>Etch challenges on Single and Dual SOI fins patterning for CFET at 25nm fin pitch</b> BT Chan, Juergen Boemmel, Julien Ryckaert, Liping Zhang, Zheng Tao, Altamirano Sanchez, Jean-Francois de Marneffe Imec, Leuven, Belgium	<b>B2-1_INV</b> <b>What can and cannot be done with Suphydrophobic, or Omniphipobic surfaces?</b> Alidad Amirfazli York University, Canada	<b>C2-1</b> <b>Micro fabricated electron optical systems</b> C.T.H. Heerkens, M.A.R. Krielaart, Ir. P. Kruit <i>TU Delft faculty of applied sciences, Delft, Netherlands</i>	<b>D2-1</b> <b>Application of junctionless nanowire transistors as ultrasensitive biosensors</b> Yordan M. Georgiev <sup>1,2</sup> , Nikolay Petkov <sup>3</sup> , Ran Yu <sup>3</sup> , Adrian M. Nightingale <sup>4</sup> , Elizabeth Buitrago <sup>5</sup> , Olan Lotvy <sup>3</sup> , John C. deMello <sup>4</sup> , Adrian M. Ionescu <sup>5</sup> , Justin D. Holmes <sup>3</sup> <sup>1</sup> Institute of Ion Beam Physics And Materials Research, Helmholtz-Centrum Dresden-Rossendorf (HZDR), Dresden, Germany, <sup>2</sup> Institute of Electronics at the Bulgarian Academy of Sciences, Sofia, Bulgaria, <sup>3</sup> Materials Chemistry & Analysis Group, School of Chemistry and Tyndall National Institute, University College Cork, Cork, Ireland, <sup>4</sup> Imperial College London, United Kingdom, <sup>5</sup> Nanoelectronic Devices Laboratory (NanoLab), École Polytechnique Fédérale de Lausanne (EPFL), Lausanne, Switzerland
13:15			<b>C2-2</b> <b>Silicon-based Micro Oscillating Heat Pipes for High Energy Physics and Space Applications</b> Timothée Frei <sup>[2,3]</sup> , Diego Alvarez Feito <sup>[1]</sup> , Grégoire Bourban <sup>[3]</sup> , Andrea Catinaccio <sup>[1]</sup> , Michel Despont <sup>[2]</sup> , Volker Gass <sup>[3]</sup> , Arno Hoogerwerf <sup>[2]</sup> , Elisa Laudi <sup>[1]</sup> , Alessandro Mapelli <sup>[1]</sup> <sup>[1]CERN, Genève, Switzerland, <sup>[2]CSEM, Neuchâtel, Switzerland, <sup>[3]EPFL, Lausanne, Switzerland</sup></sup></sup>	<b>D2-2</b> <b>Nanoplasmonic mid-IR biosensors for ultrasensitive molecular spectroscopy</b> Aurelian John-Herpin, Andreas Tittl, Maria Soier, Hatice Altug Ecole Polytechnique Federale de Lausanne, Lausanne, Switzerland



# Micro & Nano Engineering

23-26 September 2019 Rhodes, Greece

TUESDAY SEPTEMBER 24<sup>TH</sup>, 2019

## Scientific Program

<b>A2-3_INV</b> <b>Applications of Atomic Layer Deposition (ALD) and Atomic Layer Etch (ALE) in Advanced Semiconductor Manufacturing</b>  Michal Danek Lam Research Corporation, USA	<b>B2-2</b> <b>Fabrication of elastic metallic superhydrophobic surfaces</b>  Seyed Mehran Mirmohammadi <sup>1</sup> , Sasha Hoshian <sup>1,2</sup> , Ville P. Jokinen <sup>1</sup> , Sami Franssila <sup>1</sup> <sup>1</sup> Aalto University, Espoo, Finland, <sup>2</sup> Advacam Ltd, Espoo, Finland	<b>C2-3</b> <b>Multi-parameter paper sensor fabricated by inkjet-printed silver nanoparticle and PEDOT:PSS</b>  Dimitris Barmpakos <sup>1,2</sup> , Christos Tsamis <sup>2</sup> , Grigorios Kaitatas <sup>1</sup> <sup>1</sup> microSENSES Laboratory, Department of Electrical and Electronic Engineering, University of West Attica, <sup>2</sup> Institute of Nanoscience and Nanotechnology, National Centre for Scientific Research "Demokritos"	<b>D2-3</b> <b>Non-invasive bladder cancer detection based on localized surface plasmon resonance sensing approach</b>  Zi-Yi Yang <sup>1</sup> , Yi-Chun Chiu <sup>2</sup> , Wen-Huei Chang <sup>3</sup> , Chun-hung Lin <sup>1</sup> <sup>1</sup> National Cheng Kung University, Tainan, Taiwan, <sup>2</sup> Taipei City Hospital, Taipei, Taiwan, <sup>3</sup> National Pingtung University, Pingtung, Taiwan
<b>B2-3</b> <b>Fully Organic and Biodegradable, Cellulose-based, Superhydrophobic Materials</b>  Athanasios Milionis <sup>1</sup> , Chander Shekhar Sharma <sup>1</sup> , Raoul Hopf <sup>1</sup> , Michael Uggowitz <sup>1</sup> , Iker S. Bayer <sup>2</sup> , Dimos Poulikakos <sup>1</sup> <sup>1</sup> ETH Zurich, Zurich, Elβertra, <sup>2</sup> Istituto Italiano di Tecnologia, Genova, Italy	<b>C2-4</b> <b>Spatially controlled 3D origami MEMS actuation using focused electron beam exposure and polymer densification</b>  Robert Kirchner <sup>1</sup> , Sebastian Killge <sup>1</sup> , Karola Richter <sup>1</sup> , Dimitrios Kazazis <sup>2</sup> , Ran Zhang <sup>1</sup> , Johann Wolfgang Barthai <sup>1</sup> <sup>1</sup> ITU Dresden, Dresden, Germany, <sup>2</sup> Paul Scherrer Institute, Villigen PSI, Switzerland	<b>D2-4</b> <b>Silicon-based Monolithic Spectroscopic Circuit for Label-free Point-of-Need Diagnostics</b>  Konstantinos Misiakos <sup>1</sup> , Eleni Makarona <sup>1</sup> , Marcel Hoekman <sup>2</sup> , Romanos Fyrogenis <sup>3</sup> , Kari Tuukkanen <sup>4</sup> , Gerhard Jobst <sup>5</sup> , Panagiota S. Petrou <sup>6</sup> , Sotirios E. Kakabakos <sup>6</sup> , Alexandros Salapatas <sup>1</sup> , Dimitrios Goustouridis <sup>3</sup> , Mikko Harijanne <sup>4</sup> , Paivi Heimala <sup>4</sup> , Andrzej Budkowski <sup>1</sup> , Michele Lees <sup>8</sup> , Ioannis Raptis <sup>1</sup> <sup>1</sup> Institute Of Nanoscience and Nanotechnology, NCSR Demokritos, Athens, Greece, <sup>2</sup> LioniX BV, Enschede, The Netherlands, <sup>3</sup> ThetaMetris S.A., Peristeri, Attiki, Greece, <sup>4</sup> VTT, Espoo, Finland, <sup>5</sup> Jobst Technologies GmbH, Freiburg, Germany, <sup>6</sup> Institute of Nuclear & Radiological Sciences and Technology, Energy & Safety, NCSR Demokritos, Aghia Paraskevi, Attiki, Greece, <sup>7</sup> Jagellonian University, Krakow, Poland, <sup>8</sup> EUROFINS, Nantes, France	<b>D2-5</b> <b>Cost-Effective Three-Dimensional Plasmonic SERS Papers for Rapid Parquat Poisoning Diagnosis with Portable Raman Spectrometer</b>  Yu-Hsuan Chen <sup>1</sup> , Shih-Wei Chang <sup>2</sup> , Aileen Y. Sun <sup>1</sup> , Hsuen-Li Chen <sup>2</sup> , Dehui Wan <sup>1</sup> <sup>1</sup> National Tsing Hua University, Hsinchu, Taiwan, <sup>2</sup> National Taiwan University, Taipei, Taiwan
<b>A2-4</b> <b>Self-limiting Atomic Layer Etching of SiO<sub>2</sub> using Low Temperature Cyclic Ar/CHF<sub>3</sub> Plasma</b>  Stefano Cabrini <sup>1</sup> , Stefano Dallorto <sup>1,2,3</sup> , Andy Goodyear <sup>2</sup> , Mike Cooke <sup>2</sup> , Scott Dhuey <sup>1</sup> , Julia Szornel <sup>1</sup> , Adam Schwartzberg <sup>1</sup> , Ivo Rangelow <sup>3</sup> <sup>1</sup> Lawrence Berkeley National Laboratory, Berkeley, United States, <sup>2</sup> Oxford Instruments Plasma Technology, Bristol BS49 4AP, United Kingdom, <sup>3</sup> Ilmenau University of Technology, Ilmenau D-98684, Germany	<b>B2-4</b> <b>Fabrication and Characterization of Anti-Fogging Surfaces Tempered from Block-Copolymer Self-Assembly</b>  Nikolai Kofoed Mandsberg <sup>1</sup> , Agnieszka Telecka <sup>2</sup> , Emil Ludvigsen <sup>2</sup> , Rafael Taboryski <sup>2</sup> <sup>1</sup> DTU Health Tech, Kongens Lyngby, Denmark, <sup>2</sup> DTU Nanolab, Kongens Lyngby, Denmark	<b>C2-5</b> <b>Fabrication and characterization of SMA thick film actuator array for high power tactile display</b>  Jiale Xu <sup>1</sup> , Yusuke Kimura <sup>1</sup> , Kazuki Tsuji <sup>1</sup> , Konomu Abe <sup>2</sup> , Tomomi Shimizu <sup>2</sup> , Hiroyasu Hasegawa <sup>2</sup> , Takashi Mineta <sup>1</sup> <sup>1</sup> Yamagata University, Yonezawa, Japan, <sup>2</sup> Tohoku Rika CO. LTD, Niwa, Japan	

## TUESDAY SEPTEMBER 24<sup>TH</sup>, 2019

# Scientific Program

14:15-16:15	<b>POSTER SESSION I (Even Numbers)</b>
	<b>JUPITER HALL</b>
	Chairs: J. Gaspar, N. Kehagias
16:15-17:00	<b>Plenary 3 Emerging Technologies for Biohybrid Devices</b> Shoiji Takeuchi <i>Tokyo University, Japan</i>
17:00-17:45	<b>Keynote Lecture on Innovation Innovation Mindset: the top 10 critical insights every technology entrepreneur should know</b> Fotis Filippopoulos <i>Curious Inc. and International Hellenic Univ., Greece</i>
17:45-18:00	<b>SHORT BREAK</b>



# 45<sup>th</sup> International Micro & Nano Engineering Conference on

23-26 September 2019 Rhodes, Greece

TUESDAY SEPTEMBER 24<sup>TH</sup>, 2019

## Scientific Program

NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
<b>SESSION A3: MODELING &amp; METROLOGY</b> Chairs: D. Maas, A. Vekinis	<b>SESSION B3: NANOFABRICATION &amp; NODEVICES</b> Chairs: T. Ernst, N. Vainos	<b>SESSION C3: FLEXIBLE &amp; WEARABLES</b> Chairs: J.-W. Choi, E. Makarona	<b>SESSION D3: CELL &amp; ORGAN -ON-CHIP I</b> Chairs: S. Fransila, M. Kitsara
<b>A3-1</b> <b>Deep Learning Nanometrology of Line Edge Roughness</b> Eva Giannatou <sup>3,5</sup> , Vassilos Constantoudis <sup>1,5</sup> , George Papaveros <sup>1,4,5</sup> , Evangelos Gogolides <sup>1,5</sup> , Harris Papageorgiou <sup>3</sup> , Gian Lorusso <sup>2</sup> , V. Rutigliani <sup>2</sup> , F. Van Roey <sup>2</sup> , Institute of Nanoscience and Nanotechnology (INN), N.C.S.R. Demokritos, Agia Paraskevi, Greece, <sup>2</sup> IMEC, Leuven, Belgium, <sup>3</sup> Institute for Language and Speech Processing (ILSP), Athena R.C., Maroussi, Greece, <sup>4</sup> Physics Department, Aristotle University of Thessaloniki, Thessaloniki, Greece, <sup>5</sup> Nanometris P.C., Agia Paraskevi, Greece	<b>B3-1</b> <b>Super-resolution fabrication of surface relief structures by contractive scaling of nanoporous monoliths</b> A. Papademetriou, Nikolaos Vainos, K. Papachristopoulou, V. Karoutsos University Of Patras, Dept Materials Science, Patras, Greece	<b>C3-1_INV</b> <b>Printed flexible electronics for wearable applications</b> Zheng Cui Suzhou Institute of Nanotechnology, Chinese Academy of Sciences, China	<b>D3-1</b> <b>A method for the multiple direct imaging by TEM, AFM, and SERs of ion channels on plasma membranes suspended on super-hydrophobic surfaces</b> Manola Moretti <sup>1</sup> , Tania Limongi <sup>2</sup> , Maria Teresa De Angelis <sup>3</sup> , Elvira I. Parrotta <sup>3</sup> , Gianluca Santamaria <sup>3</sup> , Marco Alione <sup>1</sup> , Sergei Lopatin <sup>4</sup> , Bruno Torre <sup>1</sup> , Peng Zhang <sup>1</sup> , Andrea Giugni <sup>1</sup> , Monica Marin <sup>2</sup> , Angelica Bigo <sup>5</sup> , Patrizio Candeloro <sup>6</sup> , Giovanni Cuda <sup>3</sup> , Enzo Di Fabrizio <sup>1</sup> <sup>1</sup> King Abdullah University of Science and Technology, SMILES Lab, Jeddah, Saudi Arabia, <sup>2</sup> Dipartimento di Scienze Applicate e Tecnologia, Politecnico di Torino, Torino, Italy, <sup>3</sup> Laboratory of Stem Cell Biology, Department of Experimental and Clinical Medicine, <sup>4</sup> King Abdullah University of Science and Technology, Imaging and Characterization Core lab, Thuwal-Jeddah, Saudi Arabia, <sup>5</sup> Dipartimento di Scienze AgroAlimentari, Ambientali e Animali, Università di Udine, Udine, Italy, <sup>6</sup> BIONEM lab, Department of Experimental and Clinical Medicine, University Magna Graecia, Catanzaro, Italy

<p><b>A3-2</b> <b>Modelling the Resolution Limits of Scanning Electron Microscope Roughness Metrology</b></p> <p>Chris Mack Fractilia, LLC, Austin, United States</p>	<p><b>B3-2</b> <b>Sub-15 nm multilayer nanopillar patterning for hybrid SET/cmos integration</b></p> <p>Marie-Line Pourteau<sup>1</sup>, Ahmed Gharbi<sup>1</sup>, Pierre Brianceau<sup>1</sup>, Jacques-Alexandre Dallery<sup>2</sup>, Fabien Laulagnet<sup>1</sup>, Guido Rademaker<sup>1</sup>, Raluca Tiron<sup>1</sup>, Johannes von Borany<sup>3</sup>, Karl-Heinz Heinig<sup>3</sup>, Hans-Juergen Engelmann<sup>3</sup>, Matthias Rommel<sup>4</sup>, Leander Baier<sup>4</sup>, Wilfried Lerch<sup>5</sup>, Jürgen Niess<sup>5</sup>  <sup>1</sup>CEA-LETI, F-38054 Grenoble, France, <sup>2</sup>Vistecon Electron Beam GmbH, D-07743 Jena, Germany, <sup>3</sup>Heimholtz-Zentrum Dresden-Rossendorf, D-01328 Dresden, Germany, <sup>4</sup>Fraunhofer IISB, D-91058 Erlangen, Germany, <sup>5</sup>HQ Dielectrics GmbH, D-89160 Dornstadt, Germany</p>	<p><b>D3-2</b> <b>Microwave radars in unlabelled, non-destructive Cell detection</b></p> <p>Arda Secme<sup>1</sup>, Dilara Uslu<sup>1</sup>, Tufer Erdogan<sup>1</sup>, Hadi Sedaghat Pisheh<sup>1</sup>, M. Selim Hanay<sup>1,2</sup>  <sup>1</sup>Department of Mechanical Engineering, Bilkent University, ANKARA, Turkey, <sup>2</sup>National Nanotechnology Research Center (NNAM), Bilkent University, ANKARA, Turkey</p>
<p><b>A3-3</b> <b>A Validation of UV Imprint Process Simulation using a Thermo-visco-elastic Constitutive Model</b></p> <p>Ryunosuke Yamashita<sup>1</sup>, Yuki Onishi<sup>1</sup>, Kenji Amaya<sup>1</sup>, Yoshihiko Hirai<sup>2</sup>  <sup>1</sup>Tokyo Institute Of Technology, Tokyo, Japan, <sup>2</sup>Osaka Prefecture University, Osaka, Japan</p>	<p><b>B3-3</b> <b>Time-efficient fabrication of Sierpiński-fractal bow-tie nanostructures with a focused helium ion beam and their spectral characterization</b></p> <p>Florian Läible, Lisa Seitl, Simon Dickreuter, Dieter P. Kern, Monika Fleischer  <sup>1</sup>University of Tübingen Institute for Applied Physics, Tübingen, Germany</p>	<p><b>C3-3</b> <b>Extracellular matrix protein micro-patterning technology for whole-cell cryogenic electron microscopy studies</b></p> <p>Leeyea Engel<sup>1</sup>, Guido Gaeitta<sup>2</sup>, Liam P. Dow<sup>1,3</sup>, Mark F. Swift<sup>2</sup>, Gaspard Pardon<sup>1</sup>, Niels Volkmann<sup>2</sup>, William I. Weis<sup>4</sup>, Dorit Hanein<sup>2</sup>, Beth L. Pruitt<sup>1,3</sup>  <sup>1</sup>Department of Bioengineering, Stanford University, Stanford, USA, <sup>2</sup>Immunity and Pathogenesis Program, Sanford Burnham Prebys Medical Discovery Institute, La Jolla, USA, <sup>3</sup>Departments of Mechanical Engineering and Molecular, Cellular, and Developmental Biology, University of California, Santa Barbara, Santa Barbara, USA, <sup>4</sup>Departments of Structural Biology and Molecular Cellular Physiology, Stanford University School of Medicine, Stanford, USA</p>
<p>18:15</p>	<p>18:30</p>	



# 45<sup>th</sup> International Micro & Nano Engineering Conference on

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## Scientific Program

	NEFEKI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
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18:45	<b>A3-4</b> <b>Modeling, monitoring and future projection of stochastic defects in EUV lithography</b> Hiroshi Fukuda Hitachi High-Technologies Corporation, Tokyo, Japan	<b>B3-4</b> <b>Pathways to laser generated nano patterns for functional surfaces</b> L. Gemini, Rainer Kling, G. Mincuzzi, M. Fauccon Alphanov, Talence, France	<b>C3-3</b> <b>Cell compatibility study of SU-8 microneedles based wearable dry electrodes for electroencephalogram</b> G. Kaklamani <sup>1</sup> , G. Stavrinidis <sup>1</sup> , K. Michelakis <sup>2</sup> , V. Kontomitrou <sup>1</sup> , K. Tsagaraki <sup>1</sup> , N. Korniliou <sup>2</sup> , G. Konstantinidis <sup>1</sup> <sup>1</sup> Microelectronics Research Group, IESL-FORTH, Vassilika Vouton, Heraklion, Greece, <sup>2</sup> Greek Mediterranean University, Estavromenos, Heraklion, Greece, <sup>3</sup> Stewart Blusson Quantum Matter Institute, The University of British Columbia, Vancouver Campus, Vancouver BC, Canada	<b>D3-4</b> <b>Polymer microfluidic chip with integrated thermoformed microcavity array for exposure of 3D cell aggregates to gradients of soluble factors</b> Philipp Maurer, Mireille Stihjns, Jasja King, Timo Rademakers, Pamela Habibovic, Clemens van Blitterswijk, Vanessa LaPointe, Stefan Giselbrecht, Roman Truckenmüller MERLN Institute for Technology-Inspired Regenerative Medicine, Maastricht University, Maastricht, Netherlands

## WEDNESDAY, SEPTEMBER 25<sup>TH</sup>, 2019

# Scientific Program

JUPITER HALL	
	Chairs: E. Gogolides, M de Vittorio
08:45-09:30	<b>Plenary 4</b> <b>Intelligent and precise flow control for next-generation microfluidic POC diagnostics</b> Emmanuel Delamarche IBM Research Zurich, Switzerland
09:30-10:15	<b>Plenary 5</b> <b>The Revolution of Silicon Photonics</b> Michal Lipson Columbia University, USA

10:15-10:45	COFFEE BREAK
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# 45<sup>th</sup> International Micro & Nano Engineering Conference on

23-26 September 2019 Rhodes, Greece

WEDNESDAY, SEPTEMBER 25<sup>TH</sup>, 2019

## Scientific Program

	NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
10:45	<b>SESSION A4: 3D LITHOGRAPHIES</b> Chairs: C. Vieu, A. Olztersky	<b>SESSION B4: WETTING II</b> Chairs: A. Tserepi, A. Millonis	<b>SESSION C4: PHYSICAL SENSORS</b> Chairs: F. Murano, P. Dimitrakis	<b>SESSION D4: LAB-ON A CHIP TECHNOLOGIES</b> Chairs: S. Pang, S. Park
	<b>A4-1</b> <b>Emergent Magnetic Monopoles in a Macroscopically Degenerate 3D Artificial Spin Ice</b> Scott Dhuey <sup>1</sup> , Alan Farhan <sup>2,7</sup> , Charlotte Petersen <sup>3</sup> , Michael Saccone <sup>4</sup> , Noah Kent <sup>4</sup> , Rajesh Choddekar <sup>2</sup> , Yen-Lin Huang <sup>5</sup> , Zuhuang Chen <sup>5</sup> , Mikko J. Alava <sup>3</sup> , Thomas Lippert <sup>7,8</sup> , Andreas Scholl <sup>2</sup> , Sebastiaan van Dijken <sup>6</sup> <sup>1</sup> Molecular Foundry, Lawrence Berkeley National Laboratory, Berkeley, United States, <sup>2</sup> Advanced Light Source, Lawrence Berkeley National Laboratory, Berkeley, United States, <sup>3</sup> COMP Centre of Excellence, Department of Applied Physics, Aalto University, Aalto, Finland, <sup>4</sup> Physics Department, University of California - Santa Cruz, Santa Cruz, USA, <sup>5</sup> Dept of Materials Science and Engineering, University of California - Berkeley, Berkeley, United States, <sup>6</sup> Nanospin, Dept. of Applied Physics, Aalto University, Aalto, Finland, <sup>7</sup> Lab for Multiscale Materials Experiments, Paul Scherrer Institute, Villigen, Switzerland, <sup>8</sup> Dept. of Chemistry and Applied Biosciences, Lab of Inorganic Chemistry, ETH Zurich, Zurich, Switzerland	<b>B4-1_INV</b> <b>Wettability-Patterned Surfaces for Pumpless Handling of Fluid Microvolumes: Lab-on-Chip and Heat Transfer Applications</b> Constantine Megaridis University of Illinois at Chicago	<b>C4-1</b> <b>Suspended intracellular pressure sensor with a reference cavity</b> Maria Isabel Arjona <sup>1,2</sup> , Ana Sanchez <sup>1</sup> , Marta Duch <sup>1</sup> , Rodrigo Gomez-Martinez <sup>1</sup> , Teresa Suarez <sup>3</sup> , Jose Antonio Plaza <sup>1</sup> <sup>1</sup> Instituto De Microelectrónica De Barcelona (IMB-CNM CSIC), Cerdanyola Del Valles (Barcelona), Spain, <sup>2</sup> Departamento de Electrónica y Tecnología de los Computadores, Facultad de Ciencias, Universidad de Granada, Granada, Spain, <sup>3</sup> Centro de Investigaciones Biológicas (CIB) CSIC, Madrid, Spain	<b>D4-1</b> <b>A Novel Micro Free-Flow Electrophoresis 3D printed Lab on a Chip for exosomes separation</b> Federica Barbaresco <sup>1</sup> , Matteo Cocuzzal <sup>2</sup> , Fabrizio Candido Pirri <sup>1</sup> , Simone Luigi Marasso <sup>1,2</sup> <sup>1</sup> PoliTechnico Di Torino, Torino, Italy, <sup>2</sup> CNR-IMEM, Parma, Italy

<p><b>A4-2</b> <b>Fabrication of 3D scaffolds reproducing intestinal epithelium to-stereolithography by high-resolution 3D stereolithography</b></p> <p>Justin Creff<sup>1,2</sup>, Rémi Courson<sup>1</sup>, Thomas Mangeat<sup>2</sup>, Julie Foncy<sup>1</sup>, Sandrine Souleille<sup>1</sup>, Christophe Thibault<sup>1</sup>, Arnaud Besson<sup>2</sup>, Laurent Malagonin<sup>1</sup>  <sup>1</sup>LAAS CNRS, Toulouse, France, <sup>2</sup>LBCMCP, Toulouse, France</p>	<p><b>C4-2</b> <b>Microfabrication of a MEMS acceleration meter with two-thick functional layers</b></p> <p>Inês Sofia Garcia<sup>1</sup>, Eurico E. Moreira<sup>1,2</sup>, Rosana A. Dias<sup>1</sup>, João Gaspar<sup>1</sup>, Filipe S. Alves<sup>1</sup>, Luís Alexandre Rocha<sup>1,2</sup>  <sup>1</sup>INL - International Iberian Nanotechnology Laboratory, Braga, Portugal, <sup>2</sup>CMEMS-UMinho, Guimarães, Portugal</p>	<p><b>D4-2</b> <b>Loading of biodegradable micro-containers with budesonide for local treatment of inflammatory bowel disease</b></p> <p>Zarmeena Abid<sup>1,2</sup>, Francesca Andreoli<sup>1,2</sup>, Maja Nørgaard Kristensen<sup>1,3</sup>, Ritika Singh Petersen<sup>1,2</sup>, Anette Müllertz<sup>1,3</sup>, Anja Boisen<sup>1,4</sup>, Stephan Sylvest Keller<sup>1,2</sup>  <sup>1</sup>The Danish National Research Foundation and Villum Foundation's Center for Intelligent Drug Delivery and Sensing Using Microcontainers and Nanomechanics (IDUN), Kgs. Lyngby, Denmark, <sup>2</sup>National Centre for Nano Fabrication and Characterization, DTU NanoLab, Technical University of Denmark, Kgs. Lyngby, Denmark, <sup>3</sup>Department of Pharmacy, Faculty of Health and Medical Sciences, University of Copenhagen, 2100 Copenhagen, Denmark, <sup>4</sup>Department of Health Tech, Technical University of Denmark, Kgs. Lyngby, Denmark</p>
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# Micro & Nano Engineering

23-26 September 2019 Rhodes, Greece

WEDNESDAY SEPTEMBER 25<sup>TH</sup>, 2019

## Scientific Program

	NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
11:15	<b>SESSION A4: 3D LITHOGRAPHIES</b> Chairs: C. Vieu, A. Olziersky	<b>SESSION B4: WETTING II</b> Chairs: A. Tserepi, A. Milionis	<b>SESSION C4: PHYSICAL SENSORS</b> Chairs: F. Murano, P. Dimitrakis	<b>SESSION D4: LAB-ON A CHIP TECHNOLOGIES</b> Chairs: S. Pang, S. Park
	<b>A4-3</b> <b>Novel and versatile prototyping routes for polymeric hybrid and biconvex micro-optics</b> Johannes Wolf <sup>1</sup> , Susanne Grützner <sup>1</sup> , Margit Ferstl <sup>2</sup> , Marko Vogler <sup>1</sup> , Jan Jasper Klein <sup>1</sup> , Anja Voigt <sup>1</sup> , Manuel Thesen <sup>1</sup> , Aneit Kolander <sup>1</sup> , Markus Guttmann <sup>3</sup> , Madeleine Nuck <sup>2</sup> , Arne Schleunitz <sup>2</sup> , Gabi Grützner <sup>1</sup> <sup>1</sup> Micro resist technology GmbH, Berlin, Germany, <sup>2</sup> Fraunhofer Heinrich Hertz Institute, HHI, Berlin, Germany, <sup>3</sup> Karlsruhe Institute of Technology, Karlsruhe, Germany	<b>B4-2</b> <b>Towards long-lasting underwater superhydrophobicity of micro-nano textured surfaces: Plastron thickness observation using white light reflectance spectroscopy</b> Athanasios Smyrnakis, Dimosthenis Ioannou, Kosmas Ellinas, Aggeliki Tserepi, Evangelos Gogolides Institute of Nanoscience and Nanotechnology, NCSR "Demokritos", Agia Paraskevi, Greece	<b>C4-3</b> <b>Simple fabrication of highly sensitive capacitive pressure sensors using a porous dielectric layer with cone-shaped patterns</b> Yeongjun Kim, Juwon Hwang, Je Hoon Oh Department of Mechanical Engineering, Hanyang University, Ansan, South Korea	<b>D4-3_INV</b> <b>Acoustofluidics - A sound approach to liquid biopsies</b> Thomas Laurell Lund University, Sweden
11:30	<b>A4-4_INV</b> <b>Laser-based 3D printing at the nanoscale</b> Maria Farsari Foundation for Research & Technology Hellas, Greece	<b>B4-3</b> <b>Biomimetic architectures for entrapping air underwater using wetting materials</b> Ratul Das, Sankara Arunachalam, Zain Ahmad, Jamiliya Nauruzbayeva, Himanshu Mishra King Abdullah University of Science and Technology (KAUST), Water Desalination and Reuse Center (WDRC), Thuwal, Saudi Arabia	<b>C4-4</b> <b>The effect of cracked alumina nanoparticle strain sensor</b> Evangelos Aslanidis <sup>1</sup> , Lambros Patsiouras <sup>1</sup> , Evangelos Skotadis <sup>1</sup> , Konstantinos Giannakopoulos <sup>2</sup> , Dimitris Tsoukalias <sup>1</sup> National Technical University of Athens, Athens, Greece, <sup>2</sup> NCSR Demokritos, ATHENS, Greece	<b>D4-4</b> <b>Imprinted nanoparticles with magnetic and plasmon-optical properties for biomolecular diagnostics</b> Astrit Shoshi <sup>1</sup> , Michael J. Haslinger <sup>2</sup> , Tina Mitteramskogler <sup>2</sup> , Michael Mühlberger <sup>2</sup> , Stefan Schrittwieser <sup>3</sup> , Jörg Schötter <sup>3</sup> , Hubert Brückl <sup>1</sup> <sup>1</sup> Department for Integrated Sensor Systems, Danube University Krems, <sup>2</sup> PROFACTOR GmbH, <sup>3</sup> AIT Austrian Institute of Technology
11:45		<b>B4-4</b> <b>Engineering of nanostructured polymer surfaces with enhanced wetting properties</b> Rafał Taboryski, Nikolaj Mandberg, Agnieszka Telecka, Nastasia Okulova, Emil Ludvigsen Technical University of Denmark, Kgs Lyngby, Denmark	<b>C4-5</b> <b>Development of Microscale Magnetic Actuators</b> Jizhai Cui <sup>1,2</sup> , Paolo Testa <sup>1,2</sup> , Anja Weber <sup>1,2</sup> , Laura J. Heyderman <sup>1,2</sup> Laboratory for Mesoscopic Systems, Department of Materials, ETH Zurich, Zurich, Switzerland, <sup>2</sup> Laboratory for Multiscale Materials Experiments, Paul Scherrer Institute, Villigen, Switzerland	

12:00-13:00

LUNCH BREAK

	NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
13.00	<b>SESSION A5: NOVEL PATTERNING APPLICATIONS</b> Chairs: JF de Marneffe, V. Constantoudis	<b>SESSION B5: INDUSTRIAL</b> Chairs: R. Taboryski, A. Milionis	<b>SESSION C5: ENERGY HARVESTING DEVICES</b> Chairs: C. Tsamis, G. Murillo	<b>SESSION D5: CELLS &amp; ORGAN-ON-CHIP II</b> Chairs: R. Luttge, JM. Quero
13.15	<b>A5-1</b> <b>Fabrication of 3D anisotropic dry adhesive microstructures based on 2PP for application in space</b> Jan F. Busche, Gereon Starke, Saskia Knickeier, Andreas Dietze <i>Institute of Microtechnology, TU Braunschweig, Braunschweig, Germany</i>	<b>B5-1_INV</b> <b>Patterned Structures and Nanolaminated Hybrid Architectures from Plant-sourced Nanocellulose for Optoelectronics</b> Tekla Tammelin <i>VTT Technical Research Center, Finland</i>	<b>C5-1</b> <b>Enhanced responsivity of PN junction solar cells through graphene modification layer</b> Bo Feng, Tianyu Wang, Jingyuan Zhu, Yifang Chen <i>Fudan University, Shanghai, China</i>	<b>D5-1</b> <b>Influence of 3D microenvironment on cancer cells growth and invasion</b> Sara Sergio <sup>1,2</sup> , Addolorata Maria Luce Coluccia <sup>2</sup> , Enrico Domenico Lemma <sup>3</sup> , Barbara Spagnolo <sup>1</sup> , Daniele Vergara <sup>2,4</sup> , Michele Maffia <sup>2,4</sup> , Massimo De Vittorio <sup>1,5</sup> , Ferruccio Pisanello <sup>1</sup> <sup>1</sup> Istituto Italiano di Tecnologia, Center for Biomolecular Nanotechnologies, Arnesano, Italy, <sup>2</sup> Dipartimento di Scienze e Tecnologie Biologiche e Ambientali, Università del Salento, Lecce, Italy, <sup>3</sup> Karlsruher Institut für Technologie, Zoologisches Institut, Abteilung Zell- und Neurobiologie, Karlsruhe, Germany, <sup>4</sup> Laboratory of Clinical Proteomic, Giovanni Paolo II Hospital, Lecce, Italy, <sup>5</sup> Dipartimento di Ingegneria dell'Innovazione, Università del Salento, Lecce, Italy
			<b>C5-2</b> <b>Piezoelectric AlN-based fiber-optic devices for sensing and energy harvesting</b> Massimo Mariello <sup>1,2</sup> , Francesco Guido <sup>2</sup> , Luciana Aligeri <sup>3</sup> , Vincenzo Mariano Mastronardi <sup>2</sup> , Francesco Rizzi <sup>2</sup> , Antonio Quatieri <sup>2</sup> , Ferruccio Pisanello <sup>2</sup> , Massimo De Vittorio <sup>1,2</sup> <sup>1</sup> Dipartimento di Ingegneria dell'Innovazione, Università del Salento, Lecce, Italy, <sup>2</sup> Center for Biomolecular Nanotechnologies, Istituto Italiano di Tecnologia, Arnesano, Lecce, Italy, <sup>3</sup> Piezoskin S.r.l., Arnesano, Lecce, Italy	<b>D5-2</b> <b>Biomimetic aligned nanofibrous PVDF scaffolds for cardiac tissue engineering</b> Maria Kitsasari, Chau Le <sup>1</sup> , Alexandre Simon <sup>1</sup> , Onnik Agbulut <sup>1</sup> , Vincent Hublot <sup>2</sup> , Gaëlle Revet <sup>1</sup> , Thierry Dufour <sup>3</sup> <sup>1</sup> Sorbonne Université, Institut de Biologie Paris-Séine, Paris, France, <sup>2</sup> Sorbonne Université, Laboratoire de Réactivité de Surface UMR CNRS, Paris, France, <sup>3</sup> Sorbonne Université, Laboratoire de Physique des Plasmas, UMR CNRS, Paris, France



# Micro & Nano Engineering

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## Scientific Program

NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
<b>SESSION A5: NOVEL PATTERNING APPLICATIONS</b> Chairs: JF de Marnette, V. Constantoudis	<b>SESSION B5: INDUSTRIAL</b> Chairs: R. Taboryski, A. Milionis	<b>SESSION C5: ENERGY HARVESTING DEVICES</b> Chairs: C. Tsamis, G. Murillo	<b>SESSION D5: CELLS &amp; ORGAN-ON-CHIP II</b> Chairs: R. Luttge, JM. Quero
<b>A5-3</b> <b>Protein Amyloid Fibrils Formation and Growth in Droplet with Confined Convection Flow on Super-hydrophobic Surface</b> Peng Zhang <sup>1</sup> , Manola Moretti <sup>2</sup> , Marco Allione <sup>1</sup> , Javier Ordonezloza <sup>2</sup> , Mani Sarathy <sup>2</sup> , Enzo Di Fabrizio <sup>1</sup> <sup>1</sup> SMILES Lab, Physical Science and Engineering (PSE) and Biological and Environmental Science and Engineering (BESE) Divisions, King Abdullah University Of Science And Technology, Thuwal, Saudi Arabia, <sup>2</sup> Clean Combustion Research Center, Physical Science and Engineering (PSE) Division, King Abdullah University of Science and Technology, Thuwal, Saudi Arabia	<b>B5-2</b> <b>Directed Assembly-based Printing of Nano and Microscale Electronics and Sensors</b> Ahmed Busnaina <sup>1</sup> <sup>1</sup> Northeastern University, Boston, United States	<b>C5-3</b> <b>Metal Oxide Interlayers for High Performance Inverted Perovskite Solar Cells</b> Stelios Choulias <sup>1</sup> <sup>1</sup> Cyprus University of Technology, Limassol, Cyprus	<b>D5-3_INV</b> <b>From Cells-on-Chip to Chips-in-Cell: our fantastic “voyage”</b> Plaza, José Antonio <sup>1</sup> <sup>1</sup> Instituto de Microelectrónica de Barcelona-CNM, Spain
<b>A5-4</b> <b>A fully integrated tapered fiber optrode for simultaneous multi-point optical control and electrical readout of neural activity</b> Antonio Balenà <sup>1,2</sup> , Alessandro Rizzo <sup>1</sup> , Leonardo Sileo <sup>1</sup> , Barbara Spagnolo <sup>1</sup> , Filippo Pisano <sup>1</sup> , Marco Pisanello <sup>1</sup> , Francesco De Nuccio <sup>3</sup> , Domenico Lofrumento <sup>3</sup> , Enrico Domenico Lemma <sup>1,2</sup> , Bernardo Luis Sabatini <sup>4</sup> , Massimo De Vittorio <sup>1,2</sup> , Ferruccio Pisanello <sup>1</sup> <sup>1</sup> Istituto Italiano Di Tecnologia, Center For Biomolecular Nanotechnologies, Arnesano, Italy, <sup>2</sup> Department of Innovation Engineering, University and Neuroscience, Department of Biological and Environmental Technologies and Sciences, Università del Salento, Lecce, Italy, <sup>3</sup> Department of Neurobiology, Howard Hughes Medical Institute, Harvard Medical School, Boston, Italy	<b>B5-3</b> <b>Proto-MIP - A Novel Route for MIP Fabrication</b> Sandra Haas, Leo Schranzhofer, Brittany Roberts <sup>1</sup> ProFactor, Steyr-Gleink, Austria	<b>C5-4</b> <b>Fabrication of electrospun polyimide nanofibers and their application in triboelectric nanogenerators</b> Yeongjun Kim, Xinwei Wu, Je Hoon Oh <sup>1</sup> Department of Mechanical Engineering, Hanyang University, Ansan, South Korea	

## WEDNESDAY SEPTEMBER 25<sup>TH</sup>, 2019

# Scientific Program

14:00	<b>A5-5</b> <b>Grayscale e-beam lithography for the fabrication of 3D microfluidic devices</b> Thomas Mortelmans <sup>1,2,3</sup> , Dimitrios Kazazis <sup>1</sup> , Vitaliy A. Guzenko <sup>1</sup> , Celestino Padeste <sup>1</sup> , Xiaodan Li <sup>1</sup> , Thomas Braun <sup>2</sup> , Henning Stahlberg <sup>2</sup> , Yasin Ekinci <sup>1</sup> , Paul Scherrer Institute, 5232 Villigen, Switzerland, <sup>2</sup> Center for Cellular Imaging and NanoAnalytics (C-CINA), 4058 Basel, Switzerland, <sup>3</sup> Swiss Nanoscience Institute, 4056 Basel, Switzerland	<b>B5-4</b> <b>Antireflective Moth-Eyes Structures on Freeform Surfaces fabricated by Nanoimprint Lithography</b> Michael J. Haslinger, Anniya Ranjan Moharana, Daniel Fechtig, Michael Mühlberger Profactor GmbH, Steyr-Gleink, Austria	<b>D5-4</b> <b>Combination of a biopolymer and UV-casting for production of a peripheral nerve implant containing an internal aligned microchannels array</b> Santos Merino <sup>1</sup> , Ruth Diez - Ahedo <sup>1</sup> , María del Carmen Marquez Posadas <sup>1</sup> , Iban Quintana <sup>1</sup> , Francisco Javier Rodriguez <sup>2</sup> , John W. Haycock <sup>3</sup> , Allan Glen <sup>3</sup> , Begona Castro <sup>4</sup> , Eva Gonzalez <sup>4</sup> , Patrick Duffy <sup>5</sup> , Wenxin Wang <sup>6</sup> , IK4-Tekniker, Eibar, Spain, <sup>2</sup> Hospital Nacional de Parapléjicos, Toledo, Spain, <sup>3</sup> University of Sheffield, Sheffield, England, <sup>4</sup> Histocell S.L., Derio, Spain, <sup>5</sup> Ashland Specialties Ireland, Synergy Centre, Dublin, Ireland, <sup>6</sup> University College Dublin, Charles Institute of Dermatology, Dublin, Ireland
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14:15-16:15

## POSTER SESSION II (Odd Numbers)



# 45<sup>th</sup> International Conference on Micro & Nano Engineering

23-26 September 2019 Rhodes, Greece

WEDNESDAY SEPTEMBER 25<sup>TH</sup>, 2019

Scientific Program

JUPITER HALL	
	Chair: C. Tsamis
16:15-17:00	<b>Plenary 6</b> <b>Nanogenerators for self-powered systems and sensors</b> Zhong Lin Wang Georgia Tech, USA

NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
<b>SESSION A6:</b> <b>NIL &amp; NOVEL LITHOGRAPHIES</b> Chairs: Y. Hirai, M. Farsari	<b>SESSION B6:</b> <b>NANOFACTORY FOR BIOAPPLICATIONS</b> Chairs: A. Maan, S. Franssila	<b>SESSION C6:</b> <b>PHOTONIC STRUCTURES</b> Chairs: S. Choulis, L. Businaro	<b>SESSION D6:</b> <b>INDUSTRIAL</b> Chairs: A. McMillan, A. Tserepi
<b>A6-1</b> <b>High throughput direct metal oxide nanopatterning by solgel soft-NIL in controlled atmosphere, and related applications</b> David Grosso <sup>1</sup> , Thomas Bottein <sup>1</sup> , Simona Checcucci <sup>2</sup> , Marco Faustini <sup>3</sup> , Mario Gurioli <sup>2</sup> , Luc Favre <sup>1</sup> , Marco Abbarchi <sup>1</sup> <sup>1</sup> Im2np / Aix Marseille University, Marseille Cedex 20, France, <sup>2</sup> European Laboratory for Nonlinear Spectroscopy (LENSS), Sesto Fiorentino, Italy, <sup>3</sup> Laboratoire de Chimie de la Matière Condensée de Paris - LCMCP Sorbonne Université, Paris, France	<b>B6-1</b> <b>Direct Photoreduction of Gold Nanoparticles on SU-8 nanostructures</b> Yi-Jui Chen <sup>1</sup> , Prof. Wen-Huei Chang <sup>2</sup> , Chun-hung Lin <sup>1</sup> <sup>1</sup> National Cheng Kung University, Tainan, Taiwan, <sup>2</sup> National Pingtung University, Pingtung, Taiwan	<b>C6-1</b> <b>Stretchable plasmonic rulers: Reversibly tuning the coupling strength of individual plasmonic nano-bowties on flexible substrates</b> Florian Lalibl <sup>1,2</sup> , Dominik A. Golmmer <sup>1,2</sup> , Simon Dicke-reuter <sup>1,2</sup> , Dieter P. Kern <sup>1,2</sup> , Monika Fleischer <sup>1,2</sup> <sup>1</sup> Institute for Applied Physics, University of Tuebingen, Germany, <sup>2</sup> Center LSA+, University of Tuebingen, Tuebingen, Germany	<b>D6-1</b> <b>Label-free imaging platform for rapid analysis of biomarkers</b> Luc Dümpeleimann <sup>1</sup> , Roland A. Terborg <sup>1</sup> , Josselin Pello <sup>1</sup> , Illaria Mannelli <sup>1</sup> , Filiz Yesilkoay <sup>2</sup> , Alexander Belushkin <sup>2</sup> , Yasaman Jahani <sup>2</sup> , Nuria Fabri-Fajá <sup>3</sup> , Priyanka Dey <sup>3</sup> , Olallo Calvo-Lozano <sup>3</sup> , M.-Carmen Estevez <sup>3</sup> , Anna Fàbrega <sup>4</sup> , Juan J. González-López <sup>4</sup> , Laura M. Lechugà <sup>5</sup> , Hatice Altug <sup>2</sup> , Valerio Pruneri <sup>1</sup> <sup>1</sup> CFO - Institut de Ciències Fotòniques, Castelldefels, Spain, <sup>2</sup> EPFL - Ecole Polytechnique Fédérale de Lausanne, Lausanne, Switzerland, <sup>3</sup> ICN2 - Institute of Neuroscience and Nanotechnology, Barcelona, Spain, <sup>4</sup> Hospital Universitari Vall d'Hebron, Barcelona, Spain
<b>A6-2</b> <b>Sub-micron silver wires on non-flat polymer substrates fabricated by thermal imprint and back injection molding</b> Helmut Schift <sup>1</sup> , Sijia Xie <sup>1</sup> , Barbara Horváth <sup>1</sup> , Jerome Werder <sup>2</sup> , Paul Scherrer Institut (PSI), Villigen PSI, Switzerland, <sup>2</sup> FHNW University of Applied Sciences and Arts Northwestern Switzerland, Windisch, Switzerland	<b>B6-2</b> <b>Micro-and nanostructures for ultrafast neural interfaces</b> Bekim Osmanni <sup>1</sup> , Tino Töpper <sup>1</sup> , Helmut Schift <sup>2</sup> , Raphaël Guzman <sup>3</sup> , Magnus Kristiansen <sup>4</sup> , Rowena Crockett <sup>5</sup> , Bert Müller <sup>1</sup> <sup>1</sup> Biomaterials Science Center, Department of Biomedical Engineering, University of Basel, Allschwil, Switzerland, <sup>2</sup> Laboratory for Micro- and Nanotechnology, Paul Scherrer Institute, Villigen, Switzerland, <sup>3</sup> Department of Neurosurgery, University Hospital Basel, Basel, Switzerland, <sup>4</sup> Institute of Polymer Nanotechnology, FHNW University of Applied Sciences and Arts Northwestern Switzerland, Windisch, Switzerland, <sup>5</sup> Coating Competence Center, Empa, Dübendorf, Switzerland	<b>C6-2</b> <b>Enhancement of Photodetection Performance of Graphene by Photoreceptor Protein</b> Jing Tong <sup>1,2</sup> , Yi Wang <sup>3,4</sup> , Yuelin Wang <sup>1</sup> , Tie Li <sup>1</sup> <sup>1</sup> SIMIT CAS, Shanghai, China, <sup>2</sup> UCAS, Beijing, China, <sup>3</sup> Beijing Institute of Lifeomics, Beijing, China, <sup>4</sup> NERCPD, Beijing, China	<b>D6-2</b> <b>A sensitive Lab-on-a-chip for pathogen detection using a simple DNA amplification reaction</b> Georgia Kaprou <sup>1</sup> , Katerina Tsougeni <sup>1,2</sup> , Athina S. Kastania <sup>2</sup> , Christos Morits Loukas <sup>1</sup> , Athanasios Smyrnakis <sup>1</sup> , Kosmas Ellinas <sup>1,2</sup> , Evangelos Gogolides <sup>1,2</sup> , Angeliki Tserepi <sup>1,2</sup> <sup>1</sup> NCSR Demokritos, Athens, Greece, <sup>2</sup> Nanoplasmas PC, Athens, Greece



# 45<sup>th</sup> International Micro & Nano Engineering Conference on

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## Scientific Program

	NEFELE HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
	<b>SESSION A6:</b> <b>NIL &amp; NOVEL LITHOGRAPHIES</b> Chairs: Y. Hirai, M. Farsari	<b>SESSION B6:</b> <b>NANOFACTORY FOR BIOAPPLICATIONS</b> Chairs: A. Maan, S. Franssila	<b>SESSION C6:</b> <b>PHOTONIC STRUCTURES</b> Chairs: S. Choulis, L. Businaro	<b>SESSION D6:</b> <b>INDUSTRIAL</b> Chairs: S. Park, A. McMillan
17:30	<b>A6-3</b> <b>Hydrogen Depassivation Lithography Exposure Physics</b> John Randall <sup>1</sup> , James H.G. Owen, Ehud Fuchs, Michael Schantz, Robin Santini, Cyndi Delgado, Joseph H. Lake Zyvex Labs, Richardson, United States	<b>B6-3</b> <b>BioBots: Light-controlled micro-tools for biological applications</b> Ada-loana Bunea <sup>1</sup> , Einstrom Engay <sup>2</sup> , Alexandre Wetzel <sup>1</sup> , Rafael Taboryski <sup>1</sup> , DTU NanoLab, Kongens Lyngby, Denmark, <sup>2</sup> DTU Fotonik, Kongens Lyngby, Denmark	<b>C6-3</b> <b>Micro-lens array superpositions for level-line moirés</b> Thomas Walger <sup>1</sup> , Roger D. Hersch <sup>2</sup> , Juergen Brugger <sup>1</sup> , Microsystems Laboratory - EPFL, Lausanne, Switzerland, <sup>2</sup> School of Computer and Communication Sciences - EPFL, Lausanne, Switzerland	<b>D6-3</b> <b>Dimple structure to enable highly accurate microdroplet manipulation</b> Katsuhiro Mogi <sup>1</sup> , Shungo Adachi <sup>1</sup> , Naoki Takada <sup>2</sup> , Tomoya Inoue <sup>2</sup> , Tohru Natsume <sup>1</sup> , Molecular Profiling Research Center For Drug Discovery, National Institute Of Advanced Industrial Science And Technology, Tokyo, Japan, <sup>2</sup> Research Center For Ubiquitous MEMS and Micro Engineering, National Institute of Advanced Industrial Science and Technology, Ibaraki, Japan
17:45	<b>A6-4</b> <b>Hard mask nanopatterns integrated into semiconductor manufacturing: A facile block copolymer methodology</b> Tandra Ghoshal <sup>1</sup> , Michael Morris <sup>2</sup> , Surface And Interface Chemistry, Department Of Chemistry, AMBER And CRANN, Trinity College Dublin, Dublin, Ireland, Ireland	<b>B6-4</b> <b>Fabrication Methodology Personalised Biodegradable Microneedle Array</b> Lubo Wu <sup>1</sup> , Nobuyuki Takama <sup>1</sup> , Beomjoon Kim <sup>1</sup> , Institute of Industrial Science, The University of Tokyo, Tokyo, Japan	<b>C6-4</b> <b>Nonplanar nanostructuring of tapered optical fibers for plasmonic neural interfaces</b> Filippo Pisano <sup>1</sup> , Antonio Balena <sup>1,2</sup> , Marco Grande <sup>3</sup> , Marco Pisanello <sup>1</sup> , Tiziana Stomeo <sup>1</sup> , Antonio Qualtieri <sup>1</sup> , Marco Bianco <sup>1,2</sup> , Leonardo Sileo <sup>1</sup> , Antonella D'Orazio <sup>3</sup> , Massimo De Vittorio <sup>1,2</sup> , Ferruccio Pisanello <sup>1</sup> , Fondazione Istituto Italiano Di Tecnologia-CBN, Annesano, Italy, <sup>2</sup> Dipartimento di Ingegneria dell'Innovazione, Università del Salento, Lecce, Italy, <sup>3</sup> Dipartimento di Ingegneria Elettrica e dell'Informazione, Politecnico di Bari, Bari, Italy	<b>D6-4</b> <b>Platform for High Throughput manufacturing of Microfluidic Devices</b> Martin Smolka <sup>1</sup> , Anja Haase <sup>1</sup> , Stephan Ruttloff <sup>1</sup> , Johannes Götz <sup>1</sup> , Pelin Tören <sup>1</sup> , Markus Rumpf <sup>2</sup> , Barbara Stadlober <sup>1</sup> , Jan Hesse <sup>1</sup> , Sascha Geidel <sup>2</sup> , Jörg Nestler <sup>2</sup> , Ingo Katzmayr <sup>3</sup> , Max Sonnleitner <sup>3</sup> , Suhit Hemant <sup>4</sup> , Jan Kafka <sup>4</sup> , Isbaal Ramos <sup>5</sup> , Mirko Lohse <sup>6</sup> , Manuel Thesen <sup>6</sup> , Georgios Kokkinis <sup>7</sup> , Günther Krieghammer <sup>7</sup> , Martin Horn <sup>8</sup> , Wilfried Weigel <sup>8</sup> , Nerea Briz Iceta <sup>9</sup> , Goran Bljeilc <sup>9</sup> , JOANNEUM RESEARCH - MATERIALS Institute, Weiz, Austria, <sup>2</sup> JOANNEUM RESEARCH -HEALTH Institute, Graz, Austria, <sup>3</sup> Biflow Systems GmbH Chemnitz, Germany, <sup>4</sup> GENSPEED Biotech GmbH, Rainbach, Austria, <sup>5</sup> Immolde A/S, Hørsholm, Denmark, <sup>6</sup> Innoprot, Derio, Spain, <sup>7</sup> micro resist technology GmbH, Berlin, Germany, <sup>8</sup> Pessl Instruments GmbH, Weiz, Austria, <sup>9</sup> Scienion AG, Berlin, Germany, <sup>10</sup> Tecnalia Research and Innovation, Donostia - San Sebastián, Spain
				<b>GALA DINNER</b> Including best poster awards, micrograph contest awards and lecture/performance on art and nanotechnology “Sky am: Mythologies & methodologies of a nanoartist” by Prof. Ioannis Michaloudis
				19:30-22:00

## THURSDAY SEPTEMBER 26<sup>TH</sup>, 2019

# Scientific Program

JUPITER HALL	
	Chairs: G. Grützner, D. Kern
08:45-09:30	<b>Plenary 7</b> <b>MNE Fellow Award &amp; Lecture</b> <b>More than name print-replication and combination</b> Hella-Christin Scheer University of Wuppertal, Germany
09:30-10:00	<b>Young Investigator Award</b> <b>Chips and gadgets for miniaturized assays</b> Yuksel Temiz lbm Research, Zurich, Switzerland
10:00-10:15	<b>Award Ceremony</b>
10:15-10:45	COFFEE BREAK



# 45<sup>th</sup> International Micro & Nano Engineering Conference on

23-26 September 2019 Rhodes, Greece

THURSDAY SEPTEMBER 26<sup>TH</sup>, 2019

## Scientific Program

	NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
10:45	<b>SESSION A7:</b> <b>ELECTRON AND ION BEAM LITHOGRAPHY</b> Chairs: S. Cabrini, A. Olziersky	<b>SESSION B7:</b> <b>NANOSTRUCTURES FOR PHOTONICS</b> Chairs: M. Muhlbacher, S. Dhuey	<b>SESSION C7:</b> <b>MATERIALS &amp; DEVICES FOR NANO ELECTRONICS</b> Chairs: Z. Durranj, D. Tsoukalas	<b>SESSION D7:</b> <b>MICRO &amp; NANO FLUIDICS</b> Chairs: P. Petrou, L. Malaquin
11:00	<b>A7-1</b> <b>A single integrated fiberoptrode for optogenetic stimulation and electrical recording of neural activity</b> Barbara Spagnolo <sup>1</sup> , Leonardo Sileo <sup>1</sup> , Rui Peixoto <sup>2</sup> , Marco Pisanello <sup>1</sup> , Filippo Pisano <sup>1</sup> , Emanuela Maglie <sup>1,3</sup> , Bernardo L. Sabatini <sup>2</sup> , Massimo De Vittorio <sup>1,3</sup> , Ferruccio Pisanello <sup>1</sup> <sup>1</sup> Istituto Italiano di Teconologia, Center for Biomolecular Nanotechnologies, Arnesano, Lecce, Italy, <sup>2</sup> Department of Neurobiology, Howard Hughes Medical Institute, Harvard Medical School, U.S.A., United States, <sup>3</sup> Università del Salento, Dipartimento di Ingegneria dell'Innovazione, Italy, Italy	<b>B7-1</b> <b>Fabrication of Vivid, Wide Area Transmission Holograms in Plastic Substrates using Nanoimprint Lithography</b> Keith Morton, Liviu Clime, Gaétan Veilleux, Luke Lukic, Matthew Shiu, Tedor Veres National Research Council Canada, Montreal, Canada	<b>C7-1_INV</b> <b>Merging Computing and Sensing for Low power and Sustainable Edge Applications</b> Thomas Ernst CEA-LETI, Grenoble, France	<b>D7-1</b> <b>3D coaxial liquid injection and extraction system by 2-photon-polymerization</b> Peer Erflé <sup>1,2</sup> , Andreas Dietzel <sup>1,2</sup> <sup>1</sup> Technische Universität Braunschweig, Germany, <sup>2</sup> Technische Universität Braunschweig, Center of Pharmaceutical Engineering, Braunschweig 38106, Germany
	<b>A7-2</b> <b>Cs and Rb Ion Coldbeam Suitability for Circuit Edit</b> Yuval Greenzweig <sup>1</sup> , Richard Livengood <sup>2</sup> , Roy Hallstein <sup>2</sup> , Yariv Drezner <sup>1</sup> , Minh Ly <sup>2</sup> , Shida Tan <sup>2</sup> , Amir Raveh <sup>1</sup> <sup>1</sup> Intel Israel, Haifa, Israel, <sup>2</sup> Intel Corporation, Santa Clara, USA	<b>B7-2</b> <b>Fabrication of Gold on glass photonic nanostructures.</b> Richard B. Cousins <sup>1</sup> , Shakila Naznin <sup>2</sup> , Hamed Pezeshki <sup>2</sup> , Matt Clark <sup>2</sup> , Christopher Mellor <sup>3</sup> <sup>1</sup> nmRC, <sup>2</sup> Electrical and electronic engineering, <sup>3</sup> Physics and Astronomy	<b>D7-2</b> <b>Fabrication of a μ-fluidic device by two-photon lithography using a positive tone resist</b> Gijs Van Der Velden, Daniel Fan, Urs Stauffer Delft University Of Technology, Delft, Netherlands	

11:15	<b>A7-3</b> <b>The Marriage of the Ions and Chemistry to Fulfill Semiconductor Devices Preparation</b> Gregory Goupill <sup>1</sup> , Pascal Gounet <sup>2</sup> , Christian Hollerth <sup>3</sup> , Frank Altmann <sup>4</sup> , Sebastian Brand <sup>4</sup> , Anne Delobbe <sup>1</sup> <sup>1</sup> Orsay Physics, Fuiveau, France, <sup>2</sup> ST Microelectronics, Grenoble, France, <sup>3</sup> Infinion Technologies, Neubiberg, Germany, <sup>4</sup> Fraunhofer IWM, Halle, Germany	<b>B7-3_INV</b> <b>Biomimetics of photosynthetic photonic structures. How natural light harvesting could become an inspiration for nanotechnology</b> Martin Lopez International Iberian Nanotechnology Laboratory-INL, Portugal	<b>C7-2</b> <b>Vertical field-effect transistors based on 3D GaN nanostructure arrays</b> Klaas Stremppel <sup>1,2</sup> , Feng Yu <sup>1,2</sup> , Hendrik Spende <sup>1,2</sup> , Jana Hartmann <sup>1,2</sup> , Friedhard Römer <sup>3</sup> , Bernd Witzigmann <sup>3</sup> , Andrey Bakin <sup>1,2</sup> , Hergo-Heinrich Wehmann <sup>1,2</sup> , Hitomo Suryo Wasisto <sup>1,2</sup> , Andreas Waag <sup>1,2</sup> <sup>1</sup> Institute Of Semiconductor Technology (IHT), TU Braunschweig, Braunschweig, Germany, <sup>2</sup> Laboratory of Emerging Nanometrology (LENA), TU Braunschweig, Braunschweig, Germany, <sup>3</sup> Computational Electronics and Photonics (CEP), Kassel University, Kassel, Germany
11:30	<b>A7-4</b> <b>Excitation power density dependence of photocurrent from InGaN photocathode</b> Daiki Sato <sup>1,2</sup> , Tomohiro Nishitani <sup>2,3</sup> , Atsushi Koizumi <sup>2</sup> , Yoshiro Honda <sup>3</sup> , Hiroshi Amano <sup>3</sup> <sup>1</sup> Department of Electronics, Nagoya University, Nagoya, Japan, <sup>2</sup> Photo electron Sou Inc., Nagoya, Japan, <sup>3</sup> Center for Integrated Research of Future Electronics, Institute of Materials and Systems for Sustainability, Nagoya University, Nagoya, Japan	<b>B7-3</b> <b>Design and simulation of planar nano vacuum channel transistors (pNVCT)</b> Marco Turchetti, Phillip D. Keathley, Yujia Yang, Alberto Nardi, Luca Daniel, Karl K. Berggren Massachusetts Institute of Technology, Cambridge, United States	<b>D7-3</b> <b>A Precise, Low-Power, Electrokinetically Actuated Micropumping Mechanism</b> Alexander Eden, Farnaz Lorestani, Sean Mackenzie, Stephen Minne, David Huber, Carl Meinhart, Sumita Pennathur University of California, Santa Barbara, Santa Barbara, United States
11:45	<b>A7-5</b> <b>Nanofabrication and imaging characterization of 30 nm resolution charts with vertical sidewalls</b> Jingyuan Zhu <sup>1</sup> , Sichao Zhang <sup>1</sup> , Shanshan Xie <sup>1</sup> , Yifang Chen <sup>1</sup> , Biao Deng <sup>2</sup> , Lijuan Zhang <sup>2</sup> <sup>1</sup> Nanolithography and Application Research Group, State Key Lab of ASIC and System, China, <sup>2</sup> Shanghai Synchrotron Radiation Facility, Shanghai Institute of Applied Physics, Shanghai, China	<b>B7-4</b> <b>Monolayer graphene direct transfer on silicon for Schottky photodiode fabrication</b> Yiming Wang <sup>1,2</sup> , Alberto Ballesio <sup>2</sup> , Matteo Parmeggiani <sup>2,3</sup> , Alessio Verna <sup>2</sup> , Matteo Cocuzza <sup>2,4</sup> , Candido Fabrizio Pirri <sup>2,3</sup> , Simone Luigi Marasso <sup>2,4</sup> , Shuming Yang <sup>1</sup> <sup>1</sup> State Key Laboratory for Manufacturing System Engineering, Xian Jiaotong University, <sup>2</sup> ChiLab - Materials and Microsystems Laboratory, DISAT, Politecnico di Torino, <sup>3</sup> Center for Sustainable Future Technologies, Italian Institute of Technology, <sup>4</sup> CNR-IMEM	<b>C7-4</b> <b>Integration of 2D MoS2 with In-AlAs/InGaAs heterojunction for dual color detection in both visible and near-infrared band</b> Jianan Deng, Mingsai Zhu, Yuying Xie, Lingyi Zong, Wenzhong Bao, Yifang Chen Fudan University, Shanghai, China



# Micro & Nano Engineering

23-26 September 2019 Rhodes, Greece

THURSDAY SEPTEMBER 26<sup>TH</sup>, 2019

## Scientific Program

12:00-13:00

LUNCH BREAK

NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
<b>SESSION AB: INDUSTRIAL I</b> Chairs: I. Raptis, M. Chatzichristidi	<b>SESSION BB: WETTING III</b> Chairs: K. Ellinas, A. Amirfasi	<b>SESSION CB: MATERIALS FOR NANO ELECTRONICS II</b> Chairs: A. Busnaina, D. Tsoukalas	<b>SESSION DB: DEVICES FOR DNA STUDIES</b> Chairs: G. Kaltsas
<b>A8-1_INV</b> <b>The path to Roll to Roll Imprint Technology, an Enabling Technology</b> John Maltabes <i>Applied Materials, Germany</i>	<b>B8-1</b> <b>A scalable process for manufacturing hierarchical superhydrophobic structures on aluminium: promotion of stable dropwise condensation for tropical air conditioning</b> Kristyn Kadalà, Soochan Chung, Hayden Taylor <i>UC Berkeley, BERKELEY, United States</i>	<b>C8-1</b> <b>Suitability of HSQ as fabrication material for vertical devices at nano-scale</b> Esteve Amat <sup>1</sup> , Alberto del Moral <sup>1</sup> , Hans-Jürgen Engelmann <sup>2</sup> , Ahmed Gharbi <sup>3</sup> , Guido Rademaker <sup>3</sup> , Marie-Line Porteau <sup>3</sup> , Raluca Tiron <sup>3</sup> , Joan Bausells <sup>1</sup> , Francesc Perez-Murano <sup>1</sup> <i>Institute of Microelectronics of Barcelona, Bellaterra, Spain,</i> <sup>2</sup> <i>Helmholtz-Zentrum Dresden-Rossendorf, Dresden, Germany,</i> <sup>3</sup> <i>CEA-LETI, Grenoble, France</i>	<b>D8-1</b> <b>Ultrafast Phage-Long DNA Size Profiling Using Optonanofluidic Device</b> Chia Fu Chou <sup>1</sup> , Jia Wei Yeh <sup>1</sup> , Yii Lih Lin <sup>1,2</sup> , K. K. Sriram <sup>1,2</sup> <sup>1</sup> <i>Institute of Physics, Academia Sinica, Taipei, Taiwan,</i> <sup>2</sup> <i>Chemical Biology Division, Chalmers University of Technology, Gothenburg, Sweden</i>
		<b>C8-2</b> <b>Memristive behaviour of electro-deposited thermoelectric materials</b> Ian Mihailovic, Katrina Klösel, Christofer Hierold <i>Micro and Nanosystems, ETH Zürich, Zürich, Switzerland</i>	<b>D8-2</b> <b>Nanomechanical DNA resonator for DNA structural alterations studies</b> Monica Marin <sup>1,2</sup> , Stefano Stassi <sup>1</sup> , Marco Allione <sup>2</sup> , Sergei Lopatin <sup>3</sup> , Domenico Marson <sup>4</sup> , Erik Laurini <sup>4</sup> , Sabrina Prici <sup>4</sup> , Bruno Torre <sup>2</sup> , Andrea Giugni <sup>2</sup> , Manola Moretti <sup>2</sup> , Peng Zhang <sup>2</sup> , Candido Fabrizio Pirri <sup>1</sup> , Carlo Ricciardi <sup>1</sup> , Enzo Di Fabrizio <sup>2</sup> <sup>1</sup> <i>DISAT Polytechnic of Turin, Turin, Italy</i> <sup>2</sup> <i>SMILeS Lab, KAUST, Thuwal, Kingdom of Saudi Arabia,</i> <sup>3</sup> <i>Imaging and Characterization Core Lab, KAUST, Thuwal, Kingdom of Saudi Arabia,</i> <sup>4</sup> <i>DEA, University of Trieste, Trieste, Italy</i>

<p><b>A8-2</b> <b>Flexpol: Developing a bactericide adhesive film</b></p> <p>Nikos Kehagias Catalan Institute Of Nanoscience And Nanotechnology, Bellaterra, Barcelona, Spain</p>	<p><b>B8-3</b> <b>Design, fabrication and characterisation strategies for large area bactericidal polymer films</b></p> <p>Francone A.<sup>1</sup>, Retolaza A.<sup>2</sup>, Ramiro J.<sup>2</sup>, Merino S.<sup>2</sup>, Vieira De Castro J.<sup>3</sup>, Neves N.<sup>3</sup>, Arana A.<sup>4</sup>, Marimon J.<sup>4</sup>, Sotomayor Torres C.<sup>1,5</sup>, Kehagias N.<sup>1</sup> <sup>1</sup>CN2 - Catalan Institute of Nanoscience and Nanotechnology, <sup>2</sup>IKA-Tekniker, <sup>3</sup>Research Institute of Biomaterials, Biodegradables and Biomimetics, <sup>4</sup>University Hospital-Biodonostia Health Research Institute, <sup>5</sup>Institucio Catalana de Recerca i Estudis Avancats (ICREA), Spain</p>
<p>13:30</p>	<p><b>C8-3</b> <b>Electrostatically-coupled dopant atom quantum dot transistor measurement at room-temperature</b></p> <p>Faris Abuallaila<sup>1</sup>, Chen Wang<sup>1</sup>, Vlad Petru Veigang-Radulescu<sup>1</sup>, Jonathan Griffiths<sup>2</sup>, Aleksey Andreev<sup>3</sup>, Mervyn Jones<sup>1</sup>, Zahid Durrani<sup>1</sup> <sup>1</sup>Imperial College London, London, United Kingdom, <sup>2</sup>University of Cambridge, Cambridge, United Kingdom, <sup>3</sup>Hitachi Cambridge, Cambridge, United Kingdom</p>

13:45

<p><b>A8-3</b> <b>Full-Scale Manufacturing of 200mm/300mm Wafers on a Fully Integrated Nanoimprint Lithography System</b></p> <p>Wiesbauer H.<sup>1</sup>, Chouiki M.<sup>1</sup>, Thanner C.<sup>1</sup>, Berger G.<sup>1</sup>, Martens S.<sup>2</sup>, Treiblmayr D.<sup>1</sup>, Hartbaum J.<sup>2</sup>, Ebelhuber M.<sup>1</sup> <sup>1</sup>EVGroup, <sup>2</sup>Institut für Mikroelektronik Stuttgart (IMS CHIPS), Germany</p>
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14:00

<p><b>D8-3</b> <b>Controlling DNA translocation in nanofluidic devices using topography</b></p> <p>Franziska Esmek, Irene Fernández-Cuesta Hamburg University, Hamburg, Germany</p>	<p><b>C8-3</b> <b>sputtered ZnO nanostructure homojunctions fabricated on room temperature pre-patterned substrates</b></p> <p>Deligeorgis G.<sup>1</sup>, Kampylafka V.<sup>2</sup>, Kostopoulos A.<sup>3</sup>, Modreanu M.<sup>4</sup>, Schmidt M.<sup>5</sup>, Gagaooudakis E.<sup>6</sup>, Tsagaraki K.<sup>7</sup>, Kontomitrou V.<sup>8</sup>, Konstantinidis G.<sup>9</sup>, Kirakidis G.<sup>10</sup>, Aperathitis E.<sup>11</sup> <sup>1</sup>FORTH/iesl, <sup>2</sup>FORTH/iesl, <sup>3</sup>FORTH/iesl, <sup>4</sup>Tyndall National Institute, <sup>5</sup>Tyndall national Institute, Iceland, <sup>6</sup>FORTH/iesl, <sup>7</sup>FORTH/iesl, <sup>8</sup>FORTH/iesl, <sup>9</sup>FORTH/iesl, <sup>10</sup>FORTH/iesl, <sup>11</sup>FORTH/iesl, Greece</p>
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14:15

COFFEE BREAK



# 45<sup>th</sup> International Micro & Nano Engineering Conference on

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THURSDAY SEPTEMBER 26<sup>TH</sup>, 2019

## Scientific Program

	NEFELE HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
14:15	<b>SESSION A9: INDUSTRIAL II</b> Chairs: T. Stomeo, Y. Georgiev	<b>SESSION B9: NANO FABRICATION</b> Chairs: N. Vainos, JH Oh	<b>SESSION C9: MATERIALS FOR PHOTONICS</b> Chairs: S. Merino, M. Lopez	<b>SESSION D9: LAB &amp; ORGAN ON-CHIP</b> Chairs: K. Tsougeni, S. Keller
A9-1	All integrated mix & match direct-write nano- and microlithography platform based on local heat induced sublimation of polyphthalaldehyde resist	B9-1 <b>Materials characterization of gas assisted etch and deposition of focused Cs+ ion beam</b> Yariv Drezner <sup>1</sup> , DYuval Greenzweig <sup>1</sup> , Roy Hallstein <sup>2</sup> , Rick Livengood <sup>2</sup> , Amir Raveh <sup>1</sup> , Adam Steele <sup>3</sup> , Brenton Knuffman <sup>3</sup> , Andrew Schwarzkopf <sup>3</sup> , Intel Israel, Haifa, Israel, <sup>2</sup> Intel Corporation, Santa Clara, United States, <sup>3</sup> zeroK Nanotech, Gaithersburg, United States	C9-1 <b>Tuning Fluorophores Concentration and Their Residence Time in Zero-Mode Waveguides</b> Andrea Barbaglia <sup>1,2</sup> , Michele Dipalo <sup>1</sup> , Francesco Tantussi <sup>1</sup> , Andrea Toma <sup>1</sup> , Francesco De Angelis <sup>1</sup> , Istituto Italiano di Tecnologia, Genova, Italy, <sup>2</sup> Dipartimento di Fisica, Università degli Studi di Genova, Genova, Italy	D9-1 <b>Lensless imaging strategies for micro-particles and bacterial colonies counting</b> Alexis Maire <sup>3</sup> , Tona Yescas Gonzalez <sup>1</sup> , Olivier Lecarme <sup>2</sup> , Marc Zelismann <sup>1</sup> , Emmanuel Picard <sup>3</sup> , Pierre Marcooux <sup>4</sup> , David Peyrade <sup>1</sup> , Univ. Grenoble Alpes, CNRS, LTM, Grenoble, France, <sup>2</sup> Smart Force Technologies, c/o LTM-CNRS CEA/LETI, Grenoble, France, <sup>3</sup> Univ. Grenoble Alpes, CEA, INAC, PHELIQS SINAPS, Grenoble, France, <sup>4</sup> Univ. Grenoble Alpes, CEA, LETI, DTBS, SBSC, LCM/LBAM, Grenoble, France
14:30	<b>A9-2 Advanced FIB Patterning Strategies for Photonic Devices</b> Achim Nadzeyka, Torsten Richter, Michael Kahl, Frank Nouverté Raith GmbH, Dortmund, Germany	<b>B9-2 Lithium-Doping of ZnO: is it possible to chemically produce p-type ZnO?</b> George P. Papagergiou <sup>1</sup> , Vassileios Psycharidis <sup>1</sup> , Maria Katsikini <sup>2</sup> , Fani Pinakidou <sup>2</sup> , Eleni Paloura <sup>2</sup> , Eleni Makarona <sup>1</sup> , Institute Of Nanoscience and Nanotechnology NCSR Demokritos, Athens, Greece, School of Physics, Aristotle University of Thessaloniki, Thessaloniki, Greece	<b>C9-2 Very High Refractive Index Transition Metal Dichalcogenide Photonic Conformal Coatings by Conversion of ALD Metal Oxides</b> Adam Schwartzberg, Christopher Chen, Jacopo Pedrini, Ashley Gaulding, Christopher Kastl, Scott Dhuey, Tevye Kuykendall, Giuseppe Calafiore, Francesca Toma, Stefano Cabrini, Shaul Aloni, The Molecular Foundry, Lawrence Berkeley National Labs, Berkeley, United States	<b>D9-2 On chip reconstitution of complex biological systems: a bridge between biology and mathematical models</b> Adele De Ninni <sup>1</sup> , Francesca Romana Bertani <sup>1</sup> , Annamaria Gerardino <sup>1</sup> , Roberto Natalini <sup>4</sup> , Elshan C. Braun <sup>4</sup> , Gabriella Bretti <sup>4</sup> , Giovanna Schiavoni <sup>1,2</sup> , Fabrizio Mattei <sup>2</sup> , Eugenio Martinelli <sup>3</sup> , Arianna Mencattini <sup>3</sup> , Luca Businari <sup>1</sup> , CNR - Institute Of Photonics And Nanotechnologies, <sup>2</sup> Istituto Superiore di Sanità, <sup>3</sup> Università di Tor Vergata, Department of Electronic Engineering, <sup>4</sup> CNR-Istituto per le Applicazioni del Calcolo

<p><b>A9-3</b> <b>New high etch resistant high resolution silsesquioxane based resist for DUV/EUV and e-beam lithography as long shelf-life and more sensitive alternative for HSQ</b></p> <p>Franziska Grüneberger<sup>1</sup>, Maike Gerngroß<sup>1</sup>, Matthias Schirmer<sup>1</sup>, Frank Heyroth<sup>2</sup>, Georg Schmidt<sup>3</sup>, Nicolas Pyka<sup>4</sup>, Lothar Hahn<sup>5</sup></p> <p><sup>1</sup>Allresist GmbH, Strausberg, Germany, <sup>2</sup>Institut für Physik, Martin-Luther-Universität Halle-Wittenberg, Halle (Saale), Germany, <sup>3</sup>Interdisziplinäres Zentrum für Materialwissenschaften, Martin-Luther-Universität Halle-Wittenberg, Halle, Germany, <sup>4</sup>Raith GmbH, Dortmund, Germany, <sup>5</sup>Institute of Microstructure, Karlsruhe Institute of Technology, Eggenstein-Leopoldshafen, Germany</p>	<p><b>B9-3</b> <b>Development of van der Waals force based microscale joint for microscale assembly</b></p> <p>Ki-hwan Jang<sup>1</sup>, Min-Soo Kim<sup>2</sup>, Jong Hyuk Im<sup>1</sup>, Sung-Hoon Ahn<sup>1,3</sup></p> <p><sup>1</sup>Department of Mechanical and Aerospace Engineering, Seoul National University, Seoul, South Korea, <sup>2</sup>Soft Robotics Research Center, Seoul National University, Seoul, South Korea, <sup>3</sup>Institute of Advanced Machines and Design, Seoul National University, Seoul, South Korea</p>	<p><b>C9-3</b> <b>Fabrication and novel applications of GaN-based microLED arrays</b></p> <p>Jan Gülink<sup>1,2</sup>, Michael Fahrbach<sup>1,2</sup>, Hendrik Spende<sup>1,2</sup>, Klaas Stremmel<sup>1,2</sup>, Tony Granzl<sup>1,2</sup>, Syed Asad Ali Zaidi<sup>1</sup>, Hitomo Suryo Wasisto<sup>1,2</sup>, Andreas Waag<sup>1,2</sup></p> <p><sup>1</sup>Institute of Semiconductor Technology (IHT), TU Braunschweig, Braunschweig, Germany, <sup>2</sup>Laboratory for Emerging Nanotechnology (LENA), TU Braunschweig, Braunschweig, Germany</p>	<p><b>D9-3</b> <b>3D structuration of porous PDMs by emulsion templating for the fabrication of cell culture scaffolds</b></p> <p>Roberto Riesco<sup>1,2</sup>, Louisa Boyer<sup>1</sup>, Sarah Blosse<sup>1,2</sup>, Pauline Lefebvre<sup>3</sup>, Pauline Assemat<sup>3</sup>, Thierry Leichtle<sup>1</sup>, Angelo Accardo<sup>1</sup>, Laurent Malagoon<sup>1</sup></p> <p><sup>1</sup>LAAS-CNRS, Toulouse, France, <sup>2</sup>INSA, Toulouse, France, <sup>3</sup>IMFT, Toulouse, France</p>
<p><b>A9-4</b> <b>Multiscale Position Correction for Automated Device-scale Lithography</b></p> <p>James Owen, Joseph Lake, Ehud Fuchs, Robin Santini, John Randall Zyvex Labs, Richardson, United States</p>	<p><b>B9-4</b> <b>Electrically controlled modification of polymer film structure of semiconductor - insulator composites casted by horizontal-dipping</b></p> <p>Kamil Awsiuk<sup>1</sup>, Jakub Rysz<sup>1</sup>, Mateusz M. Marzec<sup>2</sup>, Paweł Dąbczyński<sup>1</sup>, Andrzej Budkowski<sup>1</sup></p> <p><sup>1</sup>M. Smoluchowski Institute Of Physics, Jagiellonian University, Łojasiewicza 11, 30-348 Kraków, Poland, <sup>2</sup>Academic Centre for Materials and Nanotechnology AGH University of Science and Technology, Krakow, Poland</p>	<p><b>C9-4</b> <b>Magnetic Dipole Resonance Induced Visible Luminescence from Hundred Nanometers of Silicon Particles</b></p> <p>Sih Wei Chang, Yi-Chuan Tseng, Yang-Chun Lee, Hsuen-Li Chen</p> <p>Nation Taiwan University, Taipei, Taiwan</p>	
14:45	15:00	15:15-15:30	SHORT BREAK



# 45<sup>th</sup> International Micro & Nano Engineering

23-26 September 2019 Rhodes, Greece

THURSDAY SEPTEMBER 26<sup>TH</sup>, 2019

## Scientific Program

NEFELI HALL	DELPHI HALL	JUPITER HALL	ATHENA HALL
<b>SESSION A10: RESISTS</b> Chairs: T. Watanabe, Y. Georgiev	<b>SESSION B10: MICROFABRICATION</b> Chair: N. Kehagias, V. Vamvakas	<b>SESSION C10: SENSORS &amp; MEMS</b> Chairs: H. Nishikawa, P. Dimitrakis	<b>SESSION D10: CHEM. SENSORS &amp; BIOSENSORS II</b> Chairs: K. Misiakos, P. Petrou
<b>A10-1</b> <b>New PDMAEMA based block copolymers for emerging nanotechnologies</b> Anastasia Nikai <sup>1,2</sup> , Theodore Manouras <sup>3</sup> , Panagiotis Argitis <sup>2</sup> , Maria Vamvakaki <sup>3,4</sup> , Margarita Chatzichristidi <sup>1</sup> <sup>1</sup> National And Kapodistrian University Of Athens, <sup>2</sup> Institute of Nanoscience and Nanotechnology, NCSR "Demokritos", <sup>3</sup> Department of Materials Science and Technology, University of Crete, <sup>4</sup> Institute of Electronic Structure and Laser, Foundation for Research and Technology - Hellas (FORTH), Heraklion, Greece	<b>B10-1</b> <b>Manufacturing of local defined nano- and microstructures for semiconductor devices by dewetting phenomena</b> Owen Ernst <sup>1</sup> , Katharina Eylers <sup>1</sup> , Felix Lange <sup>1,2</sup> , Jörn Bonse <sup>3</sup> , Jörg Krüger <sup>3</sup> , Torsten Boeck <sup>1</sup> <sup>1</sup> Leibniz-Institut für Kristallzüchtung (IKZ) Berlin, Germany, <sup>2</sup> Brandenburgische Technische Universität Cottbus-Senftenberg (HTWK), Senftenberg, Germany, <sup>3</sup> Bundesanstalt für Materialforschung und -prüfung (BAM), Berlin, Germany	<b>C10-1</b> <b>Highly sensitive and selective NO<sub>2</sub> gas sensor using patterned FTO electrodes</b> Yoojong Kim <sup>1</sup> , So-Young Bak <sup>1</sup> , Jeongseok Lee <sup>1</sup> , Se-Hyeong Lee <sup>1</sup> , Moonsuk Yi <sup>1</sup> <sup>1</sup> Department of Electronics Engineering, Pusan National University, Geumjunggu, South Korea, <sup>2</sup> Department of Smart Hybrid Engineering, Pusan National University, Geumjunggu, South Korea	<b>D10-1</b> <b>Engineering light collection volumes with microstructured tapered optical fibers for optical readout of neural activity monitoring</b> Emanuela Maglie <sup>1,2</sup> , Marco Pisanello <sup>1</sup> , Filippo Pisano <sup>1</sup> , Antonio Balena <sup>1,2</sup> , Marco Bianco <sup>1,2</sup> , Barbara Spignolo <sup>1</sup> , Bernardo L. Sabatini <sup>3</sup> , Massimo De Vittorio <sup>1,2</sup> , Ferruccio Pisanello <sup>1</sup> <sup>1</sup> Istituto Italiano di Tecnologia, Center for Biomolecular Nanotechnologies, Arnesano, Italy, <sup>2</sup> Dipartimento di Ingegneria dell'Innovazione, Università del Salento, Lecce, Italy, <sup>3</sup> Department of Neurobiology, Howard Hughes Medical Institute Harvard Medical School, Boston, USA
<b>A10-2</b> <b>Evaluation of RE-650 as a positive tone resist for electron beam lithography with high plasma etch durability</b> Minghai Zhu <sup>1</sup> , Meichong Yu <sup>2</sup> , Jianan Deng <sup>1</sup> , Yuying Xie <sup>1</sup> , Yifang Chen <sup>1</sup> <sup>1</sup> Nanolithography and application research group, School of Information Science and Technology, FUDAN, China, <sup>2</sup> Han-Top Photomaterials C	<b>B10-2</b> <b>Templated dewetting of ultra-long wires for a Si-based circuit</b> Monica Bollani <sup>1</sup> , Marco Salvaglio <sup>2</sup> , Abdenacer Benali <sup>3</sup> , Mohammed Bouabdellaoui <sup>3,4</sup> , Alexey Fedorov <sup>1</sup> , Axel Voigt <sup>2</sup> , Luc Favre <sup>3</sup> , Jean Benoit Claude <sup>3</sup> , David Grosso <sup>2</sup> , Antoine Ronda <sup>3</sup> , Isabelle Berbezier <sup>3</sup> , Marco Abbarchi <sup>3</sup> <sup>1</sup> Institute of Photonics and Nanotechnologies of CNR (IFN-CNR), Como, <sup>2</sup> Institute of Scientific Computing, Technische Universität Dresden, <sup>3</sup> M2NP of CNRS, Marseille, <sup>4</sup> Laboratory of Physics of Condensed Matter and Renewable Energy, Hassan II University of Casablanca, Mohammedia, Morocco	<b>C10-2</b> <b>Single-Mode Polymer Ridge Waveguide Integration of Organic Thin-Film Laser</b> Marko Cehovskil <sup>1,3</sup> , Jing Becker <sup>2</sup> , Ouacef Charfi <sup>1,3</sup> , Pascal Porten <sup>1</sup> , Hans-Hermann Johannes <sup>1,3</sup> , Claas Müller <sup>2</sup> , Wolfgang Kowalsky <sup>1,3</sup> <sup>1</sup> ITU Braunschweig, IHF, Braunschweig, Germany, <sup>2</sup> University of Freiburg, FIT, Freiburg, Germany, <sup>3</sup> Cluster of Excellence PhoenixD, Hannover, Germany	<b>D10-2</b> <b>Electrochemical Sensing Based on Inkjet-Printed Reduced Graphene Oxide on a Flexible Substrate</b> Hamed Shamkhalianehar <sup>1</sup> , Jin-Woo Choi <sup>1,2</sup> <sup>1</sup> Louisiana State University, Baton Rouge, United States, <sup>2</sup> Center for Advanced Micro-structures and Devices Louisiana State University, United States

## THURSDAY SEPTEMBER 26<sup>TH</sup>, 2019

# Scientific Program

<p><b>A10-3</b> <b>Environmentally friendly nanofabrication with cellulose and water</b></p> <p>Dore C<sup>1</sup>, Osmond J<sup>2</sup>, Mihi A<sup>1</sup>  <sup>1</sup>ICFO-The Institute of Photonic Sciences, <sup>2</sup>Institut de Ciència de Materials de Barcelona, Spain</p>	<p><b>B10-3</b> <b>Deposition and optimization of Schottky junctions by Atomic Layer Deposition for piezotronic strain sensors</b></p> <p>Raoul Joly<sup>1,2</sup>, Stéphanie Girod<sup>1</sup>, Noureddine Adjeroud<sup>1</sup>, Tai Nguyen<sup>1,2</sup>, Kevin Menguelti<sup>1</sup>, Mohamed El Hachemi<sup>1</sup>, Patrick Grysant<sup>1</sup>, Sébastien Klein<sup>1</sup>, Jérôme Polesel<sup>1</sup>  <sup>1</sup>Luxembourg Institute of Science and Technology (LIST) Belvaux, Luxembourg, <sup>2</sup>University of Luxembourg, Limpertsberg Campus, Luxembourg</p>	<p><b>C10-3</b> <b>A MEMS based capacitive resonator designed for the detection of the target analyte</b></p> <p>Serdar Tez  Pamukkale University, Engineering Faculty, Department of Electric And Electronics Engineering, Denizli, Turkey</p>	<p><b>D10-3</b> <b>Microelectrode Arrays with Integrated Pneumatic Cavities for Electrode Position Control in Retinal Prosthesis</b></p> <p>Yuanhao Xu, Stella W. Pang  City University of Hong Kong, Kowloon Tong, Kowloon, Hong Kong</p>
<p><b>A10-4</b> <b>Synthesis and Photolithographic Characterization of Phenolic Molecular Resists under Electron-beam and Extreme UV Irradiation</b></p> <p>Jin-Kyun Lee<sup>1</sup>, Jeong-Seok Mun<sup>1</sup>, Hyun-Taek Oh<sup>1</sup>, Kanghyun Kim<sup>2</sup>, Sangsui Lee<sup>2</sup>  <sup>1</sup>Inha University, Incheon, South Korea, <sup>2</sup>Pohang Accelerator Laboratory, Postech, Pohang, South Korea</p>	<p><b>B10-4</b> <b>Patterning Platinum using CMP and plasma etching industrially compatible processes</b></p> <p>Adham Elshaer, Romain Stricher, Maxime Darnon, Dominique Drouin, Serge Ecoffey, LN2<sup>2</sup> CNRS, Université de Sherbrooke, 317, Sherbrooke, Canada</p>	<p><b>C10-4</b> <b>Integration of piezoelectric nano-structures with MEMS by inkjet printing</b></p> <p>Marc Gomez, Christina Martinez, Marcos Duque, Ana Moya, Gonzalo Murillo  Microelectronics Institute of Barcelona, Bellaterra, Spain</p>	<p><b>D10-4</b> <b>Effects of the Acid-base property of the Dopant on the SnO<sub>2</sub> Gas Sensor</b></p> <p>Zhenyu Yuan, Rui Li, Liangyu Fu, Wenhui Chuai, Zhongming Guo, Zhaoyin Tu, Fanbo Kong  Northeastern University, China, Shenyang, China</p>
16:00	16:15		

16:30-16:35

**SHORT BREAK**



# 45<sup>th</sup> International Micro & Nano Engineering

23-26 September 2019 Rhodes, Greece

THURSDAY SEPTEMBER 26<sup>TH</sup>, 2019

## Scientific Program

JUPITER HALL	
	Chairs: P. Dimitrakis, E. Gogolides
16:35-17:20	<b>Plenary 8</b> <b>New Materials and Devices for Interfacing with the Brain</b> George Malliaras University of Cambridge, UK

17:20-17:30	ANNOUNCEMENTS AND CLOSING REMARKS
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# Poster Sessions



45<sup>th</sup> International Conference on  
**MNE** 2019

**WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)**

**PA - Nanopatterning**

**PA01**

**Efficient Fabrication of Soft Polymer Microcantilevers from Dry Film Photoresist for Chemical Sensor Applications**

Madeleine Nilsen<sup>1</sup>, Steffen Strehle<sup>2</sup>

<sup>1</sup>Ulm University, <sup>2</sup>Ilmenau University of Technology

**PA05**

**Comparative study of theoretical contrast between extreme ultraviolet and electron beam lithography**

Kanghyun Kim<sup>1</sup>, Byeong-Gyu Park<sup>2</sup>, Hyun-Taek Oh<sup>3</sup>, Jin-Kyun Lee<sup>3</sup>, Geunbae Lim<sup>1</sup>, Sangsul Lee<sup>2</sup>

<sup>1</sup>Postech, <sup>2</sup>Pohang Accelerator Laboratory(PAL), <sup>3</sup>Inha University

**PA07**

**Machine learning based technique towards smart laser fabrication of CGH**

Aggeliki Anastasiou<sup>1</sup>, Evangelia Zacharaki<sup>2</sup>, Dimitris Alexandropoulos<sup>1</sup>, Konstantinos Moustakas<sup>2</sup>, Nikolaos Vainos<sup>1</sup>

<sup>1</sup>Dept. of Material Science, University Of Patras, <sup>2</sup>Dept. of Electrical and Computer Engineering, University Of Patras

**PA09**

**Fabrication of Holographic Optical Elements on Silver by Nanosecond IR Laser Source**

Dimitris Alexandropoulos<sup>1</sup>, Simone Mazzucato<sup>2</sup>, Vaggelis Karoutsos<sup>1</sup>, Christina (Tanya) Politi<sup>3</sup>, Nikos Vainos<sup>1</sup>

<sup>1</sup>Dept. of Material Science, University Of Patras, <sup>2</sup>SISMA S.p.A., <sup>3</sup>Dept. of Informatics and Telecommunications, University of Peloponnese

**PA11**

**Localized Laser Pyrolysis of SU-8 by Addition of Absorber**

Emil Ludvigsen<sup>1</sup>, Nina Ritter Pedersen<sup>1</sup>, Xiaolong Zhu<sup>2</sup>, Rudolphe Marie<sup>2</sup>, David M. A. Mackenzie<sup>3</sup>, Dirch H. Pedersen<sup>3</sup>, Anders Kristensen<sup>2</sup>, Jenny Emnéus<sup>4</sup>, Stephan Sylvest Keller<sup>1</sup>

<sup>1</sup>DTU Nanolab, Technical University Of Denmark, <sup>2</sup>DTU Health Tech, Technical University of Denmark, <sup>3</sup>DTU Physics, Technical University of Denmark, <sup>4</sup>DTU Bioengineering, Technical University of Denmark

**PA13**

**E-beam lithography (EBL) with conductive layer between resist and sapphire substrate**

Silvia Diewald, Gernot Goll

Center for Functional Nanostructures - Nanostructure Service Laboratory (CFN-NSL), Karlsruhe Institute of Technology (KIT)

**PA15**

**Comparison of positive and negative high resolution e-beam processes for the fabrication of nanoconstrictions**

Maik Gerngross<sup>3</sup>, Franziska Grüneberger<sup>3</sup>, Stephanie Lake<sup>1</sup>, Philip Dürrenfeld<sup>1</sup>, Frank Heyroth<sup>2</sup>, Matthias Schirmer<sup>3</sup>, Georg Schmidt<sup>1,2</sup>

<sup>1</sup>Institut für Physik, Martin-Luther-Universität Halle-Wittenberg, <sup>2</sup>Interdisziplinäres Zentrum für Materialwissenschaften, Martin-Luther-Universität Halle-Wittenberg, <sup>3</sup>Allresist GmbH

**TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)**

**PA - Nanopatterning**

**PA02**

**AquaSAVE™: Antistatic Agent for Electron Beam Lithography**

Takahiro Mori, Akira Yamazaki

Mitsubishi Chemical Corporation

**PA04**

**Novel Lift-off Process for DUV Displacement Talbot Lithography**

Mariusz Graczyk, Victor J. Gómez, Maria Huffman, Ivan Maximov

Solid State Physics, University of Lund

**PA06**

**SU-8 alternative - Atlas 46 and enhanced processing for electroplating applications**

Franziska Grüneberger<sup>1</sup>, Maik Gerngross<sup>1</sup>, Matthias Schirmer<sup>1</sup>, Bozena Matuskova<sup>2</sup>, Martin Eibelhuber<sup>2</sup>, Tobias Zenger<sup>2</sup>, Thomas Uhrmann<sup>2</sup>, Martin Weinhart<sup>2</sup>

<sup>1</sup>Allresist GmbH, <sup>2</sup>EV Group

**PA08**

**Laser printing of Cu electrical circuits on glass substrates**

Konstantina Tourlouki, Dimitris Alexandropoulos

Dept. of Material Science, University of Patras

**PA10**

**High-throughput DTL/optical-hybrid lithography for fabricating high-density silicon nanopillar arrays for field emission**

Dirk Jonker<sup>1</sup>, R. M. Tiggelaar<sup>3</sup>, J. W. Berenschot<sup>1</sup>, N. R. Tas<sup>1</sup>, A. van Houselt<sup>2</sup>, H. J. W. Zandvliet<sup>2</sup>, J. G. E. Gardeniers<sup>1</sup>

<sup>1</sup>Mesoscale Chemical Systems group, University of Twente,

<sup>2</sup>Physics of Interfaces and Nanomaterials group, University of Twente, <sup>3</sup>NanoLab cleanroom, University of Twente

**PA12**

**Nanofabrication of thick zone plates for hard X-ray optics using SML resist**

Wang Zhuangzhuang, Shanshan Xie, Jingyuan Zhu, Yifang Chen

Fudan University

**PA14**

**Recent advances in ice lithography for 3D nanofabrication**

Ding Zhao<sup>1</sup>, Anna Elsukova<sup>1</sup>, Marietta Batzer<sup>2</sup>, Brendan Shields<sup>2</sup>, Patrick Maletinsky<sup>2</sup>, Marco Beleggia<sup>1</sup>, Anpan Han<sup>3</sup>

<sup>1</sup>DTU Nanolab, Technical University of Denmark,

<sup>2</sup>Department of Physics, University of Basel, <sup>3</sup>Department of Mechanical Engineering, Technical University of Denmark

**PA16**

**HSQ alternative Medusa 82 for gray-scale lithography**

Maik Gerngross<sup>1</sup>, Franziska Grüneberger<sup>1</sup>, Matthias Schirmer<sup>1</sup>, Paul Voigt<sup>2</sup>, Uwe Hübner<sup>2</sup>

<sup>1</sup>Allresist GmbH, <sup>2</sup>Leibniz-Institute of Photonic Technology

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PA17**

**An optimal dosage test in electron beam lithography for GaN nanoLEDs fabrication**

Syed Asad Ali Zaidi<sup>1</sup>, Tony Granz<sup>1,2</sup>, Jan Gulink<sup>1,2</sup>, Klaas Stremmel<sup>1,2</sup>, Hutomo Suryo Wasisto<sup>1,2</sup>, Andreas Waag<sup>1,2</sup>

<sup>1</sup>Institute Of Semiconductor & Technology, <sup>2</sup>Laboratory for Emerging Nanometrology

**PA19**

**High throughput Mix and Match nano lithography based on Scanning Laser Beam -, Field-Emission Scanning Probe-, and Nano Imprint Lithography**

Martin Hofmann<sup>1</sup>, Laura Weidenfeller<sup>2</sup>, Shraddha Supreeti<sup>3</sup>, Johannes Kirchner<sup>2</sup>, Mathias Holz<sup>4</sup>, Christoph Reuter<sup>4</sup>, Stephan Mechold<sup>1</sup>, Eberhard Manske<sup>2</sup>, Ivo W. Rangelow<sup>1</sup>

<sup>1</sup>Ilmenau University of Technology, Department of Micro- and Nanoelectronic Systems, Gustav-Kirchhoff-Str. 1, 98693 Ilmenau, Germany, <sup>2</sup>Ilmenau University of Technology, Institute for Process Measurement and Sensor Technology, Gustav-Kirchhoff-Str. 1, 98693 Ilmenau, Germany, <sup>3</sup>Ilmenau University of Technology, Department of Microsystems Technology, Max-Plack-Ring 12, 98693 Ilmenau, Germany, <sup>4</sup>Nanoanalytik GmbH, Ehrenbergstr. 1, 98693 Ilmenau, Germany

**PA21**

**Power-law short-range point-spread function in electron-beam lithography**

Marcus Albrechtsen<sup>1</sup>, Søren Stobbe<sup>1,2</sup>

<sup>1</sup>Department of Photonics Engineering, DTU Fotonik, Technical University Of Denmark, <sup>2</sup>Beamfox Technologies ApS

**PA23**

**Sub40 nm planar Al nanowires using two-layer resis stacks**

Fotis Kalaitzakis<sup>1</sup>, George Papageorgiou<sup>1</sup>, V. Ryazanov<sup>2</sup>, K. Arutunov<sup>3</sup>, Pascal Normand<sup>1</sup>, Panagiotis Dimitrakos<sup>1</sup>

<sup>1</sup>Institute of Nanoscience & Nanotechnology, NCSR "Demokritos", <sup>2</sup>Institute of Solid State Physics, Russian Academy of Sciences, <sup>3</sup>Institute for Electronics and Mathematics, High School of Economics

**PA25**

**Fluorescent ionic liquid structures fabricated by e-beam lithography**

Dominik Kowal<sup>1</sup>, Krzysztof Rola<sup>1</sup>, Joanna Cybinska<sup>1,2</sup>, Marcin Skorenski<sup>1</sup>, Adrian Zajac<sup>3</sup>, Marcin Smiglak<sup>3</sup>, Slawomir Drobczynski<sup>4</sup>, Katarzyna Komorowska<sup>1,4</sup>

<sup>1</sup>Lukasiewicz Research Network - PORT Polish Center For Technology Development, <sup>2</sup>Faculty of Chemistry, University of Wroclaw, <sup>3</sup>Poznan Science and Technology Park,

<sup>4</sup>Faculty of Fundamental Problems of Technology, Wroclaw University of Science and Technology

**PA27**

**Impact of plasma treatment on the pattern fidelity of nanostructured polymer surfaces**

Martin Eibelhuber<sup>1</sup>, Anna Dudus<sup>1</sup>, Jacek Gasiorowski<sup>1</sup>, Ruxandra-Aida Barb<sup>1</sup>, Christine Thanner<sup>1</sup>, Stephan Martens<sup>2</sup>, Julian Hartbaum<sup>2</sup>

<sup>1</sup>Evgroup, <sup>2</sup>Insitut für Mikroelektronik Stuttgart (IMS CHIPS)

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PA18**

**Magnetic skyrmions in thin Co/Pt/Au multilayer nanodots inspected by a tailored magnetic probe**

Jan Soltys, Iuliia Vetrova, Tomas Scepka, Michal Mruczkiewicz, Jan Derer, Stefan Gazi, Vladimir Cambel

Institute of Electrical Engineering

**PA20**

**Preparation of Micro- and Nanostructures by Ion or Electron Beam Lithography and Following Selective Wet Etching**

Tomáš Šamořil<sup>1</sup>, T. Šikola<sup>2</sup>

<sup>1</sup>Central European Institute of Technology, <sup>2</sup>Institute of Physical Engineering, Brno University of Technology

**PA22**

**Resistless SixN patterns fabrication by e-beam lithography**

Kornelia Indykiewicz, Bogdan Paszkiewicz, Regina Paszkiewicz

Wroclaw University of Science and Technology

**PA26**

**Fabrication and application of high-performance flexible transparent nanomesh electrodes**

Sung-il Chung<sup>1</sup>, Pan Kyeom Kim<sup>1</sup>, Tae-gyu Ha<sup>1</sup>, Eung Sug Lee<sup>2</sup>, Kwang Young Kim<sup>2</sup>

<sup>1</sup>Korea Electrotechnology Research Institute, <sup>2</sup>Korea Institute of Machinery & Materials

**PA28**

**Transfer durability of line-patterned replica mould made of high hardness UV-curable resin**

Tetsuma Marumo, Jun Taniguchi

Tokyo University of Science

**PA30**

**Fabrication of composite-electrode for SOFC via ultra violet nanoimprint lithography**

Ryota Akama<sup>1</sup>, Takao Okabe<sup>1</sup>, Kazuyoshi Sato<sup>2</sup>, Naoki Shikazono<sup>3</sup>, Jun Taniguchi<sup>1</sup>

<sup>1</sup>Tokyo University of Science, <sup>2</sup>Gunma University, <sup>3</sup>Institute of Industrial Science, The University of Tokyo

**PA32**

**Blue light nanoimprint lithography for patterning a positive-tone EB resist**

Takao Okabe, Haruki Matsumoto, Jun Taniguchi

Tokyo University of Science

**PA34**

**Hot punching: A versatile tool to fabricate microparticles**

Ritika Petersen<sup>1,2</sup>, Stephan Keller<sup>1,2</sup>, Anja Boisen<sup>2</sup>

<sup>1</sup>DTU Nanolab, Technical University of Denmark, <sup>2</sup>DNRF and Villum Fonden Center for Intelligent Drug Delivery and Sensing Using Microcontainers and Nanomechanics, IDUN, DTU Health Tech

**WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)**

**PA29**

**Fabrication of microchannel via UV-NIL and EBL using UV curable positive-tone EB resist**

Haruki Matsumoto, Takao Okabe, Professor Jun Taniguchi

Tokyo University of Science

**TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)**

**PA36**

**Imprint-induced grain growth in perovskite layers**

Andre Mayer, Neda Pourdavoud, Tobias Haeger, Ralf Heiderhoff, Miriam Leifels, Johannes Rond, Johannes Staabs, Patrik Görnn, Thomas Riedl, Hella-Christin Scheer

University of Wuppertal

**PA31**

**Moth-eye structured mould using sputtered glassy carbon layer for large scale application**

Tomoya Yano<sup>1</sup>, Hiroyuki Sugawara<sup>2</sup>, Jun Taniguchi<sup>1</sup>

<sup>1</sup>Tokyo University of Science, <sup>2</sup>GEOMATEC Co., Ltd.

**PA33**

**Analysis of surface cracks in VUV-hardened PDMS by means of video evaluation**

Miriam Leifels, Andre Mayer, Patrick Görnn, Hella-Christin Scheer

University Of Wuppertal

**PA39**

**Magnetic- plasmonic nanoparticles fabricated with high throughput step and repeat nanoimprint lithography**

Michael Haslinger<sup>1</sup>, Tina Mitteramskogler<sup>1</sup>, Astrit Shoshi<sup>2</sup>, Stefan Schrittwieser<sup>3</sup>, Joerg Schotter<sup>3</sup>, Hubert Brueckl<sup>2</sup>, Michael Muehlberger<sup>1</sup>

<sup>1</sup>Profactor GmbH., <sup>2</sup>Danube University Krems, Department for Integrated Sensor Systems, <sup>3</sup>AIT Austrian Institute of Technology, Molecular Diagnostics

**PA41**

**Computational study on molecular size dependence on pressing and de-molding process in nanoimprint lithograph**

Reo Sakata<sup>1</sup>, Masaaki Yasuda<sup>1</sup>, Yuya Miyashita<sup>1</sup>, Kazuhiro Tada<sup>2</sup>, Masamitsu Shirai<sup>1</sup>, Hiroaki Kawata<sup>1</sup>, Yoshihiko Hirai<sup>1</sup>

<sup>1</sup>Osaka Prefecture University, <sup>2</sup>National Institute of Technology, Toyama College

**PA43**

**Displacement Talbot Lithography for Fabrication of Large Area Nanoimprint Stamps**

Mariusz Graczyk, Muhammad Asif, Ivan Maximov

Lund University

**PA45**

**A novel process to realize 4H-SiC nanowire arrays**

Maria Androulidaki<sup>2</sup>, Maximilien Cottat<sup>1</sup>, Antonios Stavrinidis<sup>2</sup>, Cecile Gourgon<sup>1</sup>, Camille Petit-Etienne<sup>1</sup>, Edwige Bano<sup>3</sup>, George Konstantinidis<sup>2</sup>, Jumana Boussey<sup>1</sup>, Konstantinos Zekentes<sup>2,3</sup>

<sup>1</sup>Laboratoire des Technologies de la Microélectronique, <sup>2</sup>MRG-IESL/ FORTH, Vassiliki Vouton, PO Box 1385 Heraklion, Greece, <sup>3</sup>Grenoble-INP, IMEP-LAHC

**PA49**

**STM imaging enhancements for better features identification**

Ehud Fuchs, Joseph Lake, James Owen, John Randall

Zyvex Labs

**PA36**

**Imprint-induced grain growth in perovskite layers**

Andre Mayer, Neda Pourdavoud, Tobias Haeger, Ralf Heiderhoff, Miriam Leifels, Johannes Rond, Johannes Staabs, Patrik Görnn, Thomas Riedl, Hella-Christin Scheer

University of Wuppertal

**PA38**

**Shear force measurement of actuated, gecko-inspired adhesion elements with hierarchical PDMS pattern**

Joachim Zajadacz<sup>1</sup>, Klaus Zimmer<sup>1</sup>, Pierre Lorenz<sup>1</sup>, Andre Mayer<sup>2</sup>, Marc Papenheim<sup>2</sup>, Hella-Christin Scheer<sup>2</sup>

<sup>1</sup>Leibniz-Institute of Surface Engineering, <sup>2</sup>School of Electrical, Information and Media Engineering, University of Wuppertal,

**PA40**

**Combining Multilayer Multimaterial Nanoimprinting and Inkjet Printing**

Michael Mühlberger, Amiya Ranjan Moharana, Helene Außerhuber, Sonja Kopp, Tina Mitteramskogler, Daniel Fechtig

PROFACTOR GmbH

**PA42**

**Molecular simulation study of demolding process in UV nanoimprint**

Masanori Koyama, Keisuke Nakajima, Masamitsu Shirai, Hiroaki Kawata, Yoshihiko Hirai, Masaaki Yasuda

Osaka Prefecture University

**PA44**

**Nanoimprint Lithography as New Route towards 3-dimensionally structured substrates for in-vitro cell cultures**

Patrick Schuller<sup>1</sup>, M. Rothbauer<sup>1</sup>, Peter Ertl<sup>1</sup>, A. Moharana<sup>2</sup>, Michael Muehlberger<sup>2</sup>, E. Bertagnolli<sup>1</sup>, Heinz Wanzenboeck<sup>1</sup>

<sup>1</sup>IU Wien - Vienna University of Technology, <sup>2</sup>Profactor GmbH

**PA46**

**Flexible Fabrication Method of Waveguide Integrated Laser Source by CNP Process**

Jing Becker<sup>1,4</sup>, Marko Čehovski<sup>2,3</sup>, Reinhard Caspary<sup>2,3</sup>, Hans-Hermann Johannes<sup>2,3</sup>, Wolfgang Kowalsky<sup>2,3</sup>, Claas Mueller<sup>1,4</sup>

<sup>1</sup>Freiburger Zentrum für interaktive Werkstoffe und bioinspirierte Technologien (FIT), Albert-Ludwigs-Universität Freiburg, <sup>2</sup>Institut für Hochfrequenztechnik, Technische Universität Braunschweig, <sup>3</sup>Cluster of Excellence PhoenixD (Photonics, Optics, and Engineering - Innovation Across Disciplines), <sup>4</sup>Servicecenter Mechanische Mikrfertigung, IMTEK, Albert-Ludwigs-Universität Freiburg

**PA48**

**Towards faster self-assembly in block copolymer films: the use of plasma treatment**

Elsa Giraud<sup>1,2</sup>, Tandra Ghoshal<sup>1,2</sup>, M.A. Morris<sup>1</sup>

<sup>1</sup>Department of Chemistry, University College Cork, <sup>2</sup>School Of Chemistry, AMBER, Trinity College Dublin

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PA53**

**Modified fluorous developer solutions with additives for Orthogonal Photolithography of organic light emitting diode displays**

Jongchan Son<sup>1</sup>, Han Young Shin<sup>2</sup>, Yu Min Choi<sup>2</sup>, Jin-Kyun Lee<sup>1</sup>, Byung Jun Jung<sup>2</sup>

<sup>1</sup>Inha University, <sup>2</sup>University of Seoul

**PA55**

**Brilliant Fluorescent Resists for E-beam and Photolithographic Applications**

Franziska Grüneberger<sup>1</sup>, Maik Gerngross<sup>1</sup>, Matthias Schirmer<sup>1</sup>, Thomas Steglich<sup>2</sup>, Philipp Bastian<sup>3</sup>, Marita Steffen<sup>3</sup>, Michael Kumke<sup>3</sup>

<sup>1</sup>Allresist GmbH, <sup>2</sup>Präzisionsoptik Gera GmbH, <sup>3</sup>Physical Chemistry, Institute of Chemistry, University of Potsdam

**PA57**

**In-situ monitoring of development step of high-resolution e-beam resists**

Theodora Mpatzaka<sup>1</sup>, Grigoris Zisis<sup>1,2</sup>, George Papageorgiou<sup>2</sup>, Dimitrios Goustouridis<sup>1,3</sup>, Ioannis Raptis<sup>1,2</sup>

<sup>1</sup>ThetaMetris SA, Athens, Greece, <sup>2</sup>INN, NCSR 'Demokritos', Athens, Greece, <sup>3</sup>Dept. Electrical & Electronics Eng., University of West Attica, Athens, Greece

**PA59**

**Electron beam direct writing of polymer microstructures using a solvent-free ionic liquid as a resist**

Krzysztof Rola<sup>1</sup>, Adrian Zajac<sup>2</sup>, Andrea Szpecht<sup>2,3</sup>, Joanna Cybinska<sup>1,4</sup>, Marcin Smiglak<sup>2</sup>, Katarzyna Komorowska<sup>1,5</sup>

<sup>1</sup>LUKASIEWICZ Research Network - PORT Polish Center For Technology Development, <sup>2</sup>Poznan Science and Technology Park, <sup>3</sup>Faculty of Chemistry, Adam Mickiewicz University, <sup>4</sup>Faculty of Chemistry, University of Wroclaw, <sup>5</sup>Faculty of Fundamental Problems of Technology, Wroclaw University of Science and Technology

**PA61**

**Vertical High Aspect Ratio Silicon Via Etching for TSV Applications**

Stokeley K<sup>1</sup>, Ren Z<sup>1</sup>

<sup>1</sup>Oxford Instruments, Bristol, United Kingdom

**PA63**

**Surface functionalization by patterning and etching of metals using chlorine plasmas**

Guillaume Le Dain<sup>1</sup>, Feriel Laourine<sup>2</sup>, Ahmed Rhallabi<sup>1</sup>, Aurelie Girard<sup>1</sup>, Christophe Cardinaud<sup>1</sup>, Thierry Czerwic<sup>2</sup>, Stephane Guillet<sup>3</sup>, Daniel Turover<sup>4</sup>, Gregory Marcos<sup>2</sup>

<sup>1</sup>Institut Des Matériaux Jean Rouxel, Cnrs, <sup>2</sup>Institut Jean Lamour, <sup>3</sup>Centre de Nanosciences et Nanotechnologies, <sup>4</sup>SILSEF

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PA52**

**Process optimization of Medusa 82 resist by electron beam lithography**

Th. Mpatzaka<sup>1</sup>, Grigoris Konstantinos Zisis<sup>1,2</sup>, Vasilis Vamvakas<sup>2</sup>, Ioannis Raptis<sup>1,2</sup>, George Papageorgiou<sup>2</sup>, C. Kaiser<sup>3</sup>, T. Mai<sup>3</sup>, Mr. Matthias Schirmer<sup>3</sup>, Maik Gerngross<sup>3</sup>

<sup>1</sup>ThetaMetris SA, <sup>2</sup>NCSR "Demokritos", <sup>3</sup>Allresist GmbH

**PA54**

**Time- and cost-effective fabrication of micro-structured sample holders for serial crystallography experiments**

Miriam Barthelmess<sup>1</sup>, Ville Nissinen<sup>2</sup>, Petri Karvinen<sup>2</sup>, Pontus Fischer<sup>1</sup>, Tim Pakendorf<sup>1</sup>, Karol Bustos<sup>1</sup>, Gisel Peña<sup>1</sup>, Henry N. Chapman<sup>1</sup>, Alke Meents<sup>1,2</sup>

<sup>1</sup>Center for Free-Electron Laser Science, Deutsches Elektronen Synchrotron DESY, <sup>2</sup>Institute of Photonics, University of Eastern Finland

**PA56**

**A new specifically tailored resist for UV-NIL using gas permeable soft stamp and a study of its etching behaviour on fused silica substrates**

Shuhao Si<sup>1</sup>, Martin Messerschmidt<sup>2</sup>, Manuel Thesen<sup>2</sup>, Arne Schleunitz<sup>2</sup>, Gabi Grützner<sup>2</sup>, Stefan Sinzinger<sup>1</sup>

<sup>1</sup>Technische Universität Ilmenau, <sup>2</sup>micro resist technology GmbH

**PA60**

**Deep reactive ion etching of grass-free widely spaced periodic 2D structure**

Chantal Myrielle Silvestre, Henri Jansen, Ole Hansen  
Technical University of Denmark, DTU Nanolab

**PA62**

**Fabrication of decorated nanopillar arrays for silicon light trapping enhancement in solar cell applications**

Jordi Llobet<sup>1</sup>, Carlos Calaza<sup>1</sup>, Mariana Antunes<sup>1</sup>, Helder Fonseca<sup>1</sup>, Sofia Martins<sup>1</sup>, Yevgeny Faingold<sup>2</sup>, Shay Fadida<sup>2</sup>, Ashish Prajapati<sup>2</sup>, Gil Shalev<sup>2</sup>, João Gaspar<sup>1</sup>

<sup>1</sup>International Iberian Nanotechnology Laboratory, <sup>2</sup>Ben-Gurion University of the Negev

**PA64**

**Cryogenic etching for large area pattern transfer into silicon of Mix-and-Match structured resist layers**

Laura Weidenfeller<sup>1</sup>, Martin Hofmann<sup>2</sup>, Johannes Kirchner<sup>1</sup>, Mathias Holz<sup>3</sup>, Christoph Reuter<sup>3</sup>, Stephan Mechold<sup>2</sup>, Eberhard Manske<sup>1</sup>, Ivo W. Rangelow<sup>2</sup>

<sup>1</sup>Ilmenau University of Technology, Institute for Process Measurement and Sensor Technology, <sup>2</sup>Ilmenau University of Technology, Department of Micro- and Nanoelectronic Systems, <sup>3</sup>Nanoanalytic GmbH

**PA66**

**Low-temperature etching of porous low-k dielectrics in C<sub>2</sub>F<sub>4</sub>Br<sub>2</sub> plasma**

Andrey Miakonikh<sup>1,2</sup>, Askar Rezvanov<sup>2,3</sup>, Alexey Vishnevskiy<sup>4</sup>, Konstantin Rudenko<sup>1,2</sup>

<sup>1</sup>Valiev Institute For Physics And Techology of Russian Academy of Sciences, <sup>2</sup>Moscow Institute of Physics and Technology (MIPT), <sup>3</sup>Molecular Electronics Research Institute (JSC MERI), <sup>4</sup>MIREA - Russian Technological University (RTU MIREA)

**WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)**

**PA65**

A short post-processing method for high aspect ratio trenches after Bosch etching

Henk-Willem Veltkamp<sup>1</sup>, Yiyuan Zhao<sup>1</sup>, Meint de Boer<sup>1</sup>, Remco Wiegerink<sup>1</sup>, Joost Lötters<sup>1,2</sup>

<sup>1</sup>University of Twente, <sup>2</sup>Bronkhorst High-Tech BV

**TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)**

**PA68**

Anisotropic plasma etching of Silicon in gas chopping process by alternating steps of oxidation and etching

Andrey Miakonikh, Sergey Averkin, Konstantin Rudenko, Vladimir Lukichev

Valiev Institute for Physics and Technology of Russian Academy of Sciences

**PA67**

Cobalt subtractive etch for advanced interconnects

Alexander Rogozhin, Andrey Miakonikh, Andrey Tatarintsev, Konstantin Rudenko

Valiev Institute of Physics and Technology Of Russian Academy of Sciences

**PA69**

A study of the effect of bilayer resist sensitivity difference on the T shape gate profiles

Yuying Xie, Zhiqiang Chen, Jianan Deng, Mingsai Zhu, Yifang Chen

Nanolithography and Application Research Group, Fudan University

**PA71**

Direct Monte-Carlo simulation of dry e-beam etching of resist

Alexander Rogozhin<sup>1</sup>, Fedor Sidorov<sup>1,2</sup>, Mark Bruk<sup>1</sup>, Eugene Zhikharev<sup>1</sup>

<sup>1</sup>Valiev Institute of Physics and Technology of Russian Academy of Sciences, <sup>2</sup>Moscow Institute of Physics and Technology

**PA73**

AFM integrated with a SEM for correlative imaging, 3D-metrology and nanofabrication

Martin Hofmann<sup>1</sup>, Mathias Holz<sup>2</sup>, Alexander Reum<sup>2</sup>, Laura Weidenfeller<sup>3</sup>, Stephan Mechold<sup>1</sup>, Eberhard Manske<sup>3</sup>, Tzvetan Ivanov<sup>1</sup>, Ivo W. Rangelow<sup>1</sup>

<sup>1</sup>Department of Micro- and Nanoelectronic Systems,

<sup>2</sup>Nanoanalytik GmbH, <sup>3</sup>Institute for Process Measurement and Sensor Technology

**PA75**

AFM tip shape characterization and measurement correction through the use of e-beam nanopillar standards with optimized sharpness

George Papageorgiou<sup>1</sup>, V. Constantoudis<sup>1,2</sup>, R. Koops<sup>3</sup>, P. Dimitrakis<sup>1</sup>

<sup>1</sup>NCSR "Demokritos", <sup>2</sup>Nanometrisis p.c., <sup>3</sup>VSL

**PA77**

A hybrid modeling framework for the investigation of roughness formation during plasma etching of polymeric surfaces

George Memos<sup>1,2</sup>, Elefterios Lidorikis<sup>2</sup>, George Kokkoris<sup>1</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology NCSR "Demokritos", <sup>2</sup>Department of Materials Science and Engineering, University of Ioannina

**PA68**

Anisotropic plasma etching of Silicon in gas chopping process by alternating steps of oxidation and etching

Andrey Miakonikh, Sergey Averkin, Konstantin Rudenko, Vladimir Lukichev

Valiev Institute for Physics and Technology of Russian Academy of Sciences

**PA70**

Optimum design of a 740 mm-long lens mount for fast line-beam proximity exposure process producing fine patterns with 5  $\mu\text{m}$  width

ChangKyu Lee<sup>1</sup>, Hyeondong Yang<sup>1</sup>, Sang Gil Ryu<sup>2</sup>, Je Hoon Oh<sup>1</sup>

<sup>1</sup>Hanyang University, <sup>2</sup>Philoptics Co. Ltd

**PA72**

High throughput AFM wafer inspection with parallel active cantilevers

Mathias Holz<sup>2</sup>, Christoph Reuter<sup>2</sup>, Ahmad Ahmad<sup>2</sup>, Martin Hofmann<sup>1</sup>, Alexander Reum<sup>2</sup>, Tzvetan Ivanov<sup>1</sup>, Stephan Mechold<sup>1</sup>, Ivo W. Rangelow<sup>1</sup>

<sup>1</sup>Department of Micro- and Nanoelectronic Systems, <sup>2</sup>Nanoanalytik GmbH

**PA74**

Improving the accuracy of Line Edge Roughness measurement using Hidden Markov Models

George Papavarios<sup>1,2,4</sup>, Vassilios Constantoudis<sup>1,2</sup>, Ioannis Kontoyiannis<sup>3</sup>, Eva Giannatou<sup>2</sup>, Evangelos Gogolides<sup>1,2</sup>

<sup>1</sup>NCSR Demokritos/ Institute of Nanoscience and Nanotechnology, <sup>2</sup>Nanometrisis P.C., <sup>3</sup>University of Cambridge, <sup>4</sup>Aristotle University of Thessaloniki, Thessaloniki

**PA76**

SEM Inspection of Nanowire Devices: Contact Inspection, Resistance and Capacitance Measurement and Buckling Evaluation

Takeyoshi Ohashi<sup>1</sup>, Kazuhisa Hasumi<sup>2</sup>, Masami Ikota<sup>2</sup>, Gian Lorusso<sup>3</sup>, Hans Mertens<sup>3</sup>, Liesbeth Witters<sup>3</sup>, Naoto Horiguchi<sup>3</sup>

<sup>1</sup>Hitachi, Ltd., <sup>2</sup>Hitachi High-Technologies Corporation, <sup>3</sup>imec

**PA78**

Titanium Nitride Plasmonic Surfaces via Nanosphere Lithography

Spyros Kassavetis<sup>1</sup>, S. Panos<sup>2</sup>, D. Tselekidou<sup>1</sup>, A. Theodosiou<sup>1</sup>, P. Patsalas<sup>2</sup>

<sup>1</sup>Nanotechnology Lab LTFN, Physics Department, Aristotle University of Thessaloniki, Thessaloniki

<sup>2</sup>Physics Department, Aristotle University of Thessaloniki, Thessaloniki

**WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)**

**PB - Nanofabrication**

**PB01**

**Selective Area Deposition via Polymer Brush Films**

Ross Lundy, Pravind Yadav, Michael A. Morris

School of Chemistry, AMBER@CRANN, Trinity College Dublin



**PB03**

**Novel Fabrication Method for Diamond-Shaped Silicon Nanowires on (100)-Oriented Single Crystal Silicon**

Yunqian He<sup>1,2</sup>, Yi Yang<sup>1,2</sup>, Yuelin Wang<sup>1</sup>, Tie Li<sup>1</sup>

<sup>1</sup>SIMIT, CAS, <sup>2</sup>UCAS



**PB05**

**Design and fabrication of hierarchical multi-scale structures on curved surface**

Na Eun Yeo<sup>1</sup>, Doo-in Kim<sup>2</sup>, Young-Ho Ha<sup>3</sup>, Myung Yung Jeong<sup>1,4</sup>

<sup>1</sup>Department of Cogno-mechatronics Engineering, Pusan National University, <sup>2</sup>Opto-mechatronics Engineering Research Institute, Pusan National University, <sup>3</sup>Nano Convergence Center, Gyeongnam Technopark, <sup>4</sup>Department of Opto-mechatronics Engineering, Pusan National University



**PB07**

**Engineering the Oxide/Metal interface through the insertion of a buffer layer: self-organized formation of CoO nanostructures on Fe(001)**

Alberto Brambilla, Andrea Picone, Dario Giannotti, Marco Finazzi, Lamberto Duò, Franco Ciccacci

Dipartimento Di Fisica, Politecnico Di Milano



**PB09**

**Fabrication of metal-nanopillar nanostructures for plasmomechanical applications**

Zubair Buch, Pedram Sadeghi, Silvan Schmid

TU Wien



**PB11**

**Selective electrochemical wet etching for 3D Ni/Cu electrode**

Seon-Yong Hwang, Hyeong-Ho Park, Ji Hwang Lee, Chang-Hwan Kim, Keun-Woo Lee, Ho Kwan Kang  
Korea Advanced Nanofab Center



**PB13**

**Evaluation of etching characteristics on titanium-assisted chemical vapor etching of silicon dioxide**

Hironobu Nishida, Warisawa Shinichi, Kometani Reo  
Graduate School Of Frontier Sciences, The University Of Tokyo



**PB15**

**Emerging ultrafast-laser-assisted and conductive nanofiber fabrication on flexible graphene-based substrate for gas detection**

Tien-li Chang<sup>1</sup>, Cheng-Ying Chou<sup>1</sup>, Ya-Wei Lee<sup>2</sup>, Jing-Yi Yang<sup>1</sup>

<sup>1</sup>Department of Mechatronic Engineering, National Taiwan Normal University, <sup>2</sup>Department of Mechanical and Aerospace Engineering, Chung Cheng Institute of Technology, National Defense University



**TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)**

**PB - Nanofabrication**

**PB02**

**Nanostructure fill with conductive transparent oxide with supercritical CO<sub>2</sub> intending to applying to porous Si-based light emitting devices**

Eiichi Kondoh<sup>1</sup>, Akemi Shioda<sup>1</sup>, Lianhua Jin<sup>1</sup>, Bernard Gelloz<sup>2</sup>

<sup>1</sup>University of Yamanashi, <sup>2</sup>Nagoya University



**PB04**

**Towards Faster EBID Growth Using MeCpPtMe<sub>3</sub> in a Desktop SEM**

Aya Mahgoub, C.W Hagen

Tu Delft



**PB08**

**Silicon Oxide Compatible Etching Process For Oxynitride And Silicon Nitride**

Irina Kiryushina, Andrey Islyaykin, Yury Ozerin

MERI JSC



**PB10**

**Study on X-ray radiolysis-induced-chemical reaction at interface between liquid and substrate for additive manufacturing process**

Akinobu Yamaguchi<sup>1</sup>, Ikuya Sakurai<sup>2</sup>, Ikuo Okada<sup>2</sup>, Mari Ishihara<sup>3</sup>, Takao Fukuoka<sup>1</sup>, Kelvin Elphick<sup>4</sup>, Edward Jackson<sup>4</sup>, Atsufumi Hirohata<sup>4</sup>, Yuichi Utsumi<sup>1</sup>

<sup>1</sup>University of Hyogo, <sup>2</sup>Nagoya University, <sup>3</sup>Hyogo Prefectural Institute of Technology, <sup>4</sup>University of York



**PB12**

**Surface Effect on the Operation of a NEMS Switch**

Sepeedeh Shahbeigi Roudposhti<sup>1</sup>, Sertac Guneri Yazgi<sup>1</sup>, Martin Hofmann<sup>2</sup>, Mahmut Bicer<sup>1</sup>, Mohammad Nasr Esfahani<sup>3</sup>, Ivo W. Rangelow<sup>2</sup>, B. Erdem Alaca<sup>1,4</sup>

<sup>1</sup>Dept. of Mechanical Engineering, Koc University, <sup>2</sup>Dept. Micro- and Nanoelectronics Systems, Ilmenau University of Technology, <sup>3</sup>WMG, University of Warwick, <sup>4</sup>KUYTAM, Surface Science and Technology Center, Koc University



**PB16**

**Metallic ink composed of nickel-silver core-shell nanoparticles for preparation of conductive coating**

Anna Pajor-świerzy<sup>1</sup>, Robert Socha<sup>1</sup>, Radosław Pawłowski<sup>2</sup>, Piotr Warszyński<sup>1</sup>, Krzysztof Szczepanowicz<sup>1</sup>

<sup>1</sup>Jerzy Haber Institute of Catalysis and Surface Chemistry Polish Academy of Sciences, <sup>2</sup>Abraxas Jeremiasz Olgierd



**PB18**

**Optimal fabrication and characterization of YAG:Ce nanopowders for LED lighting**

Ya-Wei Lee<sup>1</sup>, Tien-Li Chang<sup>2</sup>, Su-Hsen Wu<sup>1</sup>

<sup>1</sup>National Defense University, <sup>2</sup>National Taiwan Normal University, <sup>3</sup>National Defense University



**PB20**

**Hybrid Plasmonic Nanostructures via Block Copolymer Nanopatterning**

Andrew Selkirk<sup>1</sup>, Cian Cummins<sup>2</sup>, Niall McEvoy<sup>1</sup>, Mick Morris<sup>1</sup>, Parvaneh Mokarian-Tabari<sup>1</sup>

<sup>1</sup>Trinity College, The University of Dublin, <sup>2</sup>Université de Bordeaux



**WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)**

**PB17**

**Transparent Super Water-Repellent Surface using ZnO Nanorod**

Hwa-Min Kim<sup>1</sup>, Changhyun Lee<sup>1</sup>, Jiseon Kwon<sup>1</sup>, Sunyoung Sohn<sup>2</sup>, Jongjae Kim<sup>1</sup>, Chanseob Cho<sup>3</sup>, Bonghwan Kim<sup>1</sup>

<sup>1</sup>Daegu Catholic University, <sup>2</sup>Pohang University of Science and Technology, <sup>3</sup>Kyungpook National University

**PB19**

**Effective Growth of Pure Long-straight Boron Nitride Nanowires strain and application as humidity sensor**

Dr Ling Li, Cuicui Zhuang, Xiangqian Jiang

Harbin Institute of technology

**PB21**

**The Path to Molecularly Precise Self-Assembly**

Michael Zwolak, Jacob Majikes, James Alexander Liddle

NIST

**PB23**

**Study of the fabrication of vertical GaN nanowire transistors**

George Doundoulakis<sup>1,2</sup>, Adam Adikimenakis<sup>1,2</sup>, Antonios Stavrinidis<sup>2</sup>, Katerina Tsagaraki<sup>2</sup>, Maria Androulidaki<sup>2</sup>, Fabrice Iacovella<sup>2</sup>, George Deligeorgis<sup>2</sup>, George Konstantinidis<sup>2</sup>, Alexandros Georgakilas<sup>1,2</sup>

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**PB25**

**Substrate effects in selective area growth of GaN nanowires by plasma-assisted molecular beam epitaxy**

Adam Adikimenakis<sup>1,2</sup>, George Doundoulakis<sup>1,2</sup>, Savvas Eftychis<sup>1,2</sup>, Katerina Tsagaraki<sup>1</sup>, Maria Androulidaki<sup>1</sup>, Alexandros Georgakilas<sup>1,2</sup>

<sup>1</sup>FORTH, <sup>2</sup>University of Crete

**PB27**

**Complicated micro-, nanostructure of fine crystalline spots in thin amorphous films formed by e-beam**

Vladimir Kolosov

Ural Federal University

**PB29**

**3D greyscale e-beam lithography for the template of a round shape Kinoform lens in X-ray**

Zhiqiang Chen<sup>1</sup>, Jingyuan Zhu<sup>1</sup>, Xudi Wang<sup>2</sup>, Yifang Chen<sup>1</sup>

<sup>1</sup>220 Handan Rd., Yangpu District, <sup>2</sup>School of Mechanical and Automobile Engineering, Hefei University of Technology

**TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)**

**PB22**

**Investigation of morphological and structural properties of hot-wire deposited molybdenum sulphide thin films**

Giorgos Papadimitropoulos, A. Balliou, Dimitris Davazoglou, Dimitris N. Kouvatatos

NCSR Demokritos

**PB24**

**Subtractive Plasma Nano-Assembly: A New Method for Precision Control of Surface Nanotopography**

Angelos Zeniou<sup>1,2</sup>, Evangelos Gogolides<sup>1</sup>, Vassilios Constantoudis<sup>1</sup>

<sup>1</sup>INN, NCSR Demokritos, <sup>2</sup>Department of Physics, University of Patras

**PB26**

**Ion beam implanted Germanium nanowires**

Ahmad Echresh<sup>1,2</sup>, Yufang Xie<sup>1</sup>, Slawomir Prucnal<sup>1</sup>, Lars Rebohle<sup>1</sup>, Yordan M. Georgiev<sup>1,3</sup>

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**PB28**

**HD-DVD Based Microscale 3D Printer**

Tien-Jen Chang, Lukas Vaut, Martin Voss, Line Hagner Nielsen, En-Te Hwu, Anja Boisen

The Danish National Research Foundation and Villum Foundation's Center for Intelligent Drug Delivery and Sensing Using Microcontainers and Nanomechanics (IDUN), Department of Health Technology, Technical University of Denmark

**PB30**

**FIB-induced Origami Assembling Diverse 3D Micro/nanostructures**

Junjie Li<sup>1,2</sup>, Changzhi Gu<sup>1,2</sup>, Ruhao Pan<sup>1,2</sup>

<sup>1</sup>Beijing National Laboratory for Condensed Matter Physics, Institute of Physics, Chinese Academy of Sciences, <sup>2</sup>School of Physical Sciences, CAS Key Laboratory of Vacuum Physics, University of Chinese Academy of Sciences

**PB32**

**3D-microfabrication of pyrolytic carbon electrodes combining additive manufacturing and UV lithography**

Jesper Yue Pan<sup>1</sup>, Babak Rezaei<sup>1</sup>, Thomas Aarøe Anhøj<sup>1</sup>, Niels Bent Larsen<sup>2</sup>, Stephan Sylvest Keller<sup>1</sup>

<sup>1</sup>Technical University of Denmark, <sup>2</sup>DTU HealthTech, Department of Health Technology

**PB34**

**The high sensitive sensor of refractive index based on 3D metamaterials fabricated by ion beam irradiation**

Changzhi Gu, Haifang Yang, Junjie Li

Chinese Academy of Sciences

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PB31**

**Combination of two-photon 3D printing and inkjet printing for steroid coating drug-eluting implant**

Jongmoon Jang<sup>1</sup>, Christopher Tse<sup>1</sup>, Jeong Hun Jang<sup>2</sup>,  
 Hongsoo Choi<sup>3,4</sup>, Jürgen Brugger<sup>1</sup>

<sup>1</sup>Microsystem Laboratory, École Polytechnique Fédérale De Lausanne (EPFL), <sup>2</sup>Dep't of Otolaryngology, Ajou University School of Medicine, <sup>3</sup>Dep't of Robotics Engineering, Daegu Gyeongbuk Institute of Science and Technology (DGIST), <sup>4</sup>DGIST-ETH Microrobot Research Center, DGIST

**PB35**

**Large-scale 3D plasmonic sub-10 nm-gap arrays based on stress-induced nanocrack**

Ruhao Pan<sup>1,2</sup>, Junjie Li<sup>1,2</sup>, Changzhi Gu<sup>1,2</sup>

<sup>1</sup>Beijing National Laboratory for Condensed Matter Physics, Institute of Physics, Chinese Academy of Sciences, <sup>2</sup>School of Physical Sciences, CAS Key Laboratory of Vacuum Physics, University of Chinese Academy of Sciences

**PB37**

**Growth of porous nanofiber structure via layer-by-layer self-assembly under ionic effects for antireflective and antifogging coatings**

Kengo Manabe<sup>1,2</sup>, Seimei Shiratori<sup>2</sup>

<sup>1</sup>Advanced Manufacturing Research Institute, National Institute of Advanced Industrial Science and Technology,

<sup>2</sup>Center for Material Design Science, School of Integrated Design Engineering, Keio University

**PB39**

**Fabrication of robust PDMS microstructure with hydrophobic properties**

Nithi Atthi, Witsaroot Sripumkhai, Pattaraluck Pattamang, Oraphan Thongsook, Saranya Suntalelat, Jirawat Jantawong, Rattananwan Meananeatra, Jakrapong Supadech, Nipapan Klunngien, Wutthinan Jeamsaksiri

Thai Microelectronics Center (TMEC), National Electronics and Computer Technology Center (NECTEC)

**PB41**

**Fabrication of metamaterial structure with morpho butterfly effect using standing wave effect**

Tomoki Nishino<sup>1</sup>, Hiroshi Tanigawa<sup>2</sup>, Atsushi Sekiguchi<sup>2</sup>, Hiroyuki Mayama<sup>3</sup>

<sup>1</sup>Ritsumeikan University, <sup>2</sup>The Research Organization of Science and Technology, Ritsumeikan University,

<sup>3</sup>Department of Chemistry, Asahikawa Medical University

**PB43**

**Nanoporous Ag Films for Surface-Enhanced Raman Scattering for Biosensors**

Sungho Yun<sup>1,2</sup>, HyeongJu Kim<sup>1</sup>, Dongin Lee<sup>3</sup>, Bonghwan Kim<sup>4</sup>, Chanseob Cho<sup>1</sup>

<sup>1</sup>Kyungpook National University, <sup>2</sup>Kwang-Lim Precision,

<sup>3</sup>Yeungnam University, <sup>4</sup>Daegu Catholic University

**PB45**

**Putting Cassie under Pressure**

Sankara Narayana Moorthi Arunachalam, Ratul Das, Zain Ahmad, Jamilia Nauruzbayeva, Himanshu Mishra

King Abdullah University Of Science & Technology

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PB38**

**Patterning and Pattern Transfer of Antireflective Nanostructures for Optical Glasses based on self-organized block copolymer masks**

Florian Schlachter<sup>1</sup>, Jens Bolten<sup>1</sup>, Gaulthier Rydzek<sup>2</sup>, Parvaneh Mokarian<sup>2</sup>, Max Christian Lemme<sup>1,3</sup>

<sup>1</sup>Amo GmbH, <sup>2</sup>AMBER and School of Chemistry, CRANN Institute, Trinity College Dublin, <sup>3</sup>Electronic Devices, RWTH Aachen University

**PB40**

**Pedestal-Shaped Microfluidic Nozzles to facilitate Contact Line Pinning during Electrohydrodynamic processing of Liquids**

Bjorn T.H. Borgelink, Erwin J.W. Berenschot, Cristian S. Deenen, Remco G.P. Sanders, Niels R. Tas, Han J.G.E. Gardeniers

Mesoscale Chemical Systems, University of Twente

**PB42**

**High Fidelity and Sustainable Anti-Reflective Moth-eye Nanostructures and Large Area Sub-Wavelength Applications**

Shuhao Si<sup>1</sup>, Martin Hoffmann<sup>2</sup>

<sup>1</sup>Technische Universität Ilmenau, <sup>2</sup>Ruhr-Universität Bochum

**PB44**

**Silicon surface modification for covalent attachment of molecules via strain-promoted azide-alkyne click chemistry reaction**

Fotini Vrettou<sup>1,2</sup>, Panagiota Petrou<sup>2</sup>, Sotirios Kakabakos<sup>2</sup>, Panagiotis Argitis<sup>3</sup>, Margarita Chatzichristidi<sup>1</sup>

<sup>1</sup>National And Kapodistrian University Of Athens, <sup>2</sup>Immunoassay/Immunosensors Lab, INRASTES, NCSR Demokritos, <sup>3</sup>Institute of Nanoscience and Nanotechnology, NCSR Demokritos

**PB46**

**Surface modification and microfabrication of piezoelectric fluorinated polymers by proton beam writing**

Yoshitaka Nojiri<sup>1</sup>, Yoshikazu Koike<sup>1</sup>, Yasuyuki Ishii<sup>2</sup>, Hiroyuki Nishikawa<sup>1</sup>

<sup>1</sup>Shibaura Institute of Technology, <sup>2</sup>Institutes for Quantum and Radiological Science and Technology

**PB48**

**Iodine - based etching solution for mercury cadmium telluride material**

Olga Markowska<sup>1</sup>, Jarosław Rutkowski<sup>1</sup>, Jerzy Ciosek<sup>2</sup>

<sup>1</sup>Institute of Applied Physics, Military University of Technology, <sup>2</sup>Institute of Optoelectronics, Military University of Technology

**PB50**

**Polyelectrolyte multilayer nanosystems for biomedical application**

Krzysztof Szczepanowicz<sup>1</sup>, Tomasz Kruk<sup>1</sup>, Wiktoria Tomali<sup>1</sup>, Aud Bouzga<sup>2</sup>, Christian Simon<sup>2</sup>, Piotr Warszyński<sup>1</sup>

<sup>1</sup>Jerzy Haber Institute Of Catalysis And Surface Chemistry, Polish Academy Of Sciences, <sup>2</sup>SINTEF Material and Chemistry

**WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)**

**PB47**

**Scalable Perfluorocarbon-free Gas Entrapping Surfaces/Membranes**

Zain Ahmad, Ratul Das, Sankara Arunachalam, Ulrich Buttner, Himanshu Mishra

Kaust

**PB49**

**Nanostructured surfaces for improvement of Laser Transfer process**

Javier Bravo, Javier Clemente

Naitec

**PB51**

**Nanoporous activated carbon cloth for H<sub>2</sub> adsorption, selective CO<sub>2</sub>/CH<sub>4</sub> separation and supercapacitor energy storage**

Nikolaos Kostoglou<sup>1</sup>, Christian Koczwar<sup>1</sup>, Christian Prehal<sup>2</sup>, Biljana Babic<sup>3</sup>, Christos Tampaxis<sup>4</sup>, Georgia Charalambopoulou<sup>4</sup>, Theodore Steriotis<sup>4</sup>, Kyriaki Polychronopoulou<sup>5</sup>, Georgios Constantinides<sup>6</sup>, Oskar Paris<sup>1</sup>, Claus Rebholz<sup>7</sup>, Christian Mitterer<sup>1</sup>

<sup>1</sup>Montanuniversität Leoben, <sup>2</sup>Graz University of Technology,

<sup>3</sup>University of Belgrade, <sup>4</sup>National Center for Scientific Research Demokritos, <sup>5</sup>Khalifa University of Science and Technology, <sup>6</sup>Cyprus University of Technology, <sup>7</sup>University of Cyprus

**PB53**

**Atmospheric plasma etching of nanocomposite materials for fabrication of superhydrophobic, antireflective and antibacterial surfaces**

Panagiotis Dimitrakellis<sup>1</sup>, Georgia Kaprou<sup>1</sup>, Dimitrios Mastellos<sup>2</sup>, Angeliki Tserepi<sup>1</sup>, Evangelos Gogolides<sup>1</sup>

<sup>1</sup>Institute of Nanoscience And Nanotechnology, NCSR 'Demokritos', <sup>2</sup>Institute of Nuclear & Radiological Sciences & Technology, Energy & Safety, NCSR 'Demokritos'

**PB55**

**Antifogging and optically switching, micro-nano structured surfaces**

Maria-Martha Tzianou, Giannis Thomopoulos, Dimitris Nioras, Kosmas Ellinas, Nikos Vourdas, Evangelos Gogolides

Institute of Nanoscience and Nanotechnology NCSR Demokritos

**PB57**

**Fabrication of functional separator via graphene oxide induced surface modification for lithium ion battery**

Ju Young Kim, Dong Ok Shin, Kwang Man Kim, Jimin Oh, Jumi Kim, Seok Hun Kang, Myeong Ju Lee, Young-Gi Lee

Electronics and Telecommunications Research Institute

**PB59**

**Impedance spectroscopy of diamond based nanomaterials and nanostructures**

Ruoying Zhang<sup>1</sup>, Aude Cumont<sup>1</sup>, Dongyu Li<sup>1</sup>, Nikolaos Kehagias<sup>2</sup>, Haitao Ye<sup>1</sup>

<sup>1</sup>University of Leicester, <sup>2</sup>Catalan Institute of Nanoscience and Nanotechnology

**TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)**

**PB52**

**Dew water harvesting from micro-nanotextured surfaces**

Dimitris Nioras, Giannis Thomopoulos, Maria Tzianou, Nikos Vourdas, Kosmas Ellinas, Evangelos Gogolides  
Institute of Nanoscience and Nanotechnology, NCSR Demokritos

**PB54**

**Ultra-low friction droplet motion on micro-nanostructured superhydrophobic surfaces**

Panagiotis Sarkiris<sup>1</sup>, Kosmas Ellinas<sup>1</sup>, Dimitris Gkiolas<sup>2</sup>, Dimitrios Mathioulakis<sup>2,3</sup>, Evangelos Gogolides<sup>1</sup>

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**PB58**

**A novel bio-inspired Triple hierarchical Superhydrophobic Surface (TriSS)**

Soochan Chung, Cameron Riley, Hayden Taylor

University of California, Berkeley

**PB60**

**Cyclic deformation behaviour of Ti alloys by using micro-sized specimens**

Takashi Nagoshi, Hajime Kishimoto, Akihisa Harada

National Institute of Advanced Industrial Science and Technology

**PB62**

**First-principles study on different types of 2D-MoS<sub>2</sub>-based nanocatalysts for the oxygen reduction reaction**

Jiamu Cao<sup>1,2</sup>, Junyu Chen<sup>1</sup>, Jing Zhou<sup>1</sup>, Shaoxuan Zhong<sup>1,2</sup>, Luwen Zhang<sup>1</sup>, Junfeng Liu<sup>1</sup>

<sup>1</sup>Harbin Institute of Technology, <sup>2</sup>Key Laboratory of Microsystems and Micro-Structures Manufacturing, Ministry of Education

**PB64**

**Dominating role of Rapid Heating rate on the Pt/rGO Nanocatalysts Synthesised by microwave assistant for Highly Enhanced Catalytic Properties**

Jing Zhou<sup>1</sup>, Jiamu Cao<sup>1,2</sup>, Junyu Chen<sup>1</sup>, Junfeng Liu<sup>1</sup>, Yufeng Zhang<sup>1,2</sup>

<sup>1</sup>MEMS Center, Harbin Institute of Technology, <sup>2</sup>School of electronics and information engineering, Harbin Institute of Technology

**PB66**

**Combining bottom-up and top-down approaches with micro X-ray fluorescence spectroscopy for controllable fabrication of periodic ZnO nanostructures**

George P. Papageorgiou<sup>1,2</sup>, Andreas Karydas<sup>3</sup>, Vassiliki Kantarelou<sup>3</sup>, George Papageorgiou<sup>1</sup>, Eleni Makarona<sup>1</sup>

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<sup>3</sup>Institute of Nuclear and Particle Physics, NCSR Demokritos

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PB63**

**Sensing of Hydrogen by two-dimensional doped-2H MoS<sub>2</sub> and pristine-1T MoS<sub>2</sub>: A first-principles study**

Junyu Chen<sup>1</sup>, Jing Zhou<sup>1</sup>, Jiamu Cao<sup>1,2</sup>, Shaoxuan Zhong<sup>1,2</sup>, Luwen Zhang<sup>1</sup>, Junfeng Liu<sup>1</sup>, Yufeng Zhang<sup>1,2</sup>

<sup>1</sup>MEMS Center, Harbin Institute of Technology, <sup>2</sup>Key Laboratory of Micro-systems and Micro-Structures Manufacturing, Ministry of Education

**PB65**

**Formation of MoS<sub>2</sub> nanostructure arrays using anodic aluminium oxide template**

Takaki Okamoto<sup>1</sup>, Tomohiro Shimizu<sup>1</sup>, Takeshi Ito<sup>1</sup>, Koichi Takase<sup>2</sup>, Shoso Shingubara<sup>1</sup>

<sup>1</sup>Kansai University, <sup>2</sup>Nihon University

**PB67**

**Temperature Dependent (83-533 K) Raman Spectroscopy Analysis of MoS<sub>2</sub> Monolayers on Si/SiO<sub>2</sub> and Glass Substrates**

Merve Öper, Hüseyin Sar, Feridun Ay, Nihan Kosku Perkgoz

Eskisehir Technical University

**PB69**

**Mapping of charge distribution by Kelvin probe force microscopy on graphene field effect transistor at controlled relative humidity**

Vojtěch Švarc<sup>1,2</sup>, Miroslav Bartošík<sup>1,2</sup>, Martin Konečný<sup>1,2</sup>, Jakub Sadilek<sup>1</sup>, Tomáš Šikola<sup>1,2</sup>

<sup>1</sup>Central European Institute of Technology - Brno University of Technology (CEITEC BUT), <sup>2</sup>Institute of Physical Engineering, Brno University of Technology

**PB71**

**Stacked electrophoretic deposited graphene supercapacitors**

Laigui Hu, Muhammad Zaheer, Ran Liu

Fudan University

**PB73**

**Growth and characterization of nanocrystalline and nanoparticle Hafnium films**

Menelaos Tsikourakos<sup>1</sup>, Athanasios Housiadis<sup>1</sup>, Thomas Kehagias<sup>2</sup>, Philomela Komninou<sup>2</sup>, Dimitris Tsoukalas<sup>1</sup>

<sup>1</sup>National Technical University of Athens, <sup>2</sup>Aristotle University of Thessaloniki

**PB77**

**Study on nanoimprint technology of plant structure with super water repellent structure**

Atsushi Sekiguchi<sup>1,2</sup>, Tomoki Nishino<sup>1</sup>, Hitoshi Tanigawa<sup>1</sup>, Hiroko Minami<sup>2</sup>, Japan Yoko Matsumoto<sup>2</sup>

<sup>1</sup>Ritsumeikan University, <sup>2</sup>Litho Tech Japan Corporation

**PB79**

**Subwavelength transmissive surface-relief gratings for spiral phase-contrast microscopy**

Einstom Engay<sup>1</sup>, Larissa Vertchenko<sup>1</sup>, Dewang Huo<sup>1,2</sup>, Alexandre Wetzel<sup>3</sup>, Ada-loana Bunea<sup>3</sup>, Andrei Lavrinenko<sup>1</sup>

<sup>1</sup>Technical University of Denmark, DTU Fotonik, <sup>2</sup>Harbin Institute of Technology, Department of Physics, Institute of Modern Optics, <sup>3</sup>Technical University of Denmark, DTU Nanolab

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PB68**

**Engineered bottom-up fabrication of Tin Selenide Nanostructures: ranging from 2D to 1D**

Subhajit Biswas<sup>1,2</sup>, Fionan Davitt<sup>1,2</sup>, Gillian Reid<sup>3</sup>, Justin D. Holmes<sup>1,2</sup>

<sup>1</sup>School of Chemistry, University College Cork (UCC),

<sup>2</sup>AMBER@CRANN, Trinity College Dublin, <sup>3</sup>School of Chemistry, University of Southampton

**PB70**

**Single layer reduced graphene oxide transferred by Langmuir-Blodgett and patterned by Electron Beam Lithography at wafer scale**

Adrian Martinez-Rivas<sup>1</sup>, Aldo Armando Rosales Hernández<sup>2</sup>, Narciso Muñoz-Aguirre<sup>3</sup>, Donato Valdez-Pérez<sup>2</sup>

<sup>1</sup>CIC-Instituto Politécnico Nacional, <sup>2</sup>ESIME-Zacatenco, Instituto Politécnico Nacional, <sup>3</sup>ESIME-Azcapotzalco, Instituto Politécnico Nacional

**PB76**

**Study of laparoscopic scope camera lens with antifouling function using metamaterial structure**

Tomoki Nishino<sup>1</sup>, Hiroshi Tanigawa<sup>2</sup>, Atsushi Sekiguchi<sup>2</sup>, Hiroyuki Mayama<sup>3</sup>, Akinari Hinoki<sup>4</sup>, Hiroo Uchida<sup>4</sup>

<sup>1</sup>Ritsumeikan University, <sup>2</sup>The Research Organization of Science and Technology, Ritsumeikan University,

<sup>3</sup>Department of Chemistry, Asahikawa Medical University,

<sup>4</sup>Department of Pediatric Surgery, Nagoya University Graduate School of Medicine

**PB78**

**Optical properties of aluminum nanosquare structures**

Grigoris Zisis<sup>1,2</sup>, Evangelos Almanidis<sup>1</sup>, Emmanouil Panagiotidis<sup>1</sup>, Ioannis Raptis<sup>1,2</sup>, Nikos Papanikolaou<sup>1</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology, NCSR 'Demokritos', <sup>2</sup>ThetaMetris SA

**PB80**

**Optical characterization of printed silver nanocluster wires**

Ryohei Hokari, Kazuma Kurihara, Eiji Higurashi

National Institute of Advanced Industrial Science And Technology (AIST)

**PB82**

**Measuring the complexity of nanostructured surfaces**

Athanasiou Arapisi<sup>1,3</sup>, Vassilios Constantoudis<sup>1,2</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology, NCSR Demokritos, <sup>2</sup>Nanometris, <sup>3</sup>School of Applied Mathematical and Physical Sciences, NTUA

**PB84**

**The Structure and Micro-mechanical Properties of Cobalt Electrodeposited by Micro-compression Test**

Xun Luo<sup>1,2</sup>, Tso-Fu Mark Chang<sup>3</sup>, Masato Sone<sup>3</sup>

<sup>1</sup>College of Materials and Metallurgy, Guizhou University,

<sup>2</sup>Key Laboratory of Light Metal Materials Processing Technology of Guizhou Province, Guizhou Institute of Technology, <sup>3</sup>Institute of Innovative Research, Tokyo Institute of Technology

**WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)**

**PB81**

**Controlling light wavefronts with dielectric meta-surfaces**

Emmanouil Panagiotidis<sup>1,2</sup>, Evangelos Almpanis<sup>1,2</sup>, Nikolaos Papanikolaou<sup>1</sup>, Grigoris Konstantinos Zisis<sup>1</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology, NCSR 'Demokritos', <sup>2</sup>Department of Solid State Physics, National and Kapodistrian University of Athens

**TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)**

**PB86**

**When should we consider the effect of tip size and shape in AFM measurements?**

Andrew A. Vekinis, Vassilis Constantoudis

Institute of Nanoscience and Nanotechnology, NCSR Demokritos

**PB83**

**Dip-in and measure: An alternative approach for the fabrication of metal-coated AFM probes for Tip-Enhanced Raman Spectroscopy**

Diana Davila

IBM Research - Zurich Lab

**PB85**

**Ultra-sensitive interferometric microscope for material analysis and defect detection**

Luc Dömpelmann, Roland A. Terborg, Josselin Pello, Illaria Mannelli, Valerio Pruneri

Icfo

**PB87**

**Investigation of Pt/C freestanding nanowires fabricated in focused electron beam deposition technology**

Piotr Kunicki<sup>1</sup>, Krzysztof Kwoka<sup>1</sup>, Tomasz Piasecki<sup>1</sup>, Sebastian Eberle<sup>2</sup>, Cosmin Roman<sup>2</sup>, Christofer Hierold<sup>2</sup>, Teodor Gotszalk<sup>1</sup>

<sup>1</sup>Wroclaw University of Technology, <sup>2</sup>Swiss Federal Institute of Technology in Zurich

**PB89**

**Three-dimensional silicon nanostructures for photonic applications**

Bingdong Chang, Flemming Jensen, Jörg Hübner,

Henri Jansen

Technical University of Denmark, Kongens Lyngby, Denmark

**PB88**

**Nanometrological Characterization of CuO and NiO Nanostructures of Non-conventional Morphologies: A symmetry-based approach**

Vassilios Constantoudis<sup>1,4</sup>, Ioannis Ioannou-Souglaridis<sup>1,3</sup>, A. Dimou<sup>1,2</sup>, A. Ninou<sup>1,2</sup>, M. Chatzichristidi<sup>2</sup>, E. Makarona<sup>1</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology, NCSR Demokritos, <sup>2</sup>Department of Chemistry, University of Athens, <sup>3</sup>Department of Physics, University of Athens,

<sup>4</sup>Nanometrisis p.c.

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PC - Devices & MEMS**

**PC01**

**Analysis on the Effect of Flake thickness on Photocurrent Efficiency and Photoresponsivity of ReS<sub>2</sub> Field-effect Transistors**

Ji-Hoon Shon, Young-Sun Moon, Soo-Jin Kim, Gyu-Tae Kim  
 Korea University

**PC03**

**Design of multi-layer single-electron circuit mimicking behavior of bubble film for solving Steiner tree problem**

Nobuhiko Kurata, Takahide Oya  
 Graduate School Of Engineering Science, Yokohama National University

**PC05**

**Suppression of E-field crowding in gate oxide of 1.2 kV SiC trench MOSFETs using double p-base structure**

Ogyun Seok<sup>1</sup>, Min-Woo Ha<sup>2</sup>, In Ho Kang<sup>1</sup>, Hyoung Woo Kim<sup>1</sup>, Wook Bahng<sup>1</sup>

<sup>1</sup>Korea Electrotechnology Research Institute, <sup>2</sup>Department of Electrical Engineering, Myongji University

**PC07**

**Performance Improvement of Ge pFinFETs by Post-Fin-Fabrication Annealing**

Wataru Mizubayashi<sup>1</sup>, Hiroshi Oka<sup>1</sup>, Takahiro Mori<sup>1</sup>, Yuki Ishikawa<sup>1</sup>, Seiji Samukawa<sup>2</sup>, Kazuhiko Endo<sup>1</sup>  
<sup>1</sup>AIST, <sup>2</sup>Tohoku Univ.

**PC09**

**Electrical characterisation of Sm-, Nb-co-doped TiO<sub>2</sub> thin films**

Mariko Murayama<sup>1,2</sup>, Iain Crowe<sup>2</sup>, Simon Hammersley<sup>2</sup>, Vladimir Markevich<sup>2</sup>, Matthew Halsall<sup>2</sup>, Anthony Peaker<sup>2</sup>, Kenji Sato<sup>1</sup>, Shogo Iwana<sup>1</sup>, Keita Shiraishi<sup>1</sup>, Shuji Komuro<sup>3</sup>, Masashi Ishii<sup>4</sup>, Xinwei Zhao<sup>1</sup>

<sup>1</sup>Tokyo University Of Science, <sup>2</sup>Photon Science Institute and School of Electrical and Electronic Engineering, University of Manchester, <sup>3</sup>Faculty of Science and Engineering, Toyo University, Saitama, <sup>4</sup>National Institute for Materials Science (NIMS)

**PC13**

**Ferromagnetic/Ferroelectric heterojunction-induced modulation of magnetic properties of artificial magnets**

Akinobu Yamaguchi<sup>1</sup>, Ryo Nakamura<sup>1</sup>, Shunya Saegusa<sup>1</sup>, Keisuke Yamada<sup>2</sup>, Tsunemasa Saiki<sup>3</sup>, Aiko Nakao<sup>1</sup>, Yuichi Utsumi<sup>1</sup>, Takeshi Ogasawara<sup>4</sup>, Masaki Oura<sup>5</sup>, Takuo Ohkouchi<sup>6</sup>

<sup>1</sup>University Of Hyogo, <sup>2</sup>Gifu University, <sup>3</sup>Hyogo Prefectural Institute of Technology, <sup>4</sup> National Institute of Advanced Industrial Science and Technology, <sup>5</sup>RIKEN, <sup>6</sup>Japan Synchrotron Radiation Research Institute

**PC15**

**Fabrication and Characterization of Reconfigurable Field Effect Transistors**

Bilal Khan<sup>1,2</sup>, Slawomir Prucnal<sup>1</sup>, René Hübner<sup>1</sup>, Artur Erbe<sup>1</sup>, Yordan M. Georgiev<sup>1,3</sup>

<sup>1</sup>Institute Of Ion Beam Physics And Materials Research, HZDR, <sup>2</sup>International Helmholtz Research School for Nanoelectronic Network, HZDR, <sup>3</sup>Institute of Electronics at Bulgarian Academy of Sciences, 72, Tsarigradsko chausse blvd.

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PC - Devices & MEMS**

**PC02**

**Impact of Roughness of TiN bottom electrode on the forming voltage of HfO<sub>2</sub> based Resistive Memories**

Christelle Charpin-Nicolle<sup>1</sup>, Marceline Bonvalot<sup>2</sup>, Romain Sommer<sup>1</sup>, Alain Persico<sup>1</sup>, Maryline Cordeau<sup>1</sup>, Samia Belahcen<sup>2</sup>, Brice Eychenne<sup>2</sup>, Philippe Blaise<sup>1</sup>, Sébastien Martinie<sup>1</sup>, Sophie Bernasconi<sup>1</sup>, Eric Jalaguier<sup>1</sup>, Etienne Nowak<sup>1</sup>

<sup>1</sup>CEA-LETI, <sup>2</sup>CNRS-LTM

**PC04**

**Effects of Negative Bias Stress on Electrical Characteristics of 4H-SiC MOSFETs**

Hojun Lee<sup>1</sup>, Taeeun Kim<sup>1</sup>, Ogyun Seok<sup>2</sup>, Jeong Hyun Moon<sup>2</sup>, Wook Bahng<sup>2</sup>, Dong-Won Kang<sup>3</sup>, Yong-Sang Kim<sup>4</sup>, Min-Woo Ha<sup>1</sup>

<sup>1</sup>Department of Electrical Engineering, Myongji University, <sup>2</sup>Korea Electrotechnology Research Institute, <sup>3</sup>Department of Energy Systems Engineering Chungang University,

<sup>4</sup>Department of Electrical and Computer Engineering, Sungkyunkwan University

**PC08**

**Wet Etching of ZnO thin films for Transparent Electronic Network**

Ben Daniel Rowlinson<sup>1</sup>, Nor Azlin Ghazali<sup>2</sup>, Joshua Akrofi<sup>1</sup>, Wira Sinuraya<sup>1</sup>, Martin Ebert<sup>1</sup>, Jamie Dean Reynolds<sup>1</sup>, Harold M H Chong<sup>1</sup>

<sup>1</sup>University of Southampton, <sup>2</sup>Universiti Sains Malaysia

**PC10**

**Metallization technique for drain/ source electrodes for complementary organic and ZnO nanoparticle inverter circuits**

Julia Reker<sup>1</sup>, Thorsten Meyers<sup>1</sup>, Fábio F. Vidor<sup>2</sup>, Ulrich Hilleringmann<sup>1</sup>

<sup>1</sup>Paderborn University, <sup>2</sup>Universidade Federal do Rio Grande do Sul

**PC12**

**Improved NBIS of IGZO TFTs by Novel Fluorine Doping Technique**

Kyung-Mo Jung, Jongsu Oh, Kyung Rae Kim, Yong-Sang Kim

Department Of Electrical And Computer Engineering, Sungkyunkwan University

**PC14**

**Synaptic properties of HfO<sub>x</sub> and TaO<sub>y</sub>-based resistive switching multilayer devices**

Dionisis Sakellaropoulos, Panagiotis Bousoulas, Georgios Nikas, Dimitris Tsoukalas

Department of Applied Physics, National Technical University of Athens

**PC16**

**Defect incorporation techniques for oxide-based memristive devices**

Alexander Rogozhin<sup>1</sup>, Andrey Miakonikh<sup>1</sup>, Olga Permyakova<sup>1,2</sup>, Konstantin Rudenko<sup>1</sup>

<sup>1</sup>Valiev Institute of Physics and Technology of Russian Academy of Sciences, <sup>2</sup>Moscow Institute of Physics and Technology



# 45<sup>th</sup> International Conference on Micro & Nano Engineering

23-26 September 2019  
Rhodes, Greece

## Poster Session

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PC17**

**Hydrothermally-developed ZnO pn-homojunctions on Si for optoelectronic applications**

Eleni Makarona, George Papageorgiou

Institute Of Nanoscience And Nanotechnology, NCSR "demokritos"

**PC19**

**Photogating-based position-sensitive detectors with organic semiconductors**

Wei Jin, Zhi-Jun Qiu, Chunxiao Cong, Ran Liu, Laigui Hu

Fudan University

**PC21**

**Red colored electrochromic device**

Juhee Song, Hojun Ryu, JiSu Han, Tae-Youb Kim, Chihun Sung, Seong M. Cho, Sujung Kim, Chi-Sun Hwang, Chil Seong Ah

Electronics and Telecommunications Research Institute

**PC23**

**Electrochemical Deposition as a Tool for Fabrication of Organic and Hybrid Photovoltaics**

Ouacef Charfi<sup>1,3</sup>, Markus Frericks<sup>2,4</sup>, Marko Cehovski<sup>1,3</sup>, Hans-Hermann Johannes<sup>1,3</sup>, Wolfgang Kowalsky<sup>1,3,4</sup>

<sup>1</sup>Technische Universität Braunschweig, Institut für Hochfrequenztechnik, <sup>2</sup>Technische Universität Darmstadt, Materials Science Department, Surface Science Division, <sup>3</sup>Cluster of Excellence PhoenixD (Photonics, Optics, and Engineering - Innovation Across Disciplines), <sup>4</sup>InnovationLab GmbH

**PC25**

**Fabrication and evaluation of synaptic device with 2-D array of MnO<sub>2</sub> nanoparticles**

Takahiko Ban<sup>1</sup>, Yukiharu Uraoka<sup>2</sup>, Shin-ichi Yamamoto<sup>1</sup>

<sup>1</sup>Ryukoku University, <sup>2</sup>Nara Institute of Science and Technology

**PC27**

**Fabrication of plasmonic circuits comprising waveguides, multiplexer, demultiplexer, and detector-integrated MOSFETs**

Mitsuo Fukuda, Yuta Tonooka, Tomohiro Hirano, Masashi Ota, Yasuhiko Ishikawa

Toyohashi University Of Technology

**PC29**

**A long-range plasmonic waveguide with integrated reflector for perpendicular optical interconnect applications**

Laurent Markey, Christian Vernoux, Jean-Claude Weeber, Kamal Hammani, Juan Arocás, Alain Dereux Laboratoire Interdisciplinaire Carnot de Bourgogne

**PC31**

**Fabrication of Void-free Ternary Chalcogenide Microlens Arrays Using PDMS Stamps**

Hoa Xiong, Yunfan Shi, Qian Wang, Dong Wu, Liyang Pan, Zheyao Wang

Tsinghua University/Institute Of Microelectronics

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PC18**

**Experimental and modeling study of FinHEMT transistors based on AlN/GaN/AlN heterostructure**

George Doundoulakis<sup>1,2</sup>, Adam Adikimenakis<sup>1,2</sup>, Antonios Stavrinidis<sup>2</sup>, Katerina Tsagaraki<sup>2</sup>, Maria Androulidaki<sup>2</sup>, George Deligeorgis<sup>2</sup>, George Konstantinidis<sup>2</sup>, Alexandros Georgakilas<sup>1,2</sup>

<sup>1</sup>Department of Physics, University of Crete, <sup>2</sup>Institute of Electronic Structure and Laser (IESL), Foundation for Research and Technology-Hellas (FORTH)

**PC20**

**Improving Stability of Zinc Oxide Nanowire Field Effect Transistors Operating in High Ionic Phosphate Buffered Solution**

Joshua Akrofi, Martin Ebert, Jamie Reynolds, Kai Sun, Ruoyo Hu, Maurits de Planque, Harold Chong

<sup>1</sup>University of Southampton

**PC24**

**Electromigration for memristive devices**

Joseph Lombardo<sup>1</sup>, Simon Collienne<sup>1</sup>, Adrien Petrillo<sup>1</sup>, Emile Fourneau<sup>2</sup>, Ngoc Duy Nguyen<sup>2</sup>, Alejandro V. Silhanek<sup>1</sup>

<sup>1</sup>Experimental Physics of Nanostructured Materials, Q-MAT, CESAM, University de Liège, <sup>2</sup>Solid State Physics - Interfaces and Nanostructures, Q-MAT, CESAM, Université de Liège

**PC26**

**Hot Electron Nanoscopy and spectroscopy (HENs): from probe design to real applications**

Bruno Torre, Andrea Giugni, Marco Allione, Xinyu Zhang, Enzo Di Fabrizio

*King Abdullah University Of Science and Technology*

**PC28**

**Grating integration technologies for edge emitting AlGaAs diode lasers**

Olaf Brox, Jörg Fricke, Hans Wenzel, Pietro Della Casa, Andre Maaßdorf, Markus Weyers, Mathias Matalla, Andrea Knigge

*Ferdinand-Braun-Institut, Leibniz-institut für Höchstfrequenztechnik*

**PC30**

**Experimental and numerical investigation of biosensors plasmonic substrates induced by different fabrication techniques, e-beam, soft and hard UV-NIL**

Jean-Francois Bryche<sup>1,2,3</sup>, Frédéric Hamouda<sup>2</sup>, Mondher Besbes<sup>3</sup>, Philippe Gogol<sup>2</sup>, Julien Moreau<sup>3</sup>, Marc Lamy de la Chapelle<sup>4</sup>, Michael Canva<sup>1</sup>, Bernard Bartenlian<sup>2</sup>

<sup>1</sup>Laboratoire Nanotechnologies Nanosystèmes; CNRS, Université de Sherbrooke, <sup>2</sup>Centre de Nanosciences et de Nanotechnologies; CNRS, Université Paris-Sud, Université Paris-Saclay, <sup>3</sup>Laboratoire Charles Fabry, IOGS, CNRS, Université Paris-Sud, Université Paris-Saclay, <sup>4</sup>Institut des Molécules et Matériaux du Mans; CNRS, Université Le Mans

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PC33**

Nanofabrication of fan-shaped photonic crystal spectrometers with ultrahigh resolution in SOI for the infrared range

Bo Feng, Xunya Jiang, Yifang Chen

Fudan University

**PC37**

Fabrication of metallo-dielectric metamaterials integrating nano-imprinted PMMA pillars

Tiziana Stomeo<sup>1</sup>, Armando Casolino<sup>2</sup>, Francesco Guido<sup>1</sup>, Antonio Qualtieri<sup>1</sup>, Michael Scalora<sup>3</sup>, Antonella D'Orazio<sup>2</sup>, Marco Grande<sup>2</sup>, Massimo De Vittorio<sup>1,4</sup>

<sup>1</sup>CBN - Istituto Italiano Di Tecnologia, <sup>2</sup>Politecnico Di Bari,

<sup>3</sup>Charles M. Bowden Research Center, REDCOM, <sup>4</sup>Università del Salento

**PC39**

An 1800 nm microcavity semiconductor laser

Fangyuan Meng<sup>1,2,3</sup>, Hongyan Yu<sup>1,2,3</sup>, Xuliang Zhou<sup>1,2,3</sup>, Yajie Li<sup>1,2,3</sup>, Pengfei Wang<sup>1,2,3</sup>, Wenyu Yang<sup>1,2,3</sup>, Guangzhen Luo<sup>1,2,3</sup>, Weixi Chen<sup>1</sup>, Jiaqiang Pan<sup>1,2,3</sup>

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Institute of Semiconductors, Chinese Academy of

Science, <sup>2</sup>Center of Materials Science and Optoelectronics

Engineering, University of Chinese Academy of Sciences,

<sup>3</sup>Beijing Key Laboratory of Low Dimensional Semiconductor

Materials and Devices

**PC41**

Fabrication of SU-8 thick microstructures and integrated optics fabrication by e-beam lithography

Luca Businaro, Francesca Romana Bertani, Adele De Ninno, Giorgio Pettinari, Francesco Martini, Annamaria Gerardino

CNR-IFN, Institute for Photonics and Nanotechnologies

**PC43**

Electrochromic window based on the polymer substrate with long term stability for smart auto-vehicle application

Hojun Ryu, Chi-Seong Ah, Ju-Hee Song, Sang-Hoon Cheon

ETRI

**PC45**

Highly efficient surface micromachined infrared absorber with dual-band characteristic for thermoelectric radiation sensors

A. Ihring, G. Zieger, P. Lorenz, S. Stanca, F. Haenschke, D. Blaschke, H. Schmidt

Leibniz Institute of Photonic Technology

**PC47**

Photothermal analysis of direct-write gold nanostructures – How purity and conductivity affect the plasmonic properties?

Mostafa Moonir Shawrav<sup>1</sup>, Miao-Hsuan Chien<sup>1</sup>, Zubair Buch<sup>1</sup>, Philipp Taus, Heinz D. Wanzenboeck<sup>2</sup>, Silvan Schmid<sup>1</sup>

<sup>1</sup>Micro and Nanostensors, Institute of Sensors & Actuators Systems, TU Wien, <sup>2</sup>Institute of Solid State Electronics, TU Wien

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PC32**

Generalized Two-Temperature Fitting Algorithm for Ultrashort Laser Heating of Metal Film and Nanoparticles to spatially and temporally study heat propagation

Paul Bresson<sup>1,2,3</sup>, Jean-françois Bryche<sup>1,2</sup>, Julien Moreau<sup>3</sup>, Mondher Besbes<sup>3</sup>, Paul-Ludovic Karsenti<sup>1,2</sup>, Denis Morris<sup>1,2</sup>, Paul Charette<sup>1,2</sup>, Michael Canva<sup>1,2</sup>

<sup>1</sup>Laboratoire Nanotechnologies Nanosystèmes, CNRS, Université de Sherbrooke, <sup>2</sup>Institut Interdisciplinaire d'Innovations Technologiques 3IT, <sup>3</sup>Laboratoire Charles Fabry, IOGS, CNRS, Université Paris-Sud, Université Paris-Saclay

**PC34**

Refractometric Sensing Using Gradient Plasmonic Nanostructures: Mapping Spectral Information to Spatial Patterns

Siyi Min<sup>1,2</sup>, Shijie Li<sup>1</sup>, Zhouyang Zhu<sup>1</sup>, Chuwei Liang<sup>1</sup>, Jingxuan Cai<sup>1</sup>, Xing Cheng<sup>2</sup>, Wen-Di Li<sup>1</sup>

<sup>1</sup>Department of Mechanical Engineering, The University of Hong Kong, <sup>2</sup>Department of Materials Science and Engineering, Southern University of Science and Technology

**PC36**

Filament-doped thin film electrodes for high-efficiency light-emitting and detecting devices

Tae Geun Kim, Tae Ho Lee, Yong Woon Kim  
Korea University

**PC38**

Silicon nitride nanoantennas for wireless on-chip optical networks

Tiziana Stomeo<sup>1</sup>, Andrea Toma<sup>2</sup>, Antonio Qualtieri<sup>1</sup>, Giovanna Calò<sup>3</sup>, Badrul Alam<sup>3</sup>, Vincenzo Petruzzelli<sup>3</sup>, Gaetano Bellanca<sup>4</sup>, Ali Emre Kaplan<sup>4</sup>, Massimo De Vittorio<sup>1,5</sup>

<sup>1</sup>CBN - Istituto Italiano Di Tecnologia, <sup>2</sup>Istituto Italiano di Tecnologia, <sup>3</sup>Politecnico di Bari, <sup>4</sup>Dipartimento di Ingegneria, Università di Ferrara, <sup>5</sup>Dipartimento Ingegneria dell'Innovazione, Università del Salento

**PC42**

Reversed electrochromic device with blue color in neutral states

Chil Seong Ah, Juhee Song, Hojun Ryu, Tae-Youb Kim, Seong M. Cho, Sujung Kim, Sanghoon Cheon, Joo Yeon Kim, Chi-Sun Hwang<sup>1</sup>  
Electronics And Telecommunications Research Institute (ETRI)

**PC44**

Structured light with angular momentum for excitation of near field hot spots

Marco Allione, Andrea Giugni, Bruno Torre, Enzo Di Fabrizio

Physical Science and Engineering Division, KAUST

**PC46**

Principles for selecting quantum dots with high intrinsic quantum efficiency

Søren Stobbe

Department Of Photonics Engineering, Technical University Of Denmark

**WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)**

**PC49**

Rapid and precise wavelength determination approach based on visually patterned integrated narrow bandpass filters

Zhiyi Xuan<sup>1,2,3</sup>, Ying Zhi<sup>1,3</sup>, Yi Zhang<sup>1,3</sup>, Shaowei Wang<sup>1</sup>, Wei Lu<sup>1,2,3</sup>

<sup>1</sup>State Key Laboratory Of Infrared Physics, Shanghai Institute Of Technical Physics, Chinese Academy Of Sciences,

<sup>2</sup>School of Physical Science and Technology, ShanghaiTech University,

<sup>3</sup>Shanghai Engineering Research Center of Energy-Saving Coatings

**PC51**

Performance of white-light Ce:Y3Al5O12 composite emitters for visible light optical communications

Th. Kamalakis<sup>1</sup>, D. Alexandropoulos<sup>2</sup>, Yongzheng Fang<sup>3</sup>, Yufeng Liu<sup>3</sup>, S. Couris<sup>4</sup>, Jingshan Hou<sup>3</sup>, Nikolaos Vainos<sup>1</sup>

<sup>1</sup>Harokopio University of Athens, Department of Informatics and Telematics, <sup>2</sup>University Of Patras, Dept Materials Science, <sup>3</sup>School of Materials Science and Engineering, Shanghai Institute of Technology, <sup>4</sup>University of Patras, Department of Physics

**PC53**

Transferable dielectric DBR membranes for versatile GaN-based polariton and VCSEL technology

Emmanouil Amargianitakis<sup>1,2</sup>, Stelios Kazazis<sup>2,3</sup>, George Doundoulakis<sup>2,3</sup>, George Stavrinidis<sup>2</sup>, George Konstantinidis<sup>2</sup>, Eric Delamadeleine<sup>4</sup>, Eva Monroy<sup>4</sup>, Nikolaos Pelekanos<sup>1,2</sup>

<sup>1</sup>Department of Materials Science and Technology, University Of Crete, <sup>2</sup>Microelectronics Research Group, IESL-FORTH, <sup>3</sup>Department of Physics, University of Crete,

<sup>4</sup>Université Grenoble-Alpes, CEA, INAC-PHELIQS

**PC55**

Transition metal-based 2D MXenes thin films for plasmonic photodetection

Dhinesh Babu Velusamy, Jehad K. El-Demellawi, Ahmed M. El-Zohry, Andrea Giugni, Sergei Lopatin, Mohamed N. Hedhili, Ahmed E. Mansour, Enzo Di Fabrizio, Omar F. Mohammed, Husam N. Alshareef  
Kaust - King Abdullah University Of Science and Technology

**PC57**

A novel contact-enhanced low-g inertial switch with low-stiffness fixed electrode

Ke Zhai, Liqun Du, Min Han, Weitai Wang, Ming Zhao  
Dalian University of Technology

**PC59**

Processing of piezotronic microstrain sensors on flexible substrates

Stéphanie Girod<sup>1</sup>, Raoul Joly<sup>1,2</sup>, Noureddine Adjeroud<sup>1</sup>, Kevin Menguelti<sup>1</sup>, Mohamed El Hachemi<sup>1</sup>, Patrick Grysan<sup>1</sup>, Sébastien Klein<sup>1</sup>, Jérôme Polesel<sup>1</sup>

<sup>1</sup>Luxembourg Institute of Science and Technology,

<sup>2</sup>University of Luxembourg

**PC61**

Ultra-high sensitive humidity detection using surface enhanced microcantilevers

S. Balasubramanian, K. Prabakar, S. R. Polaki  
Indira Gandhi Centre for Atomic Research

**TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)**

**PC48**

Ultrashort-pulse laser dicing of Glass-Phosphor-glass sheets

Sandra Stroj<sup>1</sup>, Giovanni Piredda<sup>1</sup>, Wolfgang Plank<sup>2</sup>, Martin Muendlein<sup>2</sup>, Matthias Domke<sup>1</sup>

<sup>1</sup>Vorarlberg University of Applied Sciences / Research Center for Microtechnology, <sup>2</sup>ESCATEC Switzerland AG

**PC50**

Ce:Y3Al5O12 phosphor / polymer nanocomposite coatings on microstructures and micromachines by pulsed laser deposition

E. Bagiokis<sup>1</sup>, K. Papachristopoulou<sup>1</sup>, V. Karoutsos<sup>1</sup>, A. Lorusso<sup>2</sup>, Yongzheng Fang<sup>3</sup>, Jingshan Hou<sup>3</sup>, Yufeng Liu<sup>3</sup>, A. Perrone<sup>2</sup>, Nikolaos Vainos<sup>1</sup>

<sup>1</sup>University Of Patras, Dept Materials Science, <sup>2</sup>Dipartimento di Matematica e Fisica "E. De Giorgi", Università del Salento & Istituto Nazionale di Fisica Nucleare, <sup>3</sup>School of Materials Science and Engineering, Shanghai Institute of Technology

**PC52**

Computer generated plasmonic holographic structures for toxin sensing

Nikolaos Vainos<sup>1</sup>, E. Bagiokis<sup>1</sup>, K. Papachristopoulou<sup>1</sup>, J. Jermann<sup>1</sup>, E. Smyrnioti<sup>1</sup>, C. Stathopoulos<sup>2</sup>, D. Papaioannou<sup>3</sup>

<sup>1</sup>University Of Patras, Dept Materials Science, <sup>2</sup>University of Patras, Department of Medicine, <sup>3</sup>University of Patras, Department of Chemistry

**PC54**

Nano-photonic structures for a silicon optical phased array capable of wide-angle and highly-efficient beam-forming operation

Jong-Bum You<sup>1</sup>, Dong-Eun Yoo<sup>1</sup>, Dong-Wook Lee<sup>1</sup>, Young Su Kim<sup>1</sup>, Kyoongsik Yu<sup>2</sup>, Hyo-Hoon Park<sup>2</sup>

<sup>1</sup>National NanoFab Center, <sup>2</sup>KAIST

**PC56**

Ultra miniaturized InterDigitated Electrodes as a platform for sensing applications

Z. Wang<sup>1</sup>, A. Syed<sup>1</sup>, S. Bhattacharya<sup>1</sup>, X. Chen<sup>1</sup>, U. Buttner<sup>1</sup>, G. Ioardache<sup>1</sup>, K. Salama<sup>2</sup>, E. Valamontes<sup>2</sup>, P. Oikonomou<sup>3</sup>, I. Raptis<sup>1,3</sup>, A. Botsialas<sup>3</sup>, M. Sanopoulou<sup>3</sup>

<sup>1</sup>Nanofabrication Core Labs, KAUST, <sup>2</sup>Dept. Electrical & Electronics Eng., University of West Attica, <sup>3</sup>Institute of Nanoscience & Nanotechnology, NCSR 'Demokritos'

**PC58**

Flow sensor and stent integration for evaluating in-situ breathing property at airway in experimental animal

Hayato Noma<sup>1</sup>, Yoshihiro Hasegawa<sup>1</sup>, Kazuhiro Taniguchi<sup>1</sup>, Miyoko Matsushima<sup>2</sup>, Tsutomu Kawabe<sup>2</sup>, Mitsuhiro Shikida<sup>1</sup>

<sup>1</sup>Hiroshima City University, <sup>2</sup>Nagoya University

**PC60**

Integration of carbon nanotube-based sensors to a flip-chip package for micro-strain detection in microelectronic package

Julien Pezard<sup>1</sup>, Yosri Ayadi<sup>1</sup>, Adham Elshaer<sup>1</sup>, Eric Duchesne<sup>2</sup>, Hélène Frémont<sup>3</sup>, Dominique Drouin<sup>1</sup>

<sup>1</sup>3IT, Universite de Sherbrooke, Sherbrooke, J1K 2R1, QC, Canada, <sup>2</sup>IBM Canada Ltd, 23 boul. de l'Aéroport, Bromont, J2L 1A3, QC, Canada, <sup>3</sup>IMS, Université Bordeaux, 351, cours de La Libération 33405 Talence cedex, FRANCE

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PC63**

**Nanomaterial based Flow-sensor for easy microfluidic chip integration**

Evangelos Skotadis<sup>1</sup>, Lampros Patsiouras<sup>1</sup>, Emmanouil Kousoulas Artouro Vargkas<sup>1</sup>, Evangelos Aslanidis<sup>1</sup>, Georgia Kaprou<sup>2</sup>, Angeliki Tserepi<sup>2</sup>, Dimitris Tsoukalas<sup>1</sup>

<sup>1</sup>National Technical University of Athens, <sup>2</sup>Institute of Nanoscience and Nanotechnology, NCSR Demokritos

**PC65**

**Thermal flow sensor operated under 40 degrees Celsius for controlling small dosing rate in drip infusion system**

Chihiro Shimohira<sup>1</sup>, Yoshihiro Hasegawa<sup>1</sup>, Kazuhiro Taniguchi<sup>1</sup>, Miyoko Matsushima<sup>2</sup>, Tsutomu Kawabe<sup>2</sup>, Mitsuhiro Shikida<sup>1</sup>

<sup>1</sup>Hiroshima City University, <sup>2</sup>Nagoya University

**PC67**

**Mode-Matched Single-Crystal Lithium Niobate Disk Resonator for High-Performance Gyroscope**

Kazutaka Obitani<sup>1</sup>, Toshiyuki Tsuchiya<sup>1</sup>, Kazutaka Araya<sup>2</sup>, Masanori Yachi<sup>3</sup>

<sup>1</sup>Department of Microengineering, Kyoto University,

<sup>2</sup>TAMAGAWA SEIKI Co., Ltd., <sup>3</sup>TAMAGAWA MOBILE EQUIPMENT Co., Ltd.

**PC69**

**A Highly Sensitive Pressure Sensor Based on Carbon Nanotubes and Polymer Composite**

Tallis H. da Costa, Jin-Woo Choi

Louisiana State University

**PC71**

**Electrochemical hydrogen sensors with wide detection ranges for hydrogen fuel cell vehicle application**

Soon-Won Jung, Yoon-Ee Jo, Ms Hye Ryun Yoon, Seung-Yun Lee

Hanbat National University

**PC73**

**Polymeric seed layer as a simple approach for nanostructuring of Ga-doped ZnO films for flexible piezoelectric energy harvesting**

Mariya Aleksandrova

Technical University Of Sofia, Department Of Microelectronics

**PC75**

**A novel polymer super capacitor with high aspect ratio 3D printed sub-millimetres structures**

Giorgio Scordo<sup>1</sup>, Valentina Bertana<sup>1</sup>, Pietro Zaccagnini<sup>1,2</sup>, Alberto Scalia<sup>1</sup>, Andrea Lamberti<sup>1,2</sup>, Stefano Romano<sup>1</sup>, Luigi Simone Marasso<sup>1,3</sup>, Carmelo Nicosia<sup>1</sup>, Luciano Scaltrito<sup>1</sup>, Sergio Ferrero<sup>1</sup>, Fabrizio Pirri<sup>1,2</sup>, Matteo Cocuzza<sup>1,3</sup>

<sup>1</sup>Politecnico di Torino, <sup>2</sup>Istituto Italiano di Tecnologia, <sup>3</sup>CNR-IMEM

**PC77**

**Fabrication of CIGS micro-concentrator solar cell devices**

Pedro Anacleto<sup>1</sup>, D. Siopa<sup>2</sup>, P.J. Dale<sup>2</sup>, S. Sadewasser<sup>1</sup>

<sup>1</sup>INL - Iberian International Nanotechnology Laboratory, <sup>2</sup>Physics and Materials Science Research Unit, Belvieux

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PC62**

**A thermal flow sensor and its signal processing circuit integration onto flexible copper on polyimide substrate**

Ayami Kato<sup>1</sup>, Iori Fujitsuna<sup>1</sup>, Yoshihiro Hasegawa<sup>1</sup>, Kazuhiro Taniguchi<sup>1</sup>, Miyoko Matsushima<sup>2</sup>, Tsutomu Kawabe<sup>2</sup>, Mitsuhiro Shikida<sup>1</sup>

<sup>1</sup>Hiroshima City University, <sup>2</sup>Nagoya University

**PC64**

**Design and performance analysis of a microgravity accelerometer with quasi-zero stiffness characteristic**

Yuxing Duan<sup>1</sup>, Xueyong Wei<sup>1,2</sup>, Minghui Zhao<sup>1</sup>, Ziming Ren<sup>1</sup>, Huiying Zhao<sup>1</sup>, Juan Ren<sup>2</sup>

<sup>1</sup>Xi'an Jiaotong University, <sup>2</sup>Chang'an University

**PC66**

**Piezoresistive strain sensors based on aqueous dispersion of graphene nanoplatelets**

Vasiliki Tsouti, Vasiliki Kekou, Meropi Sanopoulou, Stavros Chatzandroulis

NCSR Demokritos

**PC68**

**Ceramic membrane based integrated systems for power generation and sensing**

Nerea Alayo<sup>1</sup>, Marco Bianchini<sup>1</sup>, Francesco Chiabrera<sup>1</sup>, Iñigo Garbayo<sup>1</sup>, Marc Salleras<sup>3</sup>, Luis Fonseca<sup>3</sup>, Albert Tarancón<sup>1,2</sup>

<sup>1</sup>Irec, <sup>2</sup>ICREA, <sup>3</sup>IMB-CNM (CSIC)

**PC70**

**A 3D Printed Thermal Flow Sensor for Spirometry Applications**

Tzoulian Koutsis, Alexios Psyrris, Grigoris Kaltsas

microSENSES Laboratory, Department of Electrical and Electronic Engineering, University of West Attica

**PC72**

**Transparent Piezoelectric Transducer for Optical Photoacoustic Imaging**

Ya-Han Liu, Fu-Sung Lin, Li-Xiang Chen, Yeong-Her Wang, Chih-Hsien Huang

National Cheng Kung University

**PC74**

**An approach for nanostructuring of piezoelectric materials by template-assisted growth in porous aluminium oxide**

Tsvetozar Tsanev<sup>1</sup>, Maryia Aleksandrova<sup>1</sup>, Boriana Tzaneva<sup>2</sup>, Valentin Videkov<sup>1</sup>

<sup>1</sup>Technical University of Sofia, Department Of Microelectronics, <sup>2</sup>Technical University of Sofia, Department of Chemistry

**PC76**

**Ionic insulating polymer embedded light harvester for morphological control of perovskite solar cells**

Seojun Lee<sup>1</sup>, Saemon Yoon<sup>1</sup>, Jun Ryu<sup>1</sup>, Min-Woo Ha<sup>2</sup>, Yong-Sang Kim<sup>3</sup>, Dong-Won Kang<sup>1</sup>

<sup>1</sup>Chung-Ang University, <sup>2</sup>Myongji University, <sup>3</sup>Sungkyunkwan University



# 45<sup>th</sup> International Conference on Micro & Nano Engineering

23-26 September 2019  
Rhodes, Greece

## Poster Session

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

### PC81

#### Development of a novel low frequency magnetic eccentric pendulum vibration energy harvester for wireless oceanic nodes

Shaoxuan Zhong<sup>1,2</sup>, Jiamu Cao<sup>1,2</sup>, Junyu Chen<sup>1</sup>, Jing Zhou<sup>1</sup>, Luwen Zhang<sup>1</sup>, Junfeng Liu<sup>1</sup>

<sup>1</sup>MEMS Center, Harbin Institute of Technology, Harbin 150001, China, <sup>2</sup>Key Laboratory of Micro-systems and Micro-Structures Manufacturing, Ministry of Education, Harbin 150001, China

### PC83

#### Influence of bi-functional catalyst nanostructures morphology on performances for rechargeable zinc-air battery

Chun-I Lee<sup>1</sup>, Wen Sheng Chang<sup>2</sup>

<sup>1</sup>National Kaohsiung University of Science And Technology, <sup>2</sup>Industrial Technology Research Institute

### PC87

#### Analysis on vertically aligned ZnO Nanorods as composite mechanical springs for an elastic and steady piezoelectric behavior at multiple frequencies

Oscar Gilberto Súchil Pérez, Selene Capula Colindres, Adrian Martinez Rivas, Marco Antonio Ramírez Salinas

Computing Research Center CIC-IPN

### PC89

#### Shunt resistance effects in GaAs/InGaAs core-shell nanowire solar cells

Maria Androulidaki<sup>1</sup>, Emmanouil Manidakis<sup>1,2</sup>, Eleftheria Darivianaki<sup>2</sup>, Zacharias Hatzopoulos<sup>2</sup>, Siew-Li Tan<sup>3,4</sup>, Nikos Pelekanos<sup>1,2</sup>

<sup>1</sup>FORTH/IESL, <sup>2</sup>University of Crete, <sup>3</sup>Université Grenoble-Alpes, <sup>4</sup>National University of Singapore

### PC91

#### Development of novel hydrogels using single-walled carbon nanotubes and phthalocyanine derivatives

Ryota Arakaki, Takahide Oya

Graduate School of Engineering Science, Yokohama National University

### PC93

#### Investigation of laser-ablated flexible graphene film forming temperature sensors

Zhao-Chi Chen, Tien-li Chang, Pin-Chun Lin, Jing-Yi Yang

Department of Mechatronic Engineering, National Taiwan Normal University

### PC95

#### Polyester Textile Based Graphene Pressure Sensor

Xiaoming Wu<sup>1,2</sup>, Yifang Yang<sup>1</sup>, Tianling Ren<sup>1,2</sup>

<sup>1</sup>Tsinghua University, <sup>2</sup>Beijing National Research Center for Information Science and Technology

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

### PC78

#### Nanoimprint Lithography for the Creation of Solar Thermal Absorbers

Tina Mitteramskogler<sup>1</sup>, Michael J Haslinger<sup>1</sup>, Ambiörn Wennberg<sup>2</sup>, Iván F Martínez<sup>2</sup>, Michael Muehlberger<sup>1</sup>, Matthias Krause<sup>3</sup>, Elena Guillén<sup>1</sup>

<sup>1</sup>Profactor GmbH, <sup>2</sup>Nano4Energy SL, <sup>3</sup>Helmholtz-Zentrum Dresden-Rossendorf e.V.

### PC80

#### Nanostructured passivation layers for improved efficiency of CIGS solar cells

Pedro Anacleto<sup>1</sup>, E. Edoff<sup>2</sup>, W.-C. Chen<sup>2</sup>, P.J. Bolt<sup>3</sup>, W. van Boekel<sup>3</sup>, J. van Deelen<sup>3</sup>, Y. Zhou<sup>4</sup>, S. Sadewasser<sup>1</sup>

<sup>1</sup>INL - Iberian International Nanotechnology Laboratory, <sup>2</sup>Uppsala University, dep. Engineering Sciences, Uppsala, <sup>3</sup>TNO, 4 Obducat AB

### PC82

#### Demonstration of high temperature solid oxide fuel cell element based on nanohomogeneous yttria-stabilized zirconia microtubes

Andreas Nölvak<sup>1</sup>, Alexander Vanetsev<sup>1,2</sup>, Gunnar Nurk<sup>3</sup>, Aile Tamm<sup>1</sup>, Glen Kelp<sup>1</sup>, Tanel Tätte<sup>1</sup>

<sup>1</sup>Institute of Physics, University of Tartu, <sup>2</sup>Prokhorov General Physics Institute, <sup>3</sup>Institute of Chemistry, University of Tartu

### PC84

#### Surface modification of triboelectric nanogenerators with ZnO nanoparticles

Vasiliki Prifti, Achilleas Bardakas, Ariadni P. Kerasidou, Christos Tsamis

Inst. of Nanoscience and Nanotechnology, NCSR "Demokritos"

### PC86

#### A micro-structured micro capacitor on Si substrate having large capacitance for an integrated energy harvester

Hiroki Kuwano, V. Krikscikas, A. Sekiguchi, H. Oguchi Tohoku University

### PC88

#### Tuning of imprinting stamps for the fabrication of nano-electrodes for electrochemical CO<sub>2</sub> reduction

Matthias Golibrzuch, Thomas Maier, Katharina Krischer, Markus Becherer

Technical University of Munich

### PC90

#### One-Day Fast-Prototyping Process for Functionalized Membrane Array on Flexible Substrate

Thibault P. Delhaye<sup>1</sup>, Chang Ge<sup>2</sup>, Laurent A. Francis<sup>1</sup>, Edmond Cretu<sup>2</sup>, Denis Flandre<sup>1</sup>

<sup>1</sup>ICTEAM, <sup>2</sup>ECE

### PC92

#### Beat-to-beat pulse wave velocity estimation by soft and flexible Aluminium Nitride based piezoelectric sensor

Lara Natta<sup>1</sup>, Vincenzo Mariano Mastronardi<sup>1</sup>, Prospero Lombardi<sup>3</sup>, Francesco Guido<sup>1,4</sup>, Luciana Algieri<sup>1,4</sup>, Francesco Ciccirillo<sup>5</sup>, Giuseppe Colonna<sup>5</sup>, Marco Di Renzo<sup>3</sup>, Antonio Qualtieri<sup>1</sup>, Massimo De Vittorio<sup>1,2</sup>

<sup>1</sup>Istituto Italiano Di Tecnologia, <sup>2</sup>Università del Salento,

<sup>3</sup>IRCCS Fondazione Don Carlo Gnocchi, <sup>4</sup>Piezoskin S.r.l., <sup>5</sup>Department of interventional cardiology and hemodynamics, "V. Fazzi" hospital

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PC97**

**Fabrication of a Flexible Meander Antenna for Saw Remote Sensing Applications**

Leonardo Lamanna<sup>1,2</sup>, Luigi Piro<sup>1,2</sup>, Ilaria Marasco<sup>3</sup>, Giovanni Niro<sup>3</sup>, Francesco Guido<sup>1</sup>, Luciana Algieri<sup>1</sup>, Vincenzo M. Mastronardi<sup>1</sup>, Antonio Qualtieri<sup>1</sup>, Francesco Rizzi<sup>1</sup>, Massimo De Vittorio<sup>1,2</sup>, Antonella D'Orazio<sup>3</sup>, Marco Grande<sup>3</sup>

<sup>1</sup>Center for Bio-Molecular Nanotechnologies, Istituto Italiano di Tecnologia, <sup>2</sup>Dipartimento di Ingegneria dell'Innovazione, Università del Salento, <sup>3</sup>Dipartimento di Ingegneria Elettrica e dell'Informazione, Politecnico di Bari

**PC99**

**Ni-P/PET Fiber Prepared by Supercritical CO<sub>2</sub> Catalyzed for Wearable Device Applications**

Kenichi Tokuoka<sup>1</sup>, Wan-Ting Chiu<sup>3</sup>, Chun-Yi Chen<sup>1</sup>, Tso-Fu Mark Chang<sup>1</sup>, Akiko Saji<sup>2</sup>, Hiromichi Kurosu<sup>2</sup>, Masato Sone<sup>1</sup>

<sup>1</sup>Tokyo Institute Of Technology, <sup>2</sup>Nara Women's University, <sup>3</sup>The University of Tokyo

**PC101**

**Copper micro-electrode fabrication using laser printing and laser sintering processes for on-chip antennas on flexible integrated circuits**

O. Koritsoglou<sup>1</sup>, I. Theodorakos<sup>1</sup>, F. Zacharatos<sup>1</sup>, M. Makrygianni<sup>1</sup>, D. Kariyapperuma<sup>2</sup>, R. Price<sup>2</sup>, B. Cobb<sup>2</sup>, S. Melamed<sup>3</sup>, A. Kabla<sup>3</sup>, F. de la Vega<sup>3</sup>, I. Zergioti<sup>1</sup>

<sup>1</sup>National Technical University of Athens, Physics Department, <sup>2</sup>PragmatIC, <sup>3</sup>PV Nano Cell Ltd

**PC103**

**The Flexible/Stretchable Interconnection and TFT for AM Micro LED Display**

Jae Bon Koo, Chan Woo Park, Jong-Heon Yang, Sung-Haeng Cho

Electronics and Telecommunications Research Institute (ETRI)

**PC107**

**Ultrafast Laser Ablation of Flexible Graphene Micro-Heater for Wearable Application**

Chien-ping Wang<sup>1</sup>, Ming-Hong Xiao<sup>1</sup>, Tien-Li Chang<sup>2</sup>

<sup>1</sup>Department of Mechanical Engineering, National Taipei University of Technology, <sup>2</sup>Department of Mechatronic Engineering, National Taiwan Normal University

**PC111**

**An integrated fabrication method of micro RF coaxial transmitter on metal substrate combining positive and negative photoresist processes**

Liqun Du<sup>1</sup>, Min Han<sup>2</sup>, Ming Zhao<sup>1</sup>, Chengquan Du<sup>1</sup>

<sup>1</sup>School of Mechanical Engineering, Dalian University of Technology, <sup>2</sup>Faculty of Electronic Information and Electrical Engineering, Dalian University of Technology

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PC94**

**Accumulated fluence methodology for selective metallic thin-film ablation from susceptible polymer substrate using femtosecond laser pulses**

Chresten von der Heide, Andreas Dietzel  
TU Braunschweig - Institute Of Microtechnology



**PC96**

**Fabrication of stretchable supercapacitor using MnO<sub>2</sub> nanoparticles and carbon nanotube on textile**

Tae Gwang Yun, Seungmin Hyun, Chang Soo Woo  
Korea Institute Of Machinery and Materials



**PC98**

**Flash reduction of graphene oxide as cost effective fabrication technique for flexible micro-supercapacitors**

Seok Hun Kang  
Electronics and Telecommunications Research Institute



**PC100**

**Aiming to improve gate controllability of paper transistors using carbon-nanotube-composite papers by using ionic liquid**

Ryuji Iijima, Takahide Oya

Graduate School of Engineering Sciense, Yokohama National University



**PC104**

**Fabrication of Nanopatterned PVDF-HFP Film Based Flexible Pressure Sensors**

Jueun Kim, Hyungjun Lim, Jaejong Lee  
Korea Institute of Machinery & Materials (KIMM)



**PC108**

**Fabrication and Evaluation of Au-Cu Alloy 3D Structures toward MEMS Movable Components**

Kyotaro Nitta<sup>1</sup>, Haochun Tang<sup>1</sup>, Chun-Yi Chen<sup>1</sup>, Tso-Fu Mark Chang<sup>1</sup>, Daisuke Yamane<sup>1</sup>, Shinichi Iida<sup>2</sup>, Katsuyuki Machida<sup>1</sup>, Hiroyuki Ito<sup>1</sup>, Kazuya Masu<sup>1</sup>, Masato Sone<sup>1</sup>

<sup>1</sup>Tokyo Institute of Technology, <sup>2</sup>NTT Advanced Technology Corporation



**PC110**

**Polyimide foils with Au conductor traces for subretinal implants with long-term stability comparable to LCP**

Ralf Rudorf<sup>2</sup>, Anna Drzyzga<sup>2</sup>, Martin Kokelmann<sup>2</sup>, Claus J. Burkhardt<sup>1</sup>, Alfred Stett<sup>2</sup>

<sup>1</sup>NMI Reutlingen, <sup>2</sup>Retina Implant AG



**PC112**

**Effects of Fixed End Structure on Temperature Dependence of Structure Stability of Ti/Au Micro-Cantilever toward MEMS Application**

Hitomi Watanabe<sup>1</sup>, Masato Sone<sup>1</sup>, Tso-Fu Mark Chang<sup>1</sup>, Chun-yi Chen<sup>1</sup>, Shinichi Iida<sup>2</sup>, Daisuke Yamane<sup>1</sup>, Hiroyuki Ito<sup>1</sup>, Katsuyuki Machida<sup>1</sup>, Kazuya Masu<sup>1</sup>

<sup>1</sup>Tokyo Institute of Technology, <sup>2</sup>NTT Advanced Technology Corporation



# 45<sup>th</sup> International Conference on Micro & Nano Engineering

## Poster Session

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PC113**

### Sample Geometry Effect on Mechanical Property of Electrodeposited Gold Evaluated by Micro-Bending Test

Kosuke Suzuki<sup>1</sup>, Masato Sone<sup>1</sup>, Ken Hashigata<sup>1</sup>, Chun-Yi Chen<sup>1</sup>, Takashi Nagoshi<sup>2</sup>, Tso-Fu Mark Chang<sup>1</sup>, Daisuke Yamane<sup>1</sup>, Hiroyuki Ito<sup>1</sup>, Katsuyuki Machida<sup>1</sup>, Kazuya Masu<sup>1</sup>, Keisuke Asano<sup>1</sup>

<sup>1</sup>Tokyo Institute of Technology, <sup>2</sup>National Institute of Advanced Industrial Science and Technology

**PC115**

### Ultra-smooth Chip Scale Sensors for Adaptive Airfoil Control

Jan Niklas Haus, Martin Schwerter, Marcel Gäding, Monika Lester-Schädel, Andreas Dietzel

TU Braunschweig, Institut für Mikrotechnik

**PC117**

### A facile method of direct stiffness measurement for AFM cantilevers

Lukas Avilovas, J.M.R Weaver, P.S. Dobson

The University Of Glasgow

**PC119**

### In-situ TEM fatigue testing system for nanomaterials using an electrostatic actuator

Yan Cui<sup>1</sup>, Yang Yang<sup>1,2</sup>, Meng Liu<sup>1</sup>, Tie Li<sup>1</sup>, Yuelin Wang<sup>1</sup>

<sup>1</sup>Science and Technology on Microsystem Laboratory, Shanghai Institute of Microsystem and Information Technology, Chinese Academy of Sciences, <sup>2</sup>University of Chinese Academy of Sciences

**PC121**

### Design, Fabrication and Characterization of Piezoelectric Cantilever MEMS for Underwater Application

Basit Abdul<sup>1,2</sup>, Vincenzo Mariano Mastronardi<sup>1</sup>, Antonio Qualtieri<sup>1</sup>, Francesco Guido<sup>1</sup>, Luciana Algieri<sup>1</sup>, Francesco Rizzi<sup>1</sup>, Massimo De Vittorio<sup>1,2</sup>

<sup>1</sup>Center For Bio Molecular Nanotechnologies Lecce (Istituto Italiano di Tecnologia), <sup>2</sup>University of Salento

**PC123**

### Frequency control of bifurcation in the electrically coupled micromechanical resonator

Tian L<sup>2</sup>, Wei X<sup>1</sup>, Pu D<sup>1</sup>, Jiang Z<sup>1</sup>, Ren J<sup>3</sup>

<sup>1</sup>Xi'an Jiaotong University, Xi'an, China, <sup>2</sup>Chongqing Technology and Business University, Chongqing, China,

<sup>3</sup>Chang'an University, Xi'an, China

**PC125**

### Adjustment method of MEMS dual-cantilever deflection using plastic deformation of metal thin film by thermal annealing

Masaru Tanaka<sup>1,2</sup>, Y. Iijima<sup>1</sup>, Y. Masuda<sup>1</sup>, T. Sato<sup>1</sup>, T. Mineta<sup>1</sup>

<sup>1</sup>Graduate School of Science and Engineering, Yamagata University, <sup>2</sup>National Institute Of Technology, Tsuruoka College

23-26 September 2019  
Rhodes, Greece

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PC114**

### High Efficient and Cost Effective Hybrid Aluminium Nitride Substrates for Power LED Modules

Chien-ping Wang<sup>1</sup>, Yuan-Chun Huang<sup>2</sup>, Hao-Qi Liu<sup>1</sup>

<sup>1</sup>Department of Mechanical Engineering, National Taipei University of Technology, <sup>2</sup>Department of Mechanical Engineering, Chung Yuan Christian University

**PC116**

### A Novel High-performance RF-MEMS Resonator with Multiple Mode Generations

Zeji Chen<sup>1,2,3</sup>, Xiao Kan<sup>1,2,3</sup>, Tianyun Wang<sup>1,2,3</sup>, Quan Yuan<sup>1,2</sup>, Jinling Yang<sup>1,2,3</sup>, Fuhua Yang<sup>1,2,3</sup>

<sup>1</sup>Institute of Semiconductors, Chinese Academy of Sciences, <sup>2</sup>University of Chinese Academy of Sciences, <sup>3</sup>State Key Laboratory of Transducer Technology

**PC118**

### 3D tactile microprobe with isotropic kinematics for industrial micro metrology

David Metz<sup>1</sup>, Stephan Jantzen<sup>2</sup>, Karin Kniel<sup>2</sup>, Martin Stein<sup>2</sup>, Andreas Dietzel<sup>1</sup>

<sup>1</sup>Technische Universität Braunschweig, Institute of Microtechnology, <sup>2</sup>Physikalisch-Technische Bundesanstalt (PTB), Department of Coordinate Metrology

**PC120**

### Electrodeposition of TiO<sub>2</sub> Nanoparticle Reinforced High Strength Au Film for MEMS Applications

Yu-An Chien, Tso-Fu Mark Chang, Chun-Yi Chen, Daisuke Yamane, Hiroyuki Ito, Katsuyuki Machida, Kazuya Masu, Masato Sone

Institute of Innovative Research, Tokyo Institute Of Technology

**PC122**

### Self-Aligned, High Resolution Conductive Lines for Micro Heaters Fabrication

Vito Matteo Di Pietro, H. M. Außerhuber, T. Mitteramskogler, P. Kulha, F. R. Tessarollo, M. Mühlberger

Profactor Gmbh

**PC124**

### Dynamic performance of symmetric and asymmetric anti-spring structures

Yang Gao, Hongcai Zhang, Zhuangde Jiang, Xueyong Wei

Xi'an Jiaotong University

**PC126**

### Fabrication and characterization of arrayed micro-structure with Ni film springs and photolithographed SU-8 micro-pins for Tactile Display Device

Kazuki Tuji<sup>1</sup>, Jiale Xu<sup>1</sup>, Konomu Abe<sup>2</sup>, Tomomi Shimizu<sup>2</sup>, Hiroyasu Hasegawa<sup>2</sup>, Takashi Mineta<sup>1</sup>

<sup>1</sup>Yamagata University, <sup>2</sup>TokaiRika CO. LTD

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PC127**

**Large scanning range optical phased array with a compact and simple optical antenna**  
 Pengfei Wang<sup>1,2,3</sup>, Guangzhen Luo<sup>1,2,3</sup>, Yajie Li<sup>1,2,3</sup>, Wenyu Yang<sup>1,2,3</sup>, Hongyan Yu<sup>1,2,3</sup>, Xuliang Zhou<sup>1,2,3</sup>, Yejin Zhang<sup>1,2,3</sup>, Jiaoqing Pan<sup>1,2,3</sup>

<sup>1</sup>Key Laboratory of Semiconductor Materials Science, Institute of Semiconductors, Chinese Academy of Sciences, <sup>2</sup>Center of Materials Science and Optoelectronics Engineering, University of Chinese Academy of Sciences, <sup>3</sup>Beijing Key Laboratory of Low Dimensional Semiconductor Materials and Devices

**PC129**

**Full Electrostatic Control of Nanomechanical Buckling**

Selcuk Oguz Erbil<sup>1</sup>, Utku Hatipoglu<sup>1</sup>, Cenk Yanik<sup>2</sup>, Mahyar Ghavami<sup>1</sup>, Atakan B. Ari<sup>1</sup>, Mert Yuksel<sup>1</sup>, Berke Demiralp<sup>1</sup>, Mehmet Selim Hanay<sup>1,3</sup>

<sup>1</sup>Bilkent University, Department of Mechanical Engineering, <sup>2</sup>Sabanci University SUNUM Nanotechnology Research Center, <sup>3</sup>Bilkent University National Nanotechnology Research Center (UNAM)

**PC131**

**Electromagnetical cantilevers for force spectroscopy Metrology-study of elecrothermal and electromagnectic actuation efficiency**

Bartosz Pruchnik<sup>1</sup>, Tomasz Piasecki<sup>1</sup>, Karolina Orłowska<sup>1</sup>, Wojciech Majstrzyk<sup>1</sup>, Andrzej Sierakowski<sup>2</sup>, Teodor Gotszalk<sup>1</sup>

<sup>1</sup>Faculty of Microsystem Electronics and Fotonics, Wrocław University Of Science And Technology, <sup>2</sup>Institute of Electron Technology

**PC133**

**Parallel Tensile-mode Testing Of Single Crystal Silicon By Specimen Integrating Shear Strain Gauge**

Yuki Yamazaki, Yoshikazu Hirai, Toshiyuki Tsuchiya, Osamu Tabata  
 Kyoto University

**PC135**

**Novel Hybrid Silicon Microprobes for High-density Neural Activity Recording**

Ashley Novais, Carlos Calaza, João Gaspar  
 International Nanotechnology Laboratory

**PC137**

**Fire smoke detection with quartz crystal microbalance (QCM) oscillation sensor**

Sumi Yoon, Dong-ki Hong, Hye-Lim Kang, Won-Hyo Kim, Woo Kyeong Seong, Kook-Nyung Lee  
 Korea Electronics Technology Institute(KETI)

**PC139**

**Thermally Activated Discharging Mechanisms in SiNx Films with Embedded CNTs for RF MEMS Capacitive Switches**

Matroni Koutsourelis<sup>1</sup>, George Stavrinidis<sup>2</sup>, Dimitrios Birmpiliotis<sup>1</sup>, George Konstantinidis<sup>2</sup>, George Papaioannou<sup>1</sup>

<sup>1</sup>Physics Department, University of Athens, <sup>2</sup>IESL - FORTH

**PC141**

**Towards a Lab-on-Chip micro-calorimeter based on a fully-integrated CMOS-MEMS oscillator**

Rafel Perelló-Roig, Jaume Verd, Dr. Jaume Segura  
 GSE-UIB / Universitat de les Illes Balears

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PC128**

**Nonlinear Nanomechanical Mass Spectrometry at the Single-Nanoparticle Level**

Mert Yuksel<sup>1</sup>, Ezgi Orhan<sup>1</sup>, Cenk Yanik<sup>2</sup>, Atakan B. Ari<sup>1</sup>, Alper Demir<sup>4</sup>, Ahmet Hakan Karakurt<sup>1</sup>, Ramazan Tufan Erdogan<sup>1</sup>, M. Selim Hanay<sup>1,3</sup>

<sup>1</sup>Department of Mechanical Engineering, Bilkent University,

<sup>2</sup>Sabanci University SUNUM Nanotechnology Research Center, <sup>3</sup>National Nanotechnology Research Center (UNAM), Bilkent University, <sup>4</sup>Department of Electrical Engineering, Koc University

**PC132**

**Towards Fabrication of Functionalised Polymer membranes**

Nadezda Prochukhan, Abbie Keegan, Michael A. Morris

Trinity College Dublin, University Of Dublin

**PC134**

**Highly-doped in-plane Si electrodes embedded between free-hanging microfluidic channels**

Yiyuan Zhao<sup>1</sup>, H.-W. Velkamp<sup>1</sup>, T.V.P. Schut<sup>1</sup>, J. Groenesteijn<sup>2</sup>, M. J. de Boer<sup>1</sup>, R.J. Wiegerink<sup>1</sup>, J.C. Lotters<sup>1,2</sup>

<sup>1</sup>MESA+ Institute for Nanotechnology, University of Twente,

<sup>2</sup>Bronkhurst High-Tech BV

**PC136**

**Impedance spectroscopy of electrostatically driven MEMS resonators**

Krzysztof Kwoka<sup>1</sup>, Tomasz Piasecki<sup>1</sup>, Karolina Orłowska<sup>1</sup>, Paulina Szymanowska<sup>1</sup>, Andrzej Sierakowski<sup>2</sup>, Teodor Gotszalk<sup>1</sup>

<sup>1</sup>Wroclaw University of Technology, <sup>2</sup>Institute of Electron Technology

**PC138**

**New method of monitoring the intrinsic strain during electrochemical deposition process using rosette gauge**

Djaffar Belharet<sup>1</sup>, Xavier Gabrion<sup>2</sup>, Anthony Courtot<sup>1</sup>, Laurent Robert<sup>1</sup>, Samuel Queste<sup>1</sup>, Gwenn Ulliac<sup>1</sup>

<sup>1</sup>MIMENTO, FEMTO-ST, <sup>2</sup>DMA , FEMTO-ST

**PC140**

**INNOVATION-EL: The National Nanotechnology Infrastructure Network of Greece**

Vassileios Kilikoglou<sup>1</sup>, Philomela Komninou<sup>3</sup>, Spyridon H. Anastasiadis<sup>2</sup>, Efstratios I. Kamitsos<sup>4</sup>, Dimitrios Tsoukalas<sup>5</sup>, Vassileios Bourganos<sup>6</sup>, Michail Karakasidis<sup>7</sup>, Eleni Makarona<sup>1</sup>, Mirto Holastou<sup>8</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology, NCSR Demokritos, <sup>2</sup>Institute of Electronic Structure and Laser, Foundation for Research and Technology Hellas, <sup>3</sup>Electron Microscopy Laboratory, School of Physics, Aristotle University of Thessaloniki, <sup>4</sup>Theoretical and Physical Chemistry Institute, National Hellenic Research Foundation,

<sup>5</sup>School of Applied Mathematical and Physical Sciences, National Technical University of Athens, <sup>6</sup>Institute of Chemical Engineering Sciences, Foundation for Research and Technology Hellas, <sup>7</sup>Department of Materials Science & Engineering, School of Engineering, University of Ioannina, <sup>8</sup>Hellenic Institute of Metrology



# 45<sup>th</sup> International Conference on Micro & Nano Engineering

23-26 September 2019  
Rhodes, Greece

## Poster Session

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

### PC143

Influence of the features deformation caused by cutting forces in micro end milling process for thin-walled copper electrode parts

Seok Jae Ha<sup>1</sup>, Jeong Yeon Park<sup>1</sup>, Gil Sang Yoon<sup>1</sup>, Tae Sung Jung<sup>2</sup>

<sup>1</sup>Korea Institute of Industrial Technology, <sup>2</sup>Inha Technical College

### PC145

Spectrum decomposition analysis of light-emitting diode with designed electrode and InGaN/GaN quantum wells as an active region

Yohei Nishidate<sup>1</sup>, Irina Khmyrova<sup>1</sup>, Yulia Kholopova<sup>2</sup>, Anatoly Kovalchuk<sup>2</sup>, Valery Zemlyakov<sup>3</sup>, Ivan Maximov<sup>4</sup>, Sergei Shapoval<sup>2</sup>

<sup>1</sup>University of Aizu, <sup>2</sup>IMT RAS, <sup>3</sup>NRUET, <sup>4</sup>Lund University

### PC147

FEM simulation for 3D self-folding using thermoplastic reflow of polymer actuators

Ran Zhang, Andreas Richter, Robert Kirchner

Technische Universität Dresden

### PC149

A Novel Method for Depositing Patterned BCB using Spotter for Low Temperature Wafer Level Bonding

Shruti Jain, Michal M. Mielnik, Sigurd T. Moe

SINTEF Digital

### PC151

Au/Ti double-layered films for bonding and residual gas gettering in MEMS encapsulation

Yuchi Kurashima<sup>1</sup>, Takashi Matsumae<sup>1</sup>, Eiji Higurashi<sup>1</sup>, Shinya Yanagimachi<sup>1</sup>, Hideki Takagi<sup>1</sup>, Mr. Sudiyarmanto<sup>2</sup>, Eiichi Kondoh<sup>2</sup>

<sup>1</sup>National Institute of Advanced Industrial Science and Technology, <sup>2</sup>University of Yamanashi

### PC153

Reactive Bonding by Integrated Nanostructured Al/Pd Multilayer Thin Film Systems for MEMS Packaging Applications

El-mostafa Bourim, Il-Suk Kang, Hee Yeoun Kim

National NanoFab Center, Department of Nanostructure Technology

### PC155

Basic study of position measurement system at tip of surgical forceps which is sensor fusion type

Tomoki Nishino<sup>1</sup>, Hiroshi Tanigawa<sup>2</sup>, Yakichi Higo<sup>2</sup>, Takashi Furutsuka<sup>2</sup>, Kyoichi Deie<sup>3</sup>, Tetsuya Ishimaru<sup>4</sup>, Tadashi Iwanaka<sup>4</sup>

<sup>1</sup>Ritsumeikan University, <sup>2</sup>The Research Organization of Science and Technology, Ritsumeikan University, <sup>3</sup>Kitasato University Children's Surgery, <sup>4</sup>Saitama Children's Medical Center Surgery

### PC157

Evidence of Cation Selective Nano-Sized Conducting Filament Formation in Resistive Switching Memories

Dip Das, P. Johari, A. Kanjilal  
Shiv Nadar University

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

### PC142

Large area Silicon-energy filters for ion implantation

Tamas Steinbach<sup>1</sup>, Constantin Csato<sup>2</sup>, Florian Krippendorf<sup>2</sup>, Florian Letzkus<sup>1</sup>, Michael Rüb<sup>2,3</sup>, Joachim Burghartz<sup>1</sup>

<sup>1</sup>Institut Für Mikroelektronik Stuttgart (IMS-CHIPS), <sup>2</sup>mi2-factory GmbH, <sup>3</sup>Ernst-Abbe-Hochschule Jena

### PC144

Improvement in IR absorption and thermal properties of a-Si based μ-bolometers by adopting the resistive hall-array pattern

Tae Hyun Kim<sup>1</sup>, Jaeseob Oh<sup>1</sup>, Jongcheol Park<sup>1</sup>, Joo-Yun Jung<sup>2</sup>, Daewon Hong<sup>1</sup>, Hee Yeoun Kim<sup>1</sup>, Jong-Kwon Lee<sup>1</sup>

<sup>1</sup>National Nanofab Center, <sup>2</sup>Korea Institute of Machinery and Materials

### PC146

micro-Coriolis mass flow sensor with improved flow sensitivity through modelling of the sensor

Thomas V. P. Schut<sup>1</sup>, Remco J. Wiegerink<sup>1</sup>, Joost C. Lötters<sup>1,2</sup>

<sup>1</sup>University of Twente, <sup>2</sup>Bronkhorst High-tech BV

### PC148

A stochastic model with IoT gas detector based on AI-enabled technique for predicting particulate matters of 2.5 μm and 10 μm

Ya-Wei Lee<sup>1</sup>, Tien-Li Chang<sup>2</sup>

<sup>1</sup>National Defense University, <sup>2</sup>National Taiwan Normal University

### PC150

Optimization of solder paste laser printing parameters for the assembly of electronic devices

Marina Makrygianni<sup>1</sup>, Elena Margariti<sup>1</sup>, Nikos Oikonomidis<sup>2</sup>, Christos Spandonidis<sup>2</sup>, Ioanna Zergioti<sup>1</sup>

<sup>1</sup>National Technical University of Athens, Physics Department, <sup>2</sup>Prisma Electronics SA

### PC152

Electrical connection enhancement of conductive 3D printed parts based on PEDOT:PSS by metal plating

Valentina Bertana<sup>1</sup>, Giorgio Scordo<sup>1</sup>, Stefano Romano<sup>1</sup>, Carmelo Nicosia<sup>1</sup>, Simone Luigi Marasso<sup>1,2</sup>, Matteo Cocuzza<sup>1,2</sup>, Sergio Ferrero<sup>1</sup>, Candido Fabrizio Pirri<sup>1,3</sup>, Luciano Scaltrito<sup>1</sup>

<sup>1</sup>Chilab Laboratory, Department of Applied Science and Technology, Polito, <sup>2</sup>CNR-IMEM, <sup>3</sup>CSFT-IIT

### PC154

On-chip beta spectrometry with absorber-embedded radionuclides

Patryk Krzysteczkó<sup>1</sup>, Michael Paulsen<sup>1</sup>, Lina Bockhorn<sup>2</sup>, Cornelia Abmann<sup>1</sup>, Erik Bork<sup>1</sup>, Jörn Beyer<sup>1</sup>

<sup>1</sup>PTB, <sup>2</sup>PTB

### PC156

Room-temperature direct bonding of LiTaO<sub>3</sub> and SiC wafers for future SAW filter

Ryo Takigawa<sup>1</sup>, Jun Utsumi<sup>2</sup>

<sup>1</sup>Kyushu University, <sup>2</sup>Mitsubishi Heavy Industries Machine Tool Co., Ltd

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PD - Lab-on-a-chip**

**PD01**

**Fabrication of free-hanging tubes for a high flow micro Coriolis mass flow meter**

Jarno Groenesteijn<sup>1</sup>, Meint de Boer<sup>2</sup>, Jack van Putten<sup>1</sup>, Wouter Sparreboom<sup>1</sup>, Joost Lotters<sup>1,2</sup>, Remco Wiegerink<sup>2</sup>

<sup>1</sup>Bronkhorst High-Tech BV, <sup>2</sup>MESA+ Institute or Nanotechnology, University of Twente



**PD03**

**Performance of the electrochemical microactuator with a millisecond response time**

Ilia V. Uvarov<sup>1</sup>, Artem E. Melenev<sup>1</sup>, Mikhail V. Lokhanin<sup>2</sup>, Victor V. Naumov<sup>1</sup>, Vitaly V. Svetovoy<sup>3,4</sup>

<sup>1</sup>Valiev Institute Of Physics And Technology Of Russian Academy Of Sciences, Yaroslavl Branch, 2P.G. Demidov Yaroslavl State University, <sup>3</sup>Zernike Institute for Advanced Materials, University of Groningen, <sup>4</sup>A.N. Frumkin Institute of Physical Chemistry and Electrochemistry RAS



**PD07**

**Membrane integration for glass Organ-on-a-Chip systems using a reversible sealing technique**

Eugen V. Koch, Andreas Dietzel

Institute of Microtechnology, Tu Braunschweig



**PD09**

**Polymer supports for serial protein crystallography at X-ray free electron lasers**

Celestino Padeste<sup>1</sup>, Isabelle Martiel<sup>1</sup>, Agnieszka Karpik<sup>1,2</sup>, Per Magnus Kristiansen<sup>2,1</sup>

<sup>1</sup>Paul Scherrer Institut, <sup>2</sup>FHNW University of Applied Sciences and Arts Northwestern Switzerland



**PD11**

**UV lithography based fabrication of SU-8 microneedles for drug delivery applications**

Ajay Ap, Amitava DasGupta, Dhiman Chatterjee

Indian Institute of Technology Madras



**PD13**

**Femtosecond Laser structuring with online control of polarization for advanced and buried microfluidic structures**

Sven Meinen<sup>1,2</sup>, Jonathan Kottmeier<sup>1,2</sup>, Steffen Brinkmann<sup>1,2</sup>, Andreas Dietzel<sup>1,2</sup>

<sup>1</sup>Institute of Microtechnology, Technische Universität Braunschweig, <sup>2</sup>Center of Pharmaceutical Engineering (PVZ), Technische Universität Braunschweig



**PD15**

**Soft X-Ray Compatible Liquid Cells**

Alokik Kanwal<sup>1</sup>, B. Robert Ilic<sup>1</sup>, Subhrangsu Mukherjee<sup>1</sup>, Eliot H. Gann<sup>1</sup>, Cheng Wang<sup>2</sup>, Ivar A. Cordova<sup>2</sup>, Dean DeLongchamp<sup>1</sup>, James Alexander Liddle<sup>1</sup>

<sup>1</sup>National Institute of Standards and Technology, <sup>2</sup>Lawrence Berkeley National Laboratory



**PD19**

**Compact platform for automated cell culture and stem cell differentiation**

Gabriele Pitingolo<sup>1</sup>, Yong He<sup>1</sup>, Boxin Huang<sup>1</sup>, Li Wang<sup>2</sup>, Jian Shi<sup>2</sup>, Yong Chen<sup>1</sup>

<sup>1</sup>École Normale Supérieure-PSL Research University, Sorbonne Universités - UPMC Univ Paris 06, CNRS UMR 8640 PASTEUR, <sup>2</sup>MesoBioTech

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PD - Lab-on-a-chip**

**PD02**

**A nanofluidic concentrator integrating long vertical nanotrenchetched with an optimized ICP-RIE process**

Sokhna Mery Ngom<sup>1</sup>, François-Damien Delapierre<sup>2</sup>, Stephane Guillet<sup>1</sup>, Edmond Cambril<sup>1</sup>, Fatima Florès-Galicia<sup>1</sup>, Jean Gamby<sup>1</sup>, Antoine Pallandre<sup>3</sup>, Isabelle Le Potier<sup>1</sup>, Anne-Marie Haghiri-Gosnet<sup>1</sup>

<sup>1</sup>C2N - CNRS - U-Psud, <sup>2</sup>SPEC - CEA, <sup>3</sup>LCP - CNRS-Université Paris-Sud



**PD04**

**Porous polymer coatings on SS microneedles (MN)s for glucose-responsive insulin delivery**

Asad Ullah, Hye Jin Choi, Haroon Khan, Jin Ho Choi, Gyu Man Kim

Kyungpook National University



**PD06**

**Investigation of Squeeze Flow Problem on a Nano-Scale**

Sandrien Verloy<sup>1,2</sup>, Han Gardeniers<sup>1</sup>, Gert Desmet<sup>2</sup>

<sup>1</sup>University of Twente, <sup>2</sup>Vrije Universiteit Brussel



**PD08**

**Biomimetic membranes manipulation in microfluidics: towards on-chip micropipette**

Marianne Elias<sup>1,2</sup>, Adrien Dutoya<sup>1</sup>, Adrian Laborde<sup>1</sup>, Aurelie Lecestre<sup>1</sup>, Costanza Montis<sup>2</sup>, Debora Berti<sup>1</sup>, Barbara Lonetti<sup>3</sup>, Clément Roux<sup>3</sup>, Pierre Joseph<sup>1</sup>

<sup>1</sup>LAAS-CNRS, Université de Toulouse, CNRS, UPS, <sup>2</sup>CSGI and Department of Chemistry, University of Florence,

<sup>3</sup>IMRCP, Université de Toulouse, CNRS, UPS



**PD10**

**PID temperature control system based Microfluidic PCR chip for genetic analysis**

Hyo Eun Kim<sup>1</sup>, Hang-Beum Shin<sup>2</sup>, Yong-Sang Kim<sup>1</sup>

<sup>1</sup>Department of Electrical and Computer Engineering, Sungkyunkwan University, <sup>2</sup>Corporate R&D, LG Chem



**PD12**

**Rapid prototyping of a MEMS-based droplet dispenser using 3D printing**

Ali Maziz<sup>1</sup>, Remi Courson<sup>1</sup>, Fabien Mesnilgrente<sup>1</sup>, Elodie Bidal<sup>2</sup>, Loic Leroy<sup>2</sup>, Neso Sojic<sup>3</sup>, Laurent Malaquin<sup>1</sup>, Thierry Leichle<sup>1</sup>

<sup>1</sup>LAAS-CNRS, <sup>2</sup>INAC-SyMMES, <sup>3</sup>ISM



**PD14**

**Open Microchannels filled with Nanoparticle Inks**

Tina Mitteramskogler, Vito Matteo Di Pietro, Helene Ausserhuber, Michael Muehlberger

Profactor Gmbh



**PD16**

**Parallel Ejection of pL-Droplets with Pneumatic Valve Integrated Micronozzle Array**

Gaurav Pandey, Rohit Bhardwaj, Kentaro Tanagi, Azusa Kage, Takayuki Shibata, Moeto Nagai

Toyohashi University of Technology





# 45<sup>th</sup> International Conference on Micro & Nano Engineering

23-26 September 2019  
Rhodes, Greece

## Poster Session

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

### PD21

**Design of microfluidic platforms for super resolution imaging of liver sinusoidal endothelial cell dynamics**

Alessandra Dellaquila<sup>1,2</sup>, Aurélie Vigne<sup>1</sup>, Thomas Huser<sup>2</sup>, Sasha Cai Lesher-Perez<sup>1</sup>

<sup>1</sup>Elvesys, <sup>2</sup>University of Bielefeld

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

### PD18

**Open and Closed Microfluidic Wall Modifications and in-situ Reactions via a new Atmospheric Plasma Apparatus**

Angelos Zeniou<sup>1,2</sup>, Dionysia Kefallinou<sup>1</sup>, Nikos Vourdas<sup>1</sup>, Angeliki Tserepi<sup>1</sup>, Evangelos Gogolides<sup>1</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology, National Center for Scientific Research Demokritos, <sup>2</sup>Department of Physics, University of Patras

### PD23

**Vapor Chamber / Heat Spreader with Wettability - Patterned Condenser**

Theodoros P. Koukoravas, Georgios Damoulakis, Constantine Megaridis

University Of Illinois At Chicago

### PD27

**An amphiphilic copolymer-based chemocapacitor array for selective and sensitive sensing of volatile organic compounds**

Anastasia Nika<sup>1</sup>, Petros Oikonomou<sup>2</sup>, Theodore Manouras<sup>3</sup>, Panagiotis Argitis<sup>2</sup>, Maria Vamvakaki<sup>3,4</sup>, Merope Sanopoulou<sup>2</sup>, Ioannis Raptis<sup>2</sup>, Margarita Chatzichristidi<sup>1</sup>

<sup>1</sup>Department of Chemistry, National And Kapodistrian University Of Athens, <sup>2</sup>Institute of Nanoscience and Nanotechnology, NCSR "Demokritos", <sup>3</sup>Department of Materials Science and Technology, University of Crete, <sup>4</sup>Institute of Electronic Structure and Laser, Foundation for Research and Technology-Hellas

### PD29

**Microscale Modelling and Simulation of Gas Sensor Based on MoS<sub>2</sub> Hollow Spheres**

Zhenyu Yuan, Kaiyuan Zuo, Tong Wu, Junfeng Li, Xin Lin, Yichi Tong

Northeastern University, China

### PD31

**Atomic Gold Clusters Modified Polyaniline toward Highly Selective and Sensitive Electrochemical Sensor**

Yu-An Chien<sup>1</sup>, Parthojoit Chakraborty<sup>1</sup>, Wan-Ting Chiu<sup>2</sup>, Chun-Yi Chen<sup>1</sup>, Tso-Fu Mark Chang<sup>1</sup>, Takamichi Nakamoto<sup>1</sup>, Masato Sone<sup>1</sup>

<sup>1</sup>Institute of Innovative Research, Tokyo Institute of Technology, <sup>2</sup>Institute of Industrial Science, The University of Tokyo

### PD33

**Point-of-care test based on an asymmetric optofluidic grating for buruli ulcer detection**

Foelke Purr<sup>1,2</sup>, Matthias Stehr<sup>3</sup>, Mahavir Singh<sup>3</sup>, Thomas P. Burg<sup>2,4</sup>, Andreas Dietzel<sup>1</sup>

<sup>1</sup>Technische Universität Braunschweig, Institute of Microtechnology, <sup>2</sup>Max Planck Institute for Biophysical Chemistry, <sup>3</sup>Lionex Diagnostics & Therapeutics GmbH, <sup>4</sup>Technische Universität Darmstadt, Department of Electrical Engineering and Information Technology

### PD35

**Carbon nanogap electrode arrays for electrochemical sensors and biosensors**

Stefan Partel, Volha Matylitskaya

Vorarlberg University of Applied Sciences

### PD18

**Open and Closed Microfluidic Wall Modifications and in-situ Reactions via a new Atmospheric Plasma Apparatus**

Angelos Zeniou<sup>1,2</sup>, Dionysia Kefallinou<sup>1</sup>, Nikos Vourdas<sup>1</sup>, Angeliki Tserepi<sup>1</sup>, Evangelos Gogolides<sup>1</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology, National Center for Scientific Research Demokritos, <sup>2</sup>Department of Physics, University of Patras

### PD22

**Novel Thermoplastic Fluoroelastomer for Rapid Fabrication of Chemically Compatible Microdevices**

Alexander H. McMillan<sup>1,2</sup>, Maarten B.J. Roeffaers<sup>2</sup>, Sasha Cai Lesher-Perez<sup>1</sup>

<sup>1</sup>Elvesys Microfluidic Innovation Center, <sup>2</sup>Department of Microbial and Molecular Systems, Centre for Surface Chemistry and Catalysis (COK), KU Leuven

### PD26

**Fast and label-free procalcitonin determination with a White Light Reflectance Spectroscopy sensor**

Dimitra Tsounidi<sup>1</sup>, Georgios Koukouvinos<sup>1</sup>, Dimitrios Goustouridis<sup>2</sup>, Ioannis Raptis<sup>2</sup>, Vassilios Tsaousis<sup>3</sup>, Chrysanthos Mitropoulos<sup>3</sup>, Sotirios Kakabakos<sup>1</sup>, Panagiota Petrou<sup>1</sup>

<sup>1</sup>NCSR Demokritos, <sup>2</sup>ThetaMetrisis S.A., <sup>3</sup>Medicon Hellas S.A.

### PD28

**Magnetic design of multi-component nanoprobes for biomolecular diagnostics**

Hubert Brueckl<sup>1</sup>, Astrit Shoshi<sup>1</sup>, Michael J. Haslinger<sup>2</sup>, Tina Mitteramskogler<sup>2</sup>, Michael Muehlberger<sup>2</sup>, Joerg Schotter<sup>3</sup>, Stefan Schrittawieser<sup>3</sup>

<sup>1</sup>Department for Integrated Sensor Systems, Danube University Krems, <sup>2</sup>PROFACTOR GmbH, <sup>3</sup>AIT Austrian Institute of Technology

### PD30

**Individually addressable two-electrode electrochemical cell array sharing a single reference/counter electrode for enzyme activity measurements**

Manuel Gutiérrez-Capitán, Ángel Merlos, Antoni Baldi, César Fernández-Sánchez

Instituto de Microelectrónica de Barcelona (IMB-CNM), CSIC

### PD32

**Fast and Accurate Detection of Hydrogen Peroxide**

Lisa-Marie Wagner<sup>1</sup>, Matthias Pilecky<sup>2</sup>, Karlheinz Kellner<sup>1</sup>, Thomas Posniecek<sup>1</sup>, Giulia Mazza<sup>1</sup>, Martin Brandl<sup>1</sup>

<sup>1</sup>Department for Integrated Sensor Systems, Danube University Krems, <sup>2</sup>Department for Health Sciences and Biomedicine, Danube University Krems

**WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)**

**PD37**

**Label-free detection of biomolecules and cells by Localized Surface Plasmon Resonance**

Santos Merino<sup>1</sup>, Deitze Otaduy<sup>1</sup>, Aritz Retolaza<sup>1</sup>, Aritz Juarros<sup>1</sup>, Angela I. Barreda<sup>2</sup>, Francisco González<sup>2</sup>, Fernando Moreno<sup>2</sup>, Alfredo Franco<sup>3</sup>, Jose Luis Fernández-Luna<sup>3</sup>

<sup>1</sup>Ik4-tekniker, <sup>2</sup>University of Cantabria, <sup>3</sup>Hospital Universitario Marqués de Valdecilla

**PD39**

**Particle-based immunoassay: analysis of non-specific allergen-IgE interactions**

Lacey Chunilal<sup>1</sup>, Tonatiuh Yescas González<sup>1</sup>, Victor Gaudé<sup>1</sup>, Annick Barre<sup>2</sup>, Pierre Rougé<sup>2</sup>, Lorna Garnier<sup>3</sup>, Françoise Bienvenu<sup>3</sup>, Jacques Bienvenu<sup>3</sup>, Emmanuel Picard<sup>4</sup>, David Peyrade<sup>1</sup>

<sup>1</sup>Laboratoire des Technologies de la Microélectronique LTM-CNRS-UGA, <sup>2</sup>Pharmacochimie et Biologie pour le Développement, Université Toulouse III - Paul Sabatier, <sup>3</sup>Laboratoire d'Immunologie, Centre Hospitalier Lyon-Sud, <sup>4</sup>Laboratoire Silicium Nanoélectronique Photonique et Structures, INAC/SP2M/SiNaPS

**PD41**

**pH sensitivity evaluation of nanoFET sensor to extended sensing gate material**

Hyey-Lim Kang, Sumi Yoon, Dong-Ki Hong, Young Joo Kim, Sunga Song, Won-Hyo Kim, WooKyeong Seong, Kook-Nyung Lee

Korea Electronics Technology Institute (KETI)

**PD45**

**Bridge type micro-platforms with sizes of membrane and bridge-width for low-powered micro gas sensor using MEMS techniques**

Joon-shik Park<sup>1</sup>, Kwang-Bum Park<sup>1</sup>, Tae-Ho Hwang<sup>1</sup>, Hyunsung Jung<sup>2</sup>, Myoungpyo Chun<sup>2</sup>

<sup>1</sup>Korea Electronics Technology Institute, <sup>2</sup>Korea Institute of Ceramic Engineering & Technology

**PD47**

**The improvement of solid-state pH sensor for a case study on neonatal urine monitoring**

Lan Zhang, Jian Lu, Ryutaro Maeda

National Institute of Advanced Industrial Science and Technology

**PD49**

**Towards integrated multi-sensor platform for monitoring of cell nutrient, metabolite, pH, viable cell mass, dissolved oxygen and temperature in bioreactors**

Nurul Izni Rusli<sup>1,2</sup>, Irene Pia Vincentini<sup>3</sup>, Michael Kraft<sup>1</sup>

<sup>1</sup>Department of Electrical Engineering (ESAT-MICAS), University of Leuven (KU Leuven), <sup>2</sup>Department of Electrical Engineering Technology, Faculty of Engineering Technology, Universiti Malaysia Perlis (UniMAP), <sup>3</sup>DEIB, Politecnico di Milano

**TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)**

**PD34**

**NFC Antenna and Biosensor Electrode Fabrication on Intraocular Lens**

Junhyoung Ahn<sup>1</sup>, Kangho Lee<sup>2</sup>, Daekyung Jung<sup>1,3</sup>, Soongeun Kwon<sup>1</sup>, Geohong Kim<sup>1</sup>, Keebong Choi<sup>1</sup>, Hyungjun Lim<sup>1,3</sup>, JaeJong Lee<sup>1,3</sup>

<sup>1</sup>Department of Nano Manufacturing Technology, Nano-Convergence Mechanical Systems Research Division, Korea Institute Of Machinery & Materials, <sup>2</sup>Department of Rehabilitation Engineering, Daegu Research Center for Medical Devices & Rehab. Engineering, Materials Science & Engineering, Korea Institute Of Machinery & Materials,

<sup>3</sup>Department of Nano Mechatronics, University of Science & Technology

**PD36**

**In vitro detection of pathogenic bacteria by phospholipase A activity for an integrated biosensor in domestic water systems**

Sylvia Schneider, Jörg Ettenauer, Lisa Brandl, Martin Brandl

Department for Integrated Sensor Systems, Danube University Krems

**PD38**

**Evaluation of various cancer cells lines by four-point probe measurements**

Georgia Paivana<sup>1,2</sup>, Dimitris Barmpakos<sup>2</sup>, Sophie Mavrikou<sup>1</sup>, Charalampos Karavasilis<sup>2</sup>, Odysseus Tsakiridis<sup>2</sup>, Grigoris Kaltsas<sup>2</sup>, Spyridon Kintzios<sup>1</sup>

<sup>1</sup>Laboratory of Cell Technology, Department of

Biotechnology, Agricultural University of Athens, <sup>2</sup>microSENSES Laboratory, Department of Electrical and Electronic Engineering, University of West Attica

**PD40**

**Rapid detection of *Salmonella typhimurium* in drinking water samples by a White Light Reflectance Spectroscopy immunosensor**

Michailia Angelopoulou<sup>1</sup>, Panagiota Petrou<sup>1</sup>, Konstantinos Misiakos<sup>2</sup>, Ioannis Raptis<sup>3</sup>, Sotirios Kakabakos<sup>1</sup>

<sup>1</sup>NCSR "demokritos", INRASTES, Aghia Paraskevi, Greece,

<sup>2</sup>NCSR "Demokritos" INN, Aghia Paraskevi, Greece,

<sup>3</sup>ThetaMetris, Athens, Greece

**PD42**

**Synthesis of polymer-based nanoparticles for bio-nano application**

Marta Szczęch, Krzysztof Szczepanowicz, Piotr Warszyński

Jerzy Haber Institute of Catalysis And Surface Chemistry, Polish Academy Of Sciences

**PD44**

**Dielectrophoretically enhanced detection of *E. coli* cells by an integrated optical biosensor system**

Dániel Petrovszki<sup>1</sup>, Sándor Valkai<sup>1</sup>, Evelin Gora<sup>1</sup>, Martin Tanner<sup>1</sup>, Anita Bánya<sup>2</sup>, Péter Fürjes<sup>2</sup>, András Dér<sup>1</sup>

<sup>1</sup>Institute of Biophysics, Biological Research Centre, Hungarian Academy of Sciences, <sup>2</sup>Institute of Technical Physics and Materials Science, Centre for Energy Research, Hungarian Academy of Sciences



# 45<sup>th</sup> International Conference on Micro & Nano Engineering

23-26 September 2019  
Rhodes, Greece

## Poster Session

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

### PD53

#### A silicon membrane-silver nanoparticles SERS chip for trace molecules detection

Kestutis Nemciauskas<sup>1</sup>, Lina Traksele<sup>2</sup>, Alvija Salaseviciene<sup>2</sup>, Valentinas Snitka<sup>1</sup>

<sup>1</sup>Kaunas University of Technology, Research Center for Microsystems and Nanotechnology, <sup>2</sup>Kaunas University of Technology, Food Institute

### PD55

#### Storage of protein coated beads on point-of-care microfluidic cartridges for immunoassay applications

Benita Johannsen<sup>1</sup>, Lena Karkossa<sup>1</sup>, Desirée Baumgartner<sup>1</sup>, Lara Müller<sup>1</sup>, Roland Zengerle<sup>1,2</sup>, Konstantinos Mitsakakis<sup>1,2</sup>

<sup>1</sup>Hahn-Schickard, <sup>2</sup>Department of Microsystems Engineering - IMTEK

### PD57

#### Thermal design of LoC-on-PCB

Francisco Perdigones, Miguel Cabello, Jose M. Quero

Escuela Superior de Ingeniería. Universidad de Sevilla

### PD59

#### Versatile fabrication technology for microfluidic systems

Patrícia Sousa<sup>1</sup>, Jordi Llobet<sup>1</sup>, José Fernandes<sup>1</sup>, Sara Vidal<sup>2</sup>, Tamara Delgado<sup>2</sup>, Perea Otero<sup>2</sup>, Pablo Romero<sup>2</sup>, João Gaspar<sup>1</sup>

<sup>1</sup>International Iberian Nanotechnology Laboratory, <sup>2</sup>AIMEN Technology Centre

### PD61

#### Effect of oxygen plasma micro/nanostructured PMMA plates on the adhesion and proliferation of normal and cancer cells

Anastasia Kanioura<sup>1</sup>, Panagiota Petrou<sup>1</sup>, Vassilios Constantoudis<sup>2</sup>, Dimitris Kletsas<sup>3</sup>, Angeliki Tserepi<sup>2</sup>, Evangelos Gogolides<sup>2</sup>, Margarita Chatzichristidi<sup>4</sup>, Sotirios Kakabakos<sup>1</sup>

<sup>1</sup>Institute of Nuclear & Radiological Sciences & Technology, Energy & Safety, NCSR "Demokritos", <sup>2</sup>Institute of Nanoscience & Nanotechnology, NCSR "Demokritos", <sup>3</sup>Institute of Biosciences and Applications, NCSR "Demokritos", <sup>4</sup>Department of Chemistry, University of Athens

### PD63

#### A microfluidic device for live cells capturing and phenotyping using dielectrophoresis and metasurface-enhanced infrared reflection spectroscopy

Glen Kelp<sup>1,2,3</sup>, Joy Li<sup>3</sup>, Junlan Lu<sup>3</sup>, Nicholas DiNapoli<sup>3</sup>, Robert Delgado<sup>3</sup>, Shourya Dutta-Gupta<sup>3,4</sup>, Gennady Shvets<sup>3</sup>

<sup>1</sup>Institute Of Physics, University Of Tartu, <sup>2</sup>Department of Physics, University of Texas at Austin, <sup>3</sup>School of Applied and Engineering Physics, Cornell University, <sup>4</sup>Department of Materials Science and Metallurgical Engineering, Indian Institute of Technology Hyderabad

### PD65

#### Circular continuous flow PCR on a PCB microchip

Panagiotis Skaltsounis, Georgia Kaprou, Angeliki Tserepi, George Kokkoris

Institute Of Nanoscience And Nanotechnology NCSR "Demokritos"

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

### PD46

#### Patterning of Carbon Quantum Dots based thin films for electronic devices and sensors

Apostolos Segkos<sup>1,2</sup>, Charalampia Kalogirou<sup>2</sup>, Elias Sakellis<sup>1</sup>, Nikolaos Boukos<sup>1</sup>, Konstantinos Kordatos<sup>2</sup>, Christos Tsamis<sup>1</sup>

<sup>1</sup>NCSR Demokritos, <sup>2</sup>NTUA - School of Chemical Engineering

### PD50

#### Authentication of bilberries by Surface Enhanced Raman Spectroscopy

Lina Traksele<sup>1</sup>, Ceslovas Bobinas<sup>2</sup>, Gitana Alencikiene<sup>1</sup>, Alvija Salaseviciene<sup>1</sup>, Valentinas Snitka<sup>1</sup>

<sup>1</sup>Kaunas University of Technology, Food Institute, <sup>2</sup>Lithuanian Research Centre for Agriculture and Forestry Institute of Horticulture

### PD52

#### A plasmonic array of standing wires in the trigonal symmetric arrangement for broadband, polarization insensitive molecular sensing

Andrea Giugni, Marco Allione, Bruno Torre, Giovanni Marinaro, Jurgen Kosel, Enzo Di Fabrizio

Kaust - King Abdullah University Of Science and Technology

### PD54

#### Evaporation-induced biosensing on superhydrophobic surface

Rokon Uddin, Ville Jokinen, Mehran Mohammadi, Sami Franssila

Aalto University

### PD56

#### Controlled Dispensing and Mixing in Microfluidic Devices for Multiplex Genetic Diagnosis

Daigo Natsuhaba<sup>1</sup>, Keisuke Takishita<sup>1</sup>, Kisuke Tanaka<sup>1</sup>, Azusa Kage<sup>1</sup>, Moeto Nagai<sup>1</sup>, Yuko Mizukami<sup>2</sup>, Norikuni Saka<sup>2</sup>, Takayuki Shibata<sup>1</sup>

<sup>1</sup>Toyohashi University of Technology, <sup>2</sup>Aichi Agricultural Research Center

### PD58

#### Droplet-based fluid central processing platform and applications

Yaru Xing<sup>1</sup>, Xianming Liu<sup>2</sup>, Yu Liu<sup>1</sup>, Rifei Chen<sup>1</sup>, Xing Cheng<sup>1</sup>

<sup>1</sup>Southern University of Science and Technology, <sup>2</sup>Dalian Institute of Chemical Physics, Chinese Academy of Sciences

### PD60

#### Fabrication of a drug delivery tool via Laser-Induced Forward Transfer

Agamemnon Kalaitzis<sup>1</sup>, Christina Kryou<sup>1</sup>, Chrysoula Chandrinou<sup>1</sup>, Nikolaos Adamopoulos<sup>2</sup>, Ioanna Zergioti<sup>1</sup>

<sup>1</sup>National Technical University of Athens, <sup>2</sup>Galenica S.A.

### PD62

#### Reflow Process for Fabricating Curved Shaping Molds of PDMS Microchannels and Chambers

Shunya Okamoto<sup>1,2</sup>, Yoshiaki Ukita<sup>1</sup>

<sup>1</sup>University of Yamanashi, <sup>2</sup>JSPS Research Fellow

WEDNESDAY, 25<sup>TH</sup>, 2019 (ODD NUMBERS)

**PD67**

**On-chip synthesis of ruthenium complex in a microchannel by microwave heating**

Masaya Takeuchi<sup>1</sup>, Mitsuyoshi Kishihara<sup>2</sup>, Toshiro Kobayashi<sup>3</sup>, Akinobu Yamaguchi<sup>1</sup>, Takeko Matsumoto-inoue<sup>4</sup>, Yuichi Utsumi<sup>1</sup>

<sup>1</sup>University of Hyogo, <sup>2</sup>Okayama Prefectural University,

<sup>3</sup>National Institute of Technology, Tsuyama College,

<sup>4</sup>Minerva Light Lab. Inc.

**PD69**

**Development of an automated system for obstructive sleep apnea treatment based on machine learning and breath effort monitoring**

A-I Kanaris<sup>1</sup>, K. Tsoutis<sup>2</sup>, K-N Kanellopoulou<sup>1</sup>, S. Chatzandroulis<sup>1</sup>, Vasiliki Tsouti<sup>1</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology, NCSR Demokritos, Ag. Paraskevi, 15310, Greece, <sup>2</sup>Athens Dental Sleep Medicine, Athens, 11528, Greece

**PD71**

**3D Scaffolds by soft lithography for retinal tissue reconstruction**

Frédéric Hamouda<sup>1</sup>, Stéphane Guilet<sup>1</sup>, Etienne Herth<sup>1</sup>, Elise Herardot<sup>2</sup>, Lise Morizur<sup>2</sup>, Karim Ben M'Barek<sup>2</sup>, Christelle Monville<sup>2</sup>

<sup>1</sup>C2N/CNRS UMR 9001, <sup>2</sup>I-Stem, AFM, INSERM/UEVE 861

**PD73**

**Internalization and viability studies of suspended nanowires silicon chips in HeLa cells**

Sara Duran<sup>1</sup>, Marta Duch<sup>1</sup>, Rodrigo Gómez<sup>1</sup>, Marta Fernández<sup>1</sup>, Manuel Reina<sup>2</sup>, Claudia Müller<sup>2</sup>, Álvaro San Paulo<sup>3</sup>, Jaume Esteve<sup>1</sup>, Susana Castel<sup>2</sup>, José Antonio Plaza<sup>1</sup>

<sup>1</sup>Institute of Microelectronics of Barcelona IMB-CNM, (CSIC), <sup>2</sup>Departament de Biología Cel·lular, Universitat de Barcelona, <sup>3</sup>Instituto de Microelectrónica de Madrid, IMMCN (CSIC)

**PD77**

**Nanosecond Laser Irradiation on Cells Using Titanium Thin Film for Massively Parallel Cell Intranuclear Delivery**

Shin Sawai<sup>1</sup>, Harsh Gupta<sup>1</sup>, Tuhin Santra<sup>2</sup>, Azusa Kage<sup>1</sup>, Takayuki Shibata<sup>1</sup>, Moeto Nagai<sup>1</sup>

<sup>1</sup>Toyohashi University of Technology, <sup>2</sup>Indian Institute of Technology Madras

**PD79**

**In vitro bone marrow tissue development in 3D microfluidic cell culture chambers towards bone marrow-on-a-chip**

Dionysia Kefallinou<sup>1</sup>, Maria Grigoriou<sup>2</sup>, Angelos Zeniou<sup>1</sup>, Dimitrios T. Boumpas<sup>2,3</sup>, Evangelos Gogolides<sup>1</sup>, Angeliki Tserepi<sup>1</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology, National Center For Scientific Research "Demokritos", <sup>2</sup>Biomedical Research Foundation Academy of Athens, <sup>3</sup>4th Department of Medicine, Attikon University Hospital

**PD83**

**Sensitive and rapid PCB-based microfluidic platform for monitoring urinary tract infections**

Myrto Filippidou<sup>1</sup>, Georgia Kaprou<sup>1</sup>, Sotiris Ntouskas<sup>1</sup>, George Kokkoris<sup>1</sup>, Panagiota Petrou<sup>2</sup>, Dimitris Mastellos<sup>2</sup>, Stavros Chatzandroulis<sup>1</sup>, Angeliki Tserepi<sup>1</sup>

<sup>1</sup>Institute of Nanoscience and Nanotechnology, NCSR "Demokritos", <sup>2</sup>Institute of Nuclear & Radiological Sciences & Technology, Energy & Safety, NCSR "Demokritos"

TUESDAY, 24<sup>TH</sup>, 2019 (EVEN NUMBERS)

**PD64**

**Impulsion system for DNA amplification microdevice integrated on PCB**

Dimitra Kouvara<sup>1</sup>, Georgia Kaprou<sup>1</sup>, Francisco Perdigones<sup>2</sup>, José Manuel Quero<sup>2</sup>, George Kokkoris<sup>1</sup>, Angeliki Tserepi<sup>1</sup>

<sup>1</sup>NCSR Demokritos, Institute of Nanoscience & Nanotechnology, <sup>2</sup>University of Seville, School of Engineering

**PD66**

**The Investigation of Water Disinfection by Deep Ultraviolet Light-Emitting Diodes Array**

Prof Chien-ping Wang<sup>1</sup>, Zong-Ru Yeb<sup>2</sup>

<sup>1</sup>National Taipei University of Technology, <sup>2</sup>Department of Mechanical Engineering, Chung-Yuan Christian University

**PD68**

**Automated and versatile platform for cell culture and cardiac differentiation on engineered microsystems**

Gabriele Pitingolo<sup>1</sup>, Yong He<sup>1</sup>, Boxin Huang<sup>1</sup>, Li Wang<sup>2</sup>, Yong Chen<sup>1</sup>

<sup>1</sup>École Normale Supérieure-PSL Research University, Sorbonne Universités - UPMC Univ Paris 06, CNRS UMR 8640 PASTEUR, <sup>2</sup>MesoBioTech

**PD72**

**Photocatalytic Nanofabrication and Intracellular Imaging of Living Cells Using Functionalized AFM Probe**

Takayuki Shibata<sup>1</sup>, Kazutaka Uchida<sup>1</sup>, Junya Araki<sup>1</sup>, Miho Ishii-Teshima<sup>1</sup>, Terutake Hayashi<sup>2</sup>, Moeto Nagai<sup>1</sup>

<sup>1</sup>Toyohashi University of Technology, <sup>2</sup>Kyushu University

**PD74**

**Microfluidic channel with embedded monolayer nanofibers for cell culture and co-culture**

Boxin Huang<sup>1</sup>, Yong He<sup>1</sup>, Li Wang<sup>2</sup>, Jian Shi<sup>2</sup>, Jie Hu<sup>1</sup>, Elrade Rofaani<sup>1</sup>, Ayako Yamata<sup>1</sup>, Yong Chen<sup>1</sup>

<sup>1</sup>École Normale Supérieure-PSL Research University, Sorbonne Universités - UPMC Univ Paris 06, CNRS UMR 8640 PASTEUR, <sup>2</sup>MesoBioTech

**PD78**

**Cryo-FIB preparation of neuron cell interface**

Gregory Panaitov<sup>1</sup>, Elmar Neumann<sup>2</sup>, Andreas Offenhäusser<sup>1</sup>

<sup>1</sup>Institute for Bioelectronics, Research Center Jülich, <sup>2</sup>Helmholtz Nano Facility, Research Center Jülich

**PD82**

**Development of organ-on-chip barrier devices in new soft thermoplastics**

Emma Thomée<sup>1,2</sup>, Alexander McMillan<sup>1,3</sup>, Alessandra Dellaquila<sup>1,4</sup>, Alba Calatayud<sup>5</sup>, Enrique Azuaje Hualde<sup>5</sup>, Lourdes Basabe-Desmonts<sup>5</sup>, Sasha Cai Lesher-Pérez<sup>1</sup>

<sup>1</sup>Elvesys Microfluidics Innovation Center, <sup>2</sup>University of Strasbourg, CNRS/ISIS UMR 7006, <sup>3</sup>Department of Microbial and Molecular Systems, Centre for Surface Chemistry and Catalysis (COK), KU Leuven, <sup>4</sup>Biomolecular Photonics, Department of Physics, University of Bielefeld, <sup>5</sup>BIOMICS Microfluidics Research Group, Microfluidic Cluster UPV/EHU

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With continually supporting and working together with the customers, we will strive to make continuous contributions to the future of Science.

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On the basis of "Creativity and Research and Development", JEOL positively challenges the world's highest technology, thus forever contributing to the progress in both Science and Human Society through its products.

## Guiding Principles for JEOL Staff

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1. We will take pride in our work and endeavor to reform our present situation with challenging spirits.
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4. We will understand others' positions and fulfill our responsibilities through good teamwork.
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6. We will absorb a wide range of knowledge and put it in practice for our own growth.

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### Name

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### Address (head office)

1-2, Musashino 3-chome, Akishima, Tokyo, 196-8558, Japan

### Business activities

Manufacturing, sales, research and development of high-precision scientific instruments (electron optics instruments and analytical instruments), measuring instruments, semiconductor equipment, industrial equipment and medical equipment. Manufacturing and maintenance service of products and components associated with these instruments, and purchase and sales of peripheral equipment.

### Establishment

May 30, 1949

### Capital

10,038 million yen (as of March 31, 2018)

### Stock

Listed on the First Section of the Tokyo Stock Exchange

### Net Sales (consolidated)

104.570 million yen (as of the end of fiscal year 2018 (March 31, 2018))

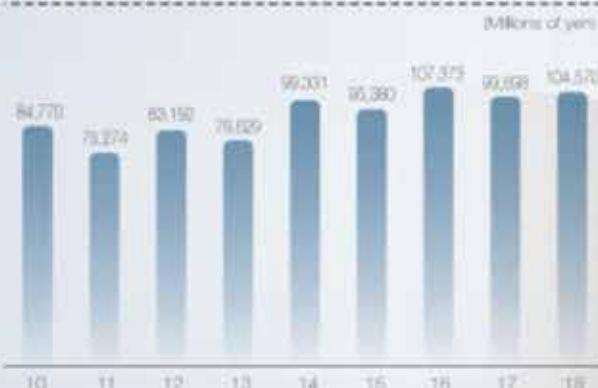
### Number of employees (consolidated)

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### Domestic subsidiaries and affiliated companies

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Booths 4-5



Booth 3



Booth 1



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## Standard Exhibitors

Booth 35



Booths 40-41



Booth 46



Booth 21



Booth 30

project  
FLEXPOL EUROPE

Booth 27



Booth 34



Booth 26



Booth 45



Booth 29



Booth 22A



Booth 22B



Booth 25



Booth 42a



Booth 36



Booth 28



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# Authors' Index

45<sup>th</sup> International Conference on  
**MNE** 2019

# Authors' Index

## A

- Abbarchi M.....A6-1, B10-2  
Abdul B.....PC121  
Abe K.....C2-5, PC126  
Abid Z.....D1-3, D4-2  
Abualnaja F.....C8-3  
Accardo A.....D9-3  
Adachi S.....D6-3  
Adamopoulos N.....PD60  
Adikimenakis A...PB23, PB25,  
.....PC18  
Adjeroud N.....B10-3, PC59  
Aeppli G.....A1-3  
Agbulut O.....D5-2  
Ah C.....PC21, PC42, PC43  
Ahmad A.....PA72  
Ahmad Z....B4-3, PB45, PB47  
Ahn J.....PD34  
Ahn S.....B9-3  
Aime C.....D1-2  
Akama R.....PA30  
Akrofi J.....PC08, PC20  
Al Jassin-Al-Hashemi E ... B1-1  
Alaca B.....PB12  
Alam B.....PC38  
Alava M.....A4-1  
Alayo N.....PC68  
Albrechtsen M.....PA21  
Aleksandrova M...PC73, PC74  
Alencikiene G.....PD50  
Alexandropoulos D ..... PA07,  
.....PA08, PA09, PC51  
Algieri L .... C5-2, PC92, PC97,  
..... PC121  
Allione M..... A5-3, D3-1, D8-2,  
..... PC26 PC44, PD52  
Almpanis E.....PB78, PB81  
Aloni S.....C9-2  
Alshareef H.....PC55  
Altamirano Sanchez E .... A2-1  
Altmann F.....A7-3  
Altug H.....D2-2, D6-1  
Alvarez Feito D.....C2-2  
Alves F.....C4-2  
Amano H.....A7-4  
Amargianitakis E.....PC53  
Amat E.....C8-1  
Amaya K.....A3-3  
Anacleto P.....PC77, PC80  
Anastasiadis S.....PC140  
Anastasiou A.....PA07  
Andreev A.....C8-3  
Andreoli F.....D4-2  
Androulidaki M...PA45, PB23,  
.....PB25, PC18, PC89  
Angelopoulou M.....PD40

## B

- Anhøj T.....PB32  
Antunes M.....PA62  
Ap A.....PD11  
Aperathitis E.....C8-4  
Arakaki R.....PC91  
Araki J.....PD72  
Arana A.....B8-3  
Arapis A.....PB82  
Araya K.....PC67  
Argitis P ... A10-1, PB44, PD27  
Ari A.....PC128, PC129  
Arjona M.....C4-1  
Arocas J.....PC29  
Arunachalam S .. B4-3, PB45,  
.....PB47  
Arutunov K.....PA23  
Asano K.....PC113  
Asif M.....PA43  
Aslanidis E ..... C4-4, PC63  
Assemat P.....D9-3  
Aßmann C.....PC154  
Atthi N.....B8-2, PB39  
Außerhuber H....PA40, PC122,  
.....PD14  
Averkin S.....PA68  
Avilovas L.....PC117  
Awsiuk K.....B9-4  
Ay F.....PB67  
Ayadi Y.....PC60  
Azuaje Hualde E.....PD82
- Bartha J ..... C2-4  
Barthelmess M ..... PA54  
Bartošík M ..... PB69  
Basabe-Desmonts L ..... PD82  
Bastian P ..... PA55  
Batzler M ..... PA14  
Baumgartner D ..... PD55  
Bausells J ..... C8-1  
Bayer I ..... B2-3  
Becherer M ..... PC88  
Becker J ..... PA46  
Belahcen S ..... PC02  
Beleggia M ..... PA14  
Belharet D ..... PC138  
Bellanca G ..... PC38  
Belushkin A ..... D6-1  
Ben M'Barek K ..... PD71  
Benali A ..... B10-2  
Berbezier I ..... B10-2  
Berenschot E ..... PB40  
Berenschot J ..... PA10  
Berger G ..... A8-3  
Berggren K ..... C7-3  
Bernasconi S ..... PC02  
Bertagnolli E ..... PA44  
Bertana V ..... PC75, PC152  
Bertani F.....C2-3, PC41, D9-2  
Berti D ..... PD08  
Besbes M ..... PC30, PC32  
Besson A ..... A4-2  
Beyer J ..... PC154  
Bhardwaj R ..... PD16  
Bhattacharya S ..... PC56  
Bianchini M ..... PC68  
Bianco M ..... C6-4, D10-1  
Bicer M ..... PB12  
Bidal E ..... PD12  
Bienvieu F ..... PD39  
Bienvieu J ..... PD39  
Bigo A ..... D3-1  
Bijelic G ..... D6-4  
Birmpiliotis D ..... PC139  
Bisig S ..... A9-1  
Biswas S ..... PB68  
Blaise P ..... PC02  
Blaschke D ..... PC45  
Blosse S ..... D9-3  
Bobinas C ..... PD50  
Bockhorn L ..... PC154  
Boeck T ..... B10-1  
Boemmels J ..... A2-1  
Boisen A .... D1-3, D4-2, PA34,  
.....PB28  
Bolat S ..... B1-1  
Bollani M ..... B10-2

- Bolt P.....PC80  
 Bolten J.....PB38  
 Bonanni S.....A9-1  
 Bonse J.....B10-1  
 Bonvalot M.....PC02  
 Borgelink B.....PB40  
 Bork E.....PC154  
 Botsialas A.....PC56  
 Bottein T.....A6-1  
 Bouabdellaoui M.....B10-2  
 Boukos N.....PD46  
 Boumpas D.....PD79  
 Bourban G.....C2-2  
 Bourganos V.....PC140  
 Bourim E.....PC153  
 Bousoulas P.....PC14  
 Boussey J.....PA45  
 Bouzga A.....PB50  
 Boyer L.....D9-3  
 Brambilla A.....PB07  
 Brand S.....A7-3  
 Brandl L.....PD36  
 Brandl M.....PD32, PD36  
 Braun E.....D9-2  
 Braun T.....A5-5  
 Bravo J.....PB49  
 Bresson P.....PC32  
 Brett G.....D9-2  
 Brianceau P.....B3-2  
 Brinkmann S.....PD13  
 Briz Iceta N.....D6-4  
 Brose S.....A1-1  
 Brox O.....PC28  
 Brückl H.....PD51  
 Brueckl H.....PA39, PD28  
 Brugger J.....C6-3, PB31  
 Bruk M.....PA71  
 Bryche J.....PC30, PC32  
 Buch Z.....PB09, PC47  
 Budkowski A.....B9-4, D2-4  
 Buitrago E.....D2-1  
 Bunea A.....B6-3, PB79  
 Burg T.....PD33  
 Burghartz J.....PC142  
 Burkhardt C.....PC110  
 Busche J.....A5-1  
 Businaro L...C2-3, PC41, PD75  
 Busnaina A.....B5-2  
 Bustos K.....PA54  
 Buttner U.....PB47, PC56
- C**
- Cabello M.....PD57  
 Cabrini S.....A2-4, C9-2  
 Cai J.....PC34  
 Calafiore G.....C9-2  
 Calatayud A.....PD82  
 Calaza C.....PA62, PC135  
 Calò G.....PC38  
 Calvo-Lozano O.....D6-1  
 Cambel V.....PA18  
 Cambril E.....PD02  
 Candeloro P.....D3-1  
 Canva M.....PC30, PC32  
 Cao J.....PB62, PB63, PB64, .....PC81  
 Capula Colindres S.....PC87  
 Cardinaud C.....PA63  
 Casolino A.....PC37  
 Caspary R.....PA46  
 Castel S.....PD73  
 Catinaccio A.....C2-2  
 Čehovski M.....PA46, PC23  
 Ceylan H.....C5-5  
 Chakraborty P.....PD31  
 Chan B.....A2-1  
 Chandrinou C.....PD60  
 Chang B.....PB89  
 Chang S.....C9-4, D2-5  
 Chang T.....PB15, PB18, .....PB28, PB84, PC93, PC99, ... PC107, PC108, PC112, PC113, .....PC120, PC148, PD31  
 Chang W.....B6-1, D2-3, PC83  
 Chapman H.....PA54  
 Charalambopoulou G.....PB51  
 Charette P.....PC32  
 Charfi O.....PC23, Charpin-Nicolle C.....PC02  
 Chatterjee D.....PD11  
 Chatzandroulis S.....PC66, .....PD69, PD83  
 Chatzichristidi M.....A10-1, .....PB44, PB88, PD27, PD61  
 Checcucci S.....A6-1  
 Chen C.....C9-2  
 Chen C.Y.PC99, PC108, PC112, .....PC113, PC120, PD31  
 Chen H.....C9-4, D2-5  
 Chen J....PB62, PB63, PB64, .....PC81  
 Chen L.....PC72  
 Chen R.....PD58  
 Chen W.....PC39, PC80  
 Chen X.....PC56  
 Chen Y.....A7-5, A10-2, B6-1, C5-1, .....C7-4, D1-2, D2-5, PA12, .....PA69, PB29, PC33, PD19, .....PD68, PD74  
 Chen Z.....A4-1, PA69, PB29, .....PC93, PC116  
 Cheng X.....PC34 , PD58  
 Cheon S.....PC42, PC43  
 Chiabrera F.....PC68  
 Chien M.....PC47  
 Chien Y.....PC120, PD31  
 Chiu W.....PC99, PD31  
 Chiu Y.....C3-2  
 Cho C.....PB17, PB43  
 Cho S. .... PC21, PC42, PC103  
 Choi H.....PB31, PD04  
 Choi J.....D10-2, PC69, PD04  
 Choi K.....PD34  
 Choi Y.....PA53  
 Chong H.....PC08, PC20  
 Chopdekar R.....A4-1  
 Chou C.....D8-1, PB15  
 Chouiki M.....A8-3  
 Choulis S.....C5-3  
 Chuai W.....D10-4  
 Chun M.....PD45  
 Chung S.....B8-1, PA26, PB58  
 Chunilal L.....PD39  
 Ciccacci F.....PB07  
 Ciccirillo F.....PC92  
 Ciosek J.....PB48  
 Clark M.....B7-2  
 Claude J.....B10-2  
 Clemente J.....PB49  
 Clime L.....B7-1  
 Cobb B.....PC101  
 Cocuzza M.....B7-4, D4-2, .....PC75, PC152  
 Collienne S.....PC24  
 Colonna G.....PC92  
 Coluccia A.....D5-1  
 Cong C.....PC19  
 Constantinides G.....PB51  
 Constantinou P.....A1-3  
 Constantoudis V.....A3-1, .....PA74, PA75, PB24, PB82, .....PB86, PB88, PD61  
 Cooke M.....A2-4  
 Cordeau M.....PC02  
 Cordova I.....PD15  
 Cottat M.....PA45  
 Couris S.....PC51  
 Courson R.....A4-2, PD12  
 Courtot A.....PC138  
 Cousins R.....B7-2  
 Creff J.....A4-2  
 Cretu E.....PC90  
 Crockett R.....B6-2  
 Crowe I.....PC09  
 Csato C.....PC142  
 Cuda G.....D3-1  
 Cui J.....C4-5  
 Cui Y.....PC119

# Authors' Index

- C**
- Cummins C.....PB20
  - Cumont A.....PB59
  - Curson N.....A1-3
  - Cybinska J.....PA25, PA59
  - Czerwiec T.....PA63
- D**
- Da Costa T.....PC69
  - Dąbczyński P.....B9-4
  - Dais C.....A1-5
  - Dale P.....PC77
  - Dallery J.....B3-2
  - Dallorto S.....A2-4
  - Damoulakis G.....PD23
  - Daniel L.....C7-3
  - Danylyuk S.....A1-1
  - Darivianaki E.....PC89
  - Darnon M.....B10-4
  - Das D.....PC157
  - Das R.....B4-3, PB45, PB47
  - DasGupta A.....PD11
  - Davazoglou D.....PB22
  - Davila D.....PB83
  - Davitt F.....PB68
  - De Angelis F.....C9-1
  - De Angelis M.....D3-1
  - de Boer M.....PA65, PC134, PD01
  - De la Vega F.....PC101
  - De Marneffe J.-F.....A2-1
  - De Ninno A.....C2-3, PC41
  - De Nuccio F.....A5-4
  - De Planque M.....PC20
  - De Vittorio M.....A5-4, A7-1, C5-2, C6-4, D1-1, D5-1, D10-1, PC37, PC38, PC92, PC97, PC121
  - Decuzzi P.....D1-1
  - Deenen C.....PB40
  - Deie K.....PC155
  - Del Moral A.....C8-1
  - Delamadeleine E.....PC53
  - Delapierre F.....PD02
  - Delgado C.....A6-3
  - Delgado R.....PD63
  - Delgado T.....PD59
  - Delhaye T.....PC90
  - Deligeorgis G.....C8-4, PB23, PC18
  - Della Casa P.....PC28
  - Dellaquila A.....PD21, PD82
  - Delobbe A.....A7-3
  - DeLongchamp D.....PD15
  - DeMello J.....D2-1
  - Demir A.....PC128
  - Demiralp B.....PC129
  - Deng B.....A7-5
  - Deng J.....A10-2, C7-4, PA69
  - Dér A.....PD44
  - Derer J.....PA18
  - Dereux A.....PC29
  - Desmet G.....PD06
  - Despont M.....C2-2
  - Dey P.....D6-1
  - Dhuey S.....A4-1, A2-4, C9-2
  - Di Fabrizio E.....A5-3, D3-1, D8-2, PC26, PC44, PC55, PD52
  - Di Francesco M.....D1-1
  - Di Mascolo D.....D1-1
  - Di Pietro V.....PC122, PD14
  - Di Rienzo M.....PC92
  - Dias R.....C4-2
  - Dickreuter S.....C6-1, B3-3
  - Dietzel A.....A5-1, D7-1, PC94, PC115, PC118, PDO7, PD13, PD33
  - Diewald S.....PA13
  - Dimitrakellis P.....PB53
  - Dimitrakis P.....PA23, PA75
  - Dimou A.....PB88
  - DiNapoli N.....PD63
  - Dipalo M.....C9-1
  - Dobson P.....PC117
  - Domke M.....PC48
  - Dong L.....C5-5
  - D'Orazio A.....C6-4, PC37, PC97
  - Dore C.....A10-3
  - Doundoulakis G.....PB23, PB25, PC18, PC53
  - Dow L.....D3-3
  - Drezner Y.....A7-2, B9-1
  - Drobczynski S.....PA25
  - Drouin D.....B10-4, PC60
  - Drzyzga A.....PC110
  - Du L.....PC57, PC111
  - Duan Y.....PC64
  - Duch M.....C4-1, PD73
  - Duchesne E.....PC60
  - Dudus A.....PA27
  - Duerig U.....A9-1
  - Dufour T.....D5-2
  - Dümpelmann L.....D6-1, PB85
  - Dùò L.....PB07
  - Duque M.....C10-4
  - Duran S.....PD73
  - Durrani Z.....C8-3
  - Dürrenfeld P.....PA15
  - Dutoya A.....PD08
  - Dutta-Gupta S.....PD63
  - Dyck O.....B1-4
- E**
- Eberle S.....PB87
  - Ebert M.....PC08, PC20
  - Echresh A.....PB26
  - Ecoffey S.....B10-4
  - Eden A.....D7-3
  - Edoff E.....PC80
  - Eftychis S.....PB25
  - Eibelhuber M.....A8-3, PA06, PA27
  - Ekinci Y.....A1-3, A1-4, A5-5
  - El Hachemi M.....B10-3, PC59,
  - El-Demellawi J.....PC55
  - Elias M.....PD08
  - Ellinas K.....B4-2, D6-2, PB52, PB54, PB55
  - Elphick K.....PB10
  - Elshaer A.....B10-4, PC60
  - Elsukovaa A.....PA14
  - El-Zohry A.....PC55
  - Emnéus J.....PA11
  - Endo K.....PC07
  - Engay E.....B6-3, PB79
  - Engel L.....B1-2, D3-3
  - Engelmann H.....B3-2, C8-1
  - Erbe A.....PC15
  - Erbil S.....PC129
  - Erdogan R.....PC128
  - Erdogan T.....D3-2
  - Erfle P.....D7-1
  - Ernst O.....B10-1
  - Ertl P.....PA44
  - Esmek F.....D8-3
  - Esteve J.....PD73
  - Estevez M.....D6-1
  - Ettenauer J.....PD36
  - Eychenne B.....PC02
  - Eylers K.....B10-1
- F**
- Fàbrega A.....D6-1
  - Fabri-Faja N.....D6-1
  - Fadida S.....PA62
  - Fahrbach M.....C9-3
  - Faingold Y.....PA62
  - Fan D.....D7-2
  - Fan S.....C3-2
  - Fang Y.....PC50, PC51
  - Farhan A.....A4-1
  - Fauçon M.....B3-4
  - Faustini M.....A6-1
  - Favre L.....A6-1, B10-2
  - Fechner R.....C1-3
  - Fechtig D.....B5-4, PA40
  - Fedorov A.....B10-2

- Felici M.....PC35  
 Feng B.....C5-1, PC33  
 Fernandes J.....PD59  
 Fernández M.....PD73  
 Fernandez-Cuesta I.....D8-3  
 Fernández-Luna J.....PD37  
 Fernández-Sánchez C... PD30  
 Ferrero S.....PC75, PC152  
 Ferstl M.....A4-3  
 Filippidou M.....PD83  
 Finazzi M.....PB07  
 Fischer P.....PA54  
 Flandre D.....PC90  
 Fleischer M.....B3-3, C6-1  
 Florès-Galicia F.....PD02  
 Foncy J.....A4-2  
 Fonseca H.....PA62  
 Fonseca L.....PC68  
 Fourneau E.....PC24  
 Francis L.....PC90  
 Franco A.....PD37  
 Francone A.....B8-3  
 Franssila S.....B2-2, PD54  
 Frei T.....C2-2  
 Fremont H.....PC60  
 Frericks M.....PC23  
 Fricke J.....PC28  
 Fu L.....D10-4  
 Fuchs E.....A6-3, A9-4, PA49  
 Fujitsuna I.....PC62  
 Fukuda H.....A3-4  
 Fukuda M.....PC27  
 Fukuoka T.....PB10  
 Fürjes P.....PD44  
 Furutsuka T.....PC155  
 Fyrogenis R.....D2-4
- G**
- Gabrion X.....PC138  
 Gäding M.....PC115  
 Gaeitta G.....D3-3  
 Gagaoudakis E.....C8-4  
 Gamby J.....PD02  
 Gann E.....PD15  
 Gao Y.....PC124  
 Garbayo I.....PC68  
 Garcia I.....C4-2  
 Gardeniers H.....C1-2, PB40,  
                   PD06  
 Gardeniers J.....PA10  
 Garnier L.....PD39  
 Gasiorowski J.....PA27  
 Gaspar J.....C4-2, PA62,  
                   PC135, PD59  
 Gass V.....C2-2
- Gaudé V.....PD39  
 Gaulding A.....C9-2  
 Gazi S.....PA18  
 Ge C.....PC90  
 Geidel S.....D6-4  
 Gelloz B.....PB02  
 Gemini L.....B3-4  
 Georgakilas A.....PB23, PB25,  
                   PC18  
 Georgiev Y...D2-1, PB26, PC15  
 Gerardino A.....C2-3, D9-2,  
                   PC41, PD75  
 Gerngroß M.....A1-1, A9-3,  
                   PA06, PA15, PA16,  
                   PA52, PA55  
 Gharbi A.....B3-2, C8-1  
 Ghavami M.....PC129  
 Ghazali N.....PC08  
 Ghoshal T.....A6-4, PA48  
 Giannakopoulos K.....C4-4  
 Giannatou E.....A3-1, PA74  
 Giannitelli S.....C2-3  
 Giannotti D.....PB07  
 Girard A.....PA63  
 Giraud E.....PA48  
 Girod S.....B10-3, PC59  
 Giselbrecht S.....D3-4  
 Giugni A.....D3-1, D8-2, PC26,  
                   PC44, PC55, PD52  
 Gkiolas D.....PB54  
 Gogol P.....PC30  
 Gogolides E.....A3-1, B4-2,  
                   D6-2, PA74, PB24,  
                   PB52, PB53, PB54, PB55,  
                   PD18, PD61, PD79  
 Golibrzuch M.....PC88  
 Goll G.....PA13  
 Gollmer D.....C6-1  
 Gomez M.....C10-4  
 Gómez R.....PD73  
 Gómez V.....PA04  
 Gómez-Martínez R.....C4-1  
 González F.....PD37  
 González-García L.....B1-2  
 González-López J.....D6-1  
 Goodyear A.....A2-4  
 Gora E.....PD44  
 Görrn P.....PA33, PA36  
 Gotszalk T.....PB87, PC131,  
                   PC136  
 Götz J.....D6-4  
 Gounet P.....A7-3  
 Goupil G.....A7-3  
 Gourgon C.....PA45  
 Goustouridis D....D2-4, PB57,  
                   PD26  
 Graczyk M.....PA04, PA43
- Grande M....C6-4, PC37, PC97  
 Granz T.....C9-3, PA17  
 Greenzweig Y.....A7-2, B9-1  
 Grenci G.....PA35  
 Griffiths J.....C8-3  
 Grigoriou M.....PD79  
 Groenesteijn J... PC134, PD01  
 Grossos D.....A6-1, B10-2  
 Grüneberger F....A9-3, PA06,  
                   PA15, PA16, PA55  
 Grützner G.....A4-3, PA56  
 Grützner S.....A4-3  
 Gryan P.....B10-3, PC59  
 Gu C.....PB30, PB34, PB35  
 Guido F.....C5-2, PC37, PC92,  
                   PC97, PC121  
 Guillet S.....PA63, PD02, PD71  
 Guillén E.....PC78  
 Gülink J.....C9-3, PA17  
 Guneri Yazgi S.....PB12  
 Guo Z.....D10-4  
 Gupta H.....PD77  
 Gurioli M.....A6-1  
 Gutiérrez-Capitán M.... PD30  
 Guttmann M.....A4-3  
 Guzenko V.....A5-5  
 Guzman R.....B6-2
- H**
- Ha M.....PC04, PC05 , PC76  
 Ha S.....PC143  
 Ha T.....PA26  
 Ha Y.....PB05  
 Haas S.....B5-3  
 Haase A.....D6-4  
 Habibović P.....D3-4  
 Haeger T.....PA36  
 Haenschke F.....PC45  
 Hagen C.....A5-2, PB04  
 Haghiri-Gosnet A.....PD02  
 Hahn L.....A9-3  
 Hallstein R.....A7-2, B9-1  
 Halsall M.....PC09  
 Hammani K.....PC29  
 Hammersley S.....PC09  
 Hamouda F.....PC30, PD71  
 Han A.....PA14  
 Han J.....PC21  
 Han M.....PC57  
 Hanay M.. D3-2, PC128, PC129  
 Hanein D.....D3-3  
 Hansen O.....PA60  
 Harada A.....PB60  
 Harada T.....A1-2  
 Harjanne M.....D2-4

# Authors' Index

- Hartbaum J. .... A8-3, C7-2,  
..... PA27
- Hasegawa H. .... C2-5, PC126
- Hasegawa Y. .... PC58, PC62,  
..... PC65
- Hashigata K. .... PC113
- Haslinger M. .... B5-4, PA39,  
..... PC78, PD28, PD51
- Hasumi K. .... PA76
- Hatipoglu U. .... PC129
- Hatzopoulos Z. .... PC89
- Haus J. .... PC115
- Hayashi T. .... PD72
- He Y. .... D1-2, PB03, PD19,  
..... PD68, PD74
- Hedhili M. .... PC55
- Heerkens C. .... C2-1
- Heiderhoff R. .... PA36
- Heimala P. .... D2-4
- Heinig K. .... B3-2
- Hemanth S. .... D6-4
- Herardot E. .... PD71
- Hersch R. .... C6-3
- Herth E. .... PD71
- Hesse J. .... D6-4
- Heyderman L. .... C4-5
- Heyroth F. .... A9-3, PA15
- Hierold C. .... C8-2, PB87
- Higo Y. .... PC155
- Higurashi E. .... PB80, PC151
- Hilleringmann U. .... PC10
- Hinoki A. .... PB76
- Hirai Y. .... A3-3, PA41, PA42,  
..... PC133
- Hirano T. .... PC27
- Hirohata A. .... PB10
- Hoekman M. .... D2-4
- Hofmann M. .... PA19, PA64, PA72,  
..... PA73, PB12, PB42
- Hokai R. .... B1-5
- Hokari R. .... PB80
- Holiastou M. .... PC140
- Hollerth C. .... A7-3
- Holmes J. .... D2-1, PB68
- Holz M. .... PA19, PA64, PA72,  
..... PA73
- Holzner F. .... A9-1
- Honda Y. .... A7-4
- Hong D. .... PC137, PC144, PD41
- Hoogerwerf A. .... C2-2
- Hopf R. .... B2-3
- Horiguchi N. .... PA76
- Horn M. .... D6-4
- Horváth B. .... A6-2, B1-1
- Hoshian S. .... B2-2
- Hou J. .... PC50, PC51
- Housiadas A. .... PB73
- Hu J. .... D1-2, PD74
- Hu L. .... PB71, PC19
- Hu R. .... PC20
- Huang B. .... D1-2, PD19, PD68,  
..... PD74
- Huang C. .... PC72
- Huang Y. .... A4-1, PC114
- Huber D. .... D7-3
- Hublot V. .... D5-2
- Hubner J. .... A2-2, PB89
- Hübner R. .... PC15
- Hübner U. .... PA16
- Huffman M. .... PA04
- Huo D. .... PB79
- Huser T. .... PD21
- Hwang C. .... PC21, PC42
- Hwang J. .... C4-3
- Hwang S. .... PB11
- Hwang T. .... PD45
- Hwu E. .... PB28
- Hyun S. .... PC96
- I**
- Iacovella F. .... PB23
- Ihring A. .... PC45
- Iida S. .... PC108, PC112
- Iijima R. .... PC100
- Iijima Y. .... PC125
- Ikota M. .... PA76
- Ilic B. .... PD15
- Im J. .... B9-3
- Indykiewicz K. .... PA22
- Inoue T. .... D6-3
- Ioannou D. .... B4-2
- Ioannou-Souglaridis I. .... PB88
- Ioardache G. .... PC56
- Ionescu A. .... D2-1
- Ishihara M. .... PB10
- Ishii M. .... PC09
- Ishii Y. .... PB46
- Ishii-Teshima M. .... PD72
- Ishikawa Y. .... PC07, PC27
- Ishimaru T. .... PC155
- Islyaykin A. .... PB08
- Ito H. .... PC108, PC112,  
..... PC113, PC120
- Ito T. .... PB65
- Ivanov T. .... PA72, PA73
- Iwana S. .... PC09
- Iwanaka T. .... PC155
- J**
- Jackson E. .... PB10
- Jahani Y. .... D6-1
- Jain S. .... PC149
- Jalaguier E. .... PC02
- Jang J. .... PB31
- Jang K. .... B9-3
- Jansen H. .... A2-2, PA60,  
..... PB89
- Janseng T. .... B8-2
- Jantawong J. .... B8-2, PB39
- Jantzen S. .... PC118
- Jeamsaksiri W. .... B8-2, PB39
- Jeevanandam G. .... A5-2
- Jefimovs K. .... A1-5
- Jehle A. .... A9-1
- Jensen F. .... A2-2, PB89
- Jeong M. .... PB05
- Jermann J. .... PC52
- Jesse S. .... B1-4
- Jiang X. .... PB19, PC33
- Jiang Z. .... PC123, PC124
- Jin L. .... PB02
- Jin W. .... PC19
- Jo Y. .... PC71
- Jobst G. .... D2-4
- Johannes H. .... PA46, PC23
- Johannsen B. .... PD55
- Johari P. .... PC157
- John-Herpin A. .... D2-2
- Jokinen V. .... B2-2, PD54
- Joly R. .... B10-3, PC59
- Jones M. .... C8-3
- Jonker D. .... PA10
- Joseph P. .... PD08
- Juarros A. .... PD37
- Jung B. .... PA53
- Jung D. .... PD34
- Jung H. .... PD45
- Jung J. .... PC144
- Jung K. .... PC12
- Jung S. .... PC71
- Jung T. .... PC143
- K**
- Kabla A. .... PC101
- Kadala K. .... B8-1
- Kafka J. .... D6-4
- Kage A. .... PD16, PD56, PD77
- Kagias M. .... A1-5
- Kahl M. .... A9-2
- Kaiser C. .... A1-1, PA52
- Kakabakos S. .... D2-4, PB44,  
..... PD26, PD40, PD61
- Kaklamani G. .... C3-3
- Kalaitzakis F. .... PA23
- Kalaitzis A. .... PD60
- Kalogirou C. .... PD46
- Kaltsas G. .... PC70, PC105,  
..... PD38

- Kamalakis T.....PC51  
 Kamitsos E.....PC140  
 Kampylafka V.....C8-4  
 Kan X.....PC116  
 Kanaris A.....PD69  
 Kanellopoulou K.....PD69  
 Kang D.....PC04, PC76  
 Kang H.....PB11, PC137, PD41  
 Kang I.....PC05, PC153  
 Kang S.....PB57, PC98  
 Kanioura A.....PD61  
 Kanjilal A.....PC157  
 Kantarelou V.....PB66  
 Kanwal A.....PD15  
 Kaplan A.....PC38  
 Kaprou G.....D6-2, PB53,  
       .....PC63, PD64, PD65, PD83  
 Karakasidis M.....PC140  
 Karakurt A.....PC128  
 Karavasilis C.....PD38  
 Kariyapperuma D.....PC101  
 Karkossa L.....PD55  
 Karoutsos V.....B3-1, PA09,  
       .....PC50  
 Karpik A.....PD09  
 Karsenti P.....PC32  
 Karvinen P.....PA54  
 Karydas A.....PB66  
 Kassavetis S.....PA78  
 Kastania A.....D6-2  
 Kastl C.....C9-2  
 Kato A.....PC62  
 Katsikini M.....B9-2  
 Katzmayr I.....D6-4  
 Kawabe T..PC58, PC62, PC65  
 Kawata H.....PA41, PA42  
 Kazazis D.....A1-3, A1-4, A5-5,  
       .....C2-4  
 Kazazis S.....PC53  
 Keathley P.....C7-3  
 Keegan A.....PC132  
 Kefallinou D.....PD18, PD79  
 Kehagias N.....A8-2, B8-3,  
       .....PB59  
 Kehagias T.....PB73  
 Kekou V.....PC66  
 Keller S.....D1-3, D4-2, PA11,  
       .....PA34, PB32  
 Kellner K.....PD32  
 Kelp G.....PC82, PD63  
 Kent N.....A4-1  
 Kerasidou A.....PC84  
 Kern D.....B3-3, C6-1  
 Khan B.....PC15  
 Khan H.....PD04  
 Khmyrova I.....PC145  
 Kholopova Y.....PC145  
 Kilikoglou V.....PC140  
 Killge S.....C2-4  
 Kim B.....B6-4, PB17, PB43  
 Kim C.....PB11  
 Kim D.....PB05  
 Kim G.....PC01, PD04, PD34  
 Kim H.....PB17, PB43, PC05,  
       .....PC144, PC153, PD10  
 Kim J.....PB17, PB57, PC42,  
       .....PC104  
 Kim K.....A10-4, PA05, PA26,  
       .....PB57, PC12  
 Kim M.....B9-3  
 Kim P.....PA26  
 Kim S.....PC01, PC21, PC42  
 Kim T.....PC04, P C21, PC36,  
       .....PC42, PC144  
 Kim W.....PC137, PD41  
 Kim Y.....C2-5, C4-3, C5-4,  
       .....C10-1, PC04, PC12, PC36,  
       .....PC54, PC76, PD10, PD41  
 Kimura Y.....C2-5  
 King J.....D3-4  
 Kintzios S.....PD38  
 Kirchner J.....PA19, PA64  
 Kirchner R.....C2-4, PC147  
 Kiriakidis G.....C8-4  
 Kiryushina I.....PB08  
 Kishihara M.....PD67  
 Kishimoto H.....PB60  
 Kister T.....B1-2  
 Kitsara M.....D5-2  
 Klein J.....A4-3  
 Klein S.....B10-3, PC59  
 Klein Y.....C1-2  
 Kletsas D.....PD61  
 Kling R.....B3-4  
 Klösel K.....C8-2  
 Klunngien N.....B8-2, PB39  
 Knickmeier S.....A5-1  
 Kniel K.....PC118  
 Knigge A.....PC28  
 Knuffman B.....B9-1  
 Kobayashi T.....PD67  
 Koch E.....PD07  
 Koczwara C.....PB51  
 Kohl M.....C1-3  
 Koike Y.....PB46  
 Koizmi A.....A7-4  
 Kokelmann M.....PC110  
 Kokkinis G.....D6-4  
 Kokkoris G.....PA77, PD64,  
       .....PD65, PD83  
 Kolander A.....A4-3  
 Kolosov V.....PB27  
 Kometani R.....C1-4, PB13  
 Komninou P.....PB73, PC140  
 Komorowska K....PA25, PA59  
 Komuro S.....PC09  
 Kondoh E.....PB02, PC151  
 Konečný M.....PB69  
 Kong F.....D10-4  
 Kongto N.....B8-2  
 Konstantinidis G.....C3-3,  
       .....C8-4, PA45, PB23, PC18,  
       .....PC53, PC139  
 Kontomitrou V.....C3-3, C8-4  
 Kontoyiannis I.....PA74  
 Koo J.....PC103  
 Koops R.....PA75  
 Kopp S.....PA40  
 Kordatos K.....PD46  
 Koritsoglou O.....PC101  
 Korniliou N.....C3-3  
 Kosel J.....PD52  
 Kosku Perkgoz N.....PB67  
 Kostoglou N.....PB51  
 Kostopoulos A.....C8-4  
 Kottmeier J.....PD13  
 Kötz M.....C1-3  
 Koukoravas T.....PD23  
 Koukouvino G.....PD26  
 Koutsis T.....PC70  
 Koutsourelis M.....PC139  
 Kouvara D.....PD64  
 Kouvatsos D.....PB22  
 Kovalchuk A.....PC145  
 Kowal D.....PA25  
 Kowalsky W.....PA46, PC23  
 Koyama M.....PA42  
 Kraft M.....PD49  
 Kraus T.....B1-2  
 Krause M.....PC78  
 Kravchenko I.....B1-4  
 Krieghammer G.....D6-4  
 Krielaart M.....C2-1  
 Krikscikas V.....PC86  
 Krippendorf F.....PC142  
 Krischer K.....PC88  
 Kristensen A.....PA11  
 Kristensen M.....D4-2  
 Kristiansen M.....B6-2  
 Kristiansen P.....PD09  
 Krüger J.....B10-1  
 Kruit P.....A5-2, C2-1  
 Kruck T.....PB50  
 Kryou C.....PD60  
 Krzysteczk P.....PC154  
 Kulha P.....PC122  
 Kumke M.....PA55  
 Kunicki P.....PB87  
 Kurashima Y.....PC151

# Authors' Index

- L**
- Kurata N..... PC03
  - Kurihara K..... B1-5, PB80
  - Kurosu H..... PC99
  - Kuwano H..... PC86
  - Kuykendall T..... C9-2
  - Kwoka K..... PB87, PC136
  - Kwon J..... PB17
  - Kwon S..... PD34
- M**
- Lesher-Perez S..... PD21, PD22, ..... PD82
  - Letzkus F..... PC142
  - Li D..... PB59
  - Li J..... PB30, PB34, PB35, ..... PD29, PD63
  - Li L..... PB19
  - Li R..... D10-4
  - Li S..... PC34
  - Li T..... C6-2, PB03, PC119
  - Li W..... PC34
  - Li X..... A5-5
  - Li Y..... PC39, PC127
  - Liang C..... PC34
  - Liddle J..... PB21, PD15
  - Lidorikis E..... PA77
  - Lim G..... PA05
  - Lim H..... PC104, PD34
  - Limongi T..... D3-1
  - Lin C..... B6-1, D2-3
  - Lin F..... PC72
  - Lin P..... PC93
  - Lin X..... PD29
  - Lin Y..... D8-1
  - Lippert T..... A4-1
  - Liu H..... PC114
  - Liu J.PB62, PB63, PB64, PC81
  - Liu M..... PC119
  - Liu R..... PB71, PC19
  - Liu X..... PD58
  - Liu Y..... D1-2, PC50, PC51, ..... PC72, PD58
  - Livengood R..... A7-2, B9-1
  - Llobet J..... PD59, PA62
  - Lofrumento D..... A5-4
  - Lohse M..... D6-4
  - Lokhanin M..... PD03
  - Lombardi P..... PC92
  - Lombardo J..... PC24
  - Lonetti B..... PD08
  - Loosen P..... A1-1
  - Lopatin S..... D3-1, D8-2, PC55
  - Lorenz P..... PA38, PC45
  - Lorestani F..... D7-3
  - Lorusso A..... PC50
  - Lorusso G..... A3-1, PA76
  - Lotters J.C..... PC134
  - Lötters J..... C1-2, PA65, ..... PC146, PD01
  - Lotty O..... D2-1
  - Loukas C..... D6-2
  - Low H..... PA35
  - Lu J..... PD47, PD63
  - Lu W..... PC49
  - Ludvigsen E..... PA11, B2-4, ..... B4-4
  - Lukic L..... B7-1
  - Lukichev V..... PA68
  - Lundy R..... PB01
  - Luo G..... PC39, PC127
  - Luo X..... PB84
  - Ly M..... A7-2

- |   |   |   |
|---|---|---|
| Martiel I.....PD09                                | Mertens H.....PA76  | Mortelmans T.....A5-5                                 |
| Martinelli E.....D9-2                             | Mesnilgrente F.....PD12   | Morton K.....B7-1                                     |
| Martinez C.....C10-4                              | Messerschmidt M.....PA56  | Mosgaard M.....D1-3                                   |
| Martínez I.....PC78                               | Metz D.....PC118  | Moustakas K.....PA07                                  |
| Martinez-Rivas A.....PB70,<br>.....PC87           | Meyers T.....PC10   | Moya A.....C10-4                                      |
| Martini F.....PC41                                | Miakonikh A.....PA66, PA67,<br>.....PA68, PC16                                  | Mpatzaka T.....PA52, PB57                             |
| Martinie S.....PC02                               | Michelakis K.....C3-3   | Mruczkiewicz M.....PA18                               |
| Martins S.....PA62                                | Mielnik M.....PC149   | Muehlberger M....PA39, PA44,<br>.....PC78, PD14, PD28 |
| Marumo T.....PA28                                 | Mihailovic I.....C8-2   | Mueller C.....PA46                                    |
| Marzec M.....B9-4                                 | Mihi A.....A10-3  | Muendlein M.....PC48                                  |
| Mastellos D.....PB53, PD83                        | Milionis A.....B2-3   | Mühlberger M.....B5-4, D4-4,<br>.....PA40, PC122      |
| Mastronardi V.....C5-2, PC92,<br>.....PC97, PC121 | Min S.....PC34  | Mukherjee S.....PD15                                  |
| Masu K.....PC108, PC112,<br>.....PC113, PC120     | Minami H.....PB77   | Müller B.....B6-2                                     |
| Masuda Y.....PC125                                | Mincuzzi G.....B3-4   | Müller C.....PD73                                     |
| Matalla M.....PC28                                | Mineta T.....C2-5, PC125,<br>.....PC126   | Müller L.....PD55                                     |
| Mathioulakis D.....PB54                           | Minne S.....D7-3  | Müllertz A.....D1-3, D4-2                             |
| Matsumae T.....PC151                              | Miranda A.....PB72  | Mun J.....A10-4                                       |
| Matsumoto H.....PA29, PA32                        | Mirmohammadi S.....B2-2   | Muñoz-Aguirre N.....PB70                              |
| Matsumoto Y.....PB77                              | Mishra H....B4-3, PB45, PB47  | Murayama M.....PC09                                   |
| Matsumoto-inoue T.....PD67                        | Misiakos K.....D2-4, PD40   | Murillo G.....C10-4                                   |
| Matsushima M.....PC58,<br>.....PC62, PC65         | Mitropoulos C.....PD26  |   |
| Mattei F.....D9-2                                 | Mitsakakis K.....PD55   |   |
| Matuskova B.....PA06                              | Mitteramskogler T.....D4-4,<br>.....PA39, PA40, PC78, PC122,<br>.....PD14, PD28 |   |
| Matylitskaya V.....PD35                           | Mitterer C.....PB51   |   |
| Maurer J.....B1-2                                 | Miyake K.....B1-5   |   |
| Maurer P.....D3-4                                 | Miyashita Y.....PA41  |   |
| Mavrikou S.....PD38                               | Mizubayashi W.....PC07  |   |
| Maximov I.....PA04, PA43,<br>.....PC145           | Mizukami Y.....PD56   |   |
| Mayama H.....PB41, PB76                           | Modreanu M.....C8-4   |   |
| Mayer A.....PA33, PA36,<br>.....PA38              | Moe S.....PC149   |   |
| Maziz A.....PD12                                  | Mogi K.....D6-3   |   |
| Mazza G.....PD32                                  | Mohammadi M.....PD54  |   |
| Mazzucato S.....PA09                              | Mohammed O.....PC55   |   |
| McEvoy N.....PB20                                 | Moharana A.....B5-4, PA40,<br>.....PA44   |   |
| McMillan A.....PD22, PD82                         | Mokarian P.....PB38   |   |
| Meananeatra R.....PB39                            | Mokarian-Tabari P.....PB20  |   |
| Mehold S.....PA19, PA64,<br>.....PA72, PA73       | Mol J.....B1-4  |   |
| Meents A.....PA54                                 | Monroy E.....PC53   |   |
| Megaridis C.....PD23                              | Montis C.....PD08   |   |
| Meinen S.....PD13                                 | Monville C.....PD71   |   |
| Meinhart C.....D7-3                               | Moon J.....PC04   |   |
| Melamed S.....PC101                               | Moon Y.....PC01   |   |
| Melenev A.....PD03                                | Moreau J.....PC30, PC32   |   |
| Mellor C.....B7-2                                 | Moreira E.....C4-2  |   |
| Memos G.....PA77                                  | Moreno F.....PD37   |   |
| Mencattini A.....D9-2                             | Moretti M.....A5-3, D3-1, D8-2  |   |
| Meng F.....PC39                                   | Mori T.....PA02, PC07   |   |
| Menguelti K.....B10-3, PC59                       | Morizur L.....PD71  |   |
| Merino S.....B8-3, PD37                           | Morris D.....PC32   |   |
| Merlos A.....PD30                                 | Morris M....A6-4, PA48, PB01,<br>.....PB20, PC132                               |   |

# Authors' Index

- N**
- Ninou A.....PB88
  - Nioras D.....PB52, PB55
  - Niro G.....PC97
  - Nishida H.....PB13
  - Nishidate Y.....PC145
  - Nishikawa H.....PB46
  - Nishino T.....PB41, PB76, PB77, PC155
  - Nishitani T.....A7-4
  - Nissinen V.....PA54
  - Nitta K.....PC108
  - Nojiri Y.....PB46
  - Nõlvak A.....PC82
  - Noma H.....PC58
  - Normand P.....PA23
  - Nouvertné F.....A9-2
  - Novais A.....PC135
  - Nowak E.....PC02
  - Ntouskas S.....PD83
  - Nuck M.....A4-3
  - Nurk G.....PC82
- O**
- Obitani K.....PC67
  - Offenhaeusser A.....PD78
  - Ogasawara T.....PC13
  - Oguchi H.....PC86
  - Oh H.....A10-4, PA05
  - Oh J.....C4-3, C5-4, PC144, PA70, PB57, PC12
  - Ohashi T.....PA76
  - Ohkouchi T.....PC13
  - Oikonomidis N.....PC150
  - Oikonomou P.....PC56, PD27
  - Oka H.....PC07
  - Okabe T....PA29, PA30, PA32
  - Okada I.....PB10
  - Okamoto S.....PD62
  - Okamoto T.....PB65
  - Okulova N.....B4-4
  - Onishi Y.....A3-3
  - Öper M.....PB67
  - Ordonezloza J.....A5-3
  - Ören S.....C5-5
  - Orhan E.....PC128
  - Orłowska K.....PC131, PC136
  - Osmani B.....B6-2
  - Osmond J.....A10-3
  - Ota M.....PC27
  - Otraduy D.....PD37
  - Otero N.....PD59
  - Oura M.....PC13
  - Owen J.....A6-3, A9-4, PA49,
  - Oya T.....PC03, PC91, PC100
  - Ozerin Y.....PB08
- P**
- Padeste C.....A5-5, PD09
  - Padmanabhan S.....D1-1
  - Paivana G.....PD38
  - Pajor-świerzy A.....PB16
  - Pakendorf T.....PA54
  - Pallandre A.....PD02
  - Paloura E.....B9-2
  - Pan J.....PB32, PC39, PC127
  - Pan L.....PC31
  - Pan R.....PB30, PB35
  - Panagiotidis E.....PB78, PB81
  - Panaitov G.....PD78
  - Pandey G.....PD16
  - Pang S.....D10-3
  - Panos S.....PA78
  - Papachristopoulou K.....B3-1, PC50, PC52
  - Papademetriou A.....B3-1
  - Papadimitropoulos G....PB22
  - Papageorgiou G.....B9-2, PA23, PA52, PA75, PB57, PB66
  - Papageorgiou G.P.....PC17
  - Papageorgiou H.....A3-1
  - Papaioannou D.....PC52
  - Papaioannou G.....PC139
  - Papanikolaou N....PB78, PB81
  - Papavarios G.....A3-1, PA74
  - Papenheim M.....PA38
  - Pardon G.....D3-3
  - Paris O.....PB51
  - Park B.....PA05
  - Park C.....PC103
  - Park H.....PB11, PC54
  - Park J....PC143, PC144, PD45
  - Park K.....PD45
  - Parmeggiani M.....B7-4
  - Parrotta E.....D3-1
  - Partel S.....PD35
  - Paszkiewicz B.....PA22
  - Paszkiewicz R.....PA22
  - Patsalas P.....PA78
  - Patsiouras L.....C4-4, PC63
  - Pattamang P.....B8-2, PB39
  - Paul P.....A9-1
  - Paulsen M.....PC154
  - Pawlowski R.....PB16
  - Peaker A.....PC09
  - Pedersen D.....PA11
  - Pedersen N.....PA11
  - Pedrini J.....C9-2
  - Peixoto R.....A7-1
  - Pelekanos N.....PC53, PC89
  - Pello J.....D6-1, PB85
  - Peña G.....PA54
  - Pennathur S.....D7-3
  - Perdigones F.....PD57, PD64
  - Perelló-Roig R.....PC14
  - Perez-Murano F.....C8-1
  - Permyakova O.....PC16
  - Perrone A.....PC50
  - Persico A.....PC02
  - Peter D.....A9-1
  - Petersen C.....A4-1
  - Petersen R.. D1-3, D4-2, PA34
  - Petit-Etienne C.....PA45
  - Petkov N.....D2-1
  - Petrillo A.....PC24
  - Petrou P.....PB44, PD26, PD40, PD83 PD61
  - Petrovszki D.....PD44
  - Petruzzelli V.....PC38
  - Pettinari G.....PC35 , PC41
  - Peyrade D.....D9-1, PD39
  - Pezard J.....PC60
  - Pezeshki H.....B7-2
  - Piasecki T.....PB87, PC131, PC136
  - Picard E.....D9-1, PD39
  - Picone A.....PB07
  - Pilecky M.....PD32
  - Pinakidou F.....B9-2
  - Piredda G.....PC48
  - Piro L.....PC97
  - Pirri C.....B7-4, D8-2, PC152
  - Pirri F.....D4-2, PC75
  - Pisanello F.....A5-4, A7-1, C5-2, C6-4, D5-1, D10-1
  - Pisanello M.....A5-4, A7-1, C6-4, D10-1
  - Pisano F.....A5-4, A7-1, C6-4, D10-1
  - Pitingolo G.....D1-2, PD19, PD68
  - Plank W.....PC48
  - Plaza J.....C4-1, PD73
  - Polaki S.....PC61
  - Polesel J.....B10-3, PC59
  - Polimeni A.....PC35
  - Politi C.....PA09
  - Polychronopoulou K.....PB51
  - Posniecek T.....PD32
  - Poulikakos D.....B2-3
  - Pourdavoud N.....PA36
  - Pourteau M.....B3-2
  - Prabakar K.....PC61
  - Prajapati A.....PA62
  - Prehal C.....PB51
  - Price R.....PC101
  - Pricl S.....D8-2

- Prifti V.....PC84  
 Primavera R.....D1-1  
 Prochukhan N.....PC132  
 Pruchnik B.....PC131  
 Prucnal S.....PB26, PC15  
 Pruitt B.....D3-3  
 Pruneri V.....D6-1, PB85  
 Psycharis V.....B9-2  
 Psyrris A.....PC70  
 Pu D.....PC123  
 Purr F.....PD33  
 Pyka N.....A9-3
- Q**
- Qiu Z.....PC19  
 Qualtieri A.....C5-2, C6-4,  
 .....PC37, PC38, PC92, PC97,  
 .....PC121  
 Quero J.....PD57, PD64  
 Queste S.....PC138
- R**
- Rademaker G.....B3-2, C8-1  
 Rademakers T.....D3-4  
 Rainer A.....C2-3  
 Ramírez Salinas M.....PC87  
 Ramiro J.....B8-3  
 Ramos I.....D6-4  
 Randall J.....A6-3, A9-4, PA49  
 Rangelow I.....A2-4, PA19,  
 .....PA64, PA72, PA73, PB12  
 Raptis I.....D2-4, PD40, PA52,  
 .....PB57, PB78, PC56,  
 .....PD26, PD27  
 Rastjoo S.....C1-3  
 Raveh A.....A7-2, B9-1  
 Rebholz C.....PB51  
 Rebohle L.....PB26  
 Reid G.....PB68  
 Reina M.....PD73  
 Reker J.....PC10  
 Ren J.....PC64, PC123  
 Ren T.....PC95  
 Ren Z.....PA61, PC64  
 Retozala A.....B8-3, PD37  
 Reum A.....PA72, PA73  
 Reuter C.....PA19, PA64, PA72  
 Revet G.....D5-2  
 Reynolds J.....PC08, PC20  
 Rezaei B.....PB32  
 Rezvanov A.....PA66  
 Rhallabi A.....PA63  
 Ricciardi C.....D8-2  
 Richter A.....PC147  
 Richter K.....C2-4  
 Richter T.....A9-2
- Riedl T.....PA36  
 Riesco R.....D9-3  
 Riley C.....PB58  
 Rizzi F.....D1-1, C5-2, PC97,  
 .....PC121  
 Rizzo A.....A5-4, D1-1  
 Robert L.....PC138  
 Roberts B.....B5-3  
 Rocha L.....C4-2  
 Rodchanarowan A.....B8-2  
 Roeffaers M.....PD22  
 Rofaani E.....D1-2, PD74  
 Rogozhin A.....PA67, PA71,  
 .....PC16  
 Rola K.....PA25, PA59  
 Roman C.....PB87  
 Romano L.....A1-5  
 Romano S.....PC75, PC152  
 Römer F.....C7-2  
 Romero P.....PD59  
 Rommel M.....B3-2  
 Rond J.....PA36  
 Ronda A.....B10-2  
 Rosales Hernández A.....PB70  
 Rothbauer M.....PA44  
 Rougé P.....PD39  
 Roux C.....PD08  
 Rowlinson B.....PC08  
 Rüb M.....PC142  
 Rubini S.....PC35  
 Rudenko K.....PA66, PA67,  
 .....PA68, PC16  
 Rudorf R.....PC110  
 Rumpler M.....D6-4  
 Rusli N.....PD49  
 Rutigliani V.....A3-1  
 Rutkowski J.....PB48  
 Ruttloff S.....D6-4  
 Ryazanov V.....PA23  
 Ryckaert J.....A2-1  
 Rydzek G.....PB38  
 Rysz J.....B9-4  
 Ryu H.....PC21, PC42, PC43  
 Ryu J.....PC76  
 Ryu S.....PA70
- S**
- Sabatini B....A5-4, A7-1, D10-1  
 Saccone M.....A4-1  
 Sadeghi P.....PB09  
 Sadewasser S.....PC77, PC80  
 Sadílek J.....PB69  
 Saegusa S.....PC13  
 Saiki T.....PC13  
 Saji A.....PC99  
 Saka N.....PD56
- Sakata R.....PA41  
 Sakellaropoulos D.....PC14  
 Sakellis E.....PD46  
 Sakurai I.....PB10  
 Salama K.....PC56  
 Salapatas A.....D2-4  
 Salaseviciene A...PD50, PD53  
 Salleras M.....PC68  
 Salvalaglio M.....B10-2  
 Šamořil T.....PA20  
 Samukawa S.....PC07  
 San Paulo A.....PD73  
 Sanchez A.....C4-1  
 Sanders R.....PB40  
 Sanopoulou M...PC56, PC66,  
 .....PD27  
 Santamaria G.....D3-1  
 Santini R.....A6-3, A9-4  
 Santra T.....PD77  
 Sar H.....PB67  
 Sarathy M.....A5-3  
 Sarkiris P.....PB54  
 Sato D.....A7-4  
 Sato K.....PA30, PC09  
 Sato T.....PC125  
 Sawai S.....PD77  
 Scalia A.....PC75  
 Scalora M.....PC37  
 Scaltrito L.....PC75, PC152  
 Scepka T.....PA18  
 Schantz M.....A6-3  
 Scheer H.....PA33, PA36,  
 .....PA38  
 Schiavoni G.....D9-2  
 Schift H.....A1-5, A6-2, B1-1,  
 .....B6-2  
 Schirmer M.....A1-1, A9-3,  
 .....PA06, PA15, PA16, PA52,  
 .....PA55  
 Schlachter F.....PB38  
 Schleunitz A.....A4-3, PA56  
 Schmid S.....PB09, PC47  
 Schmidt G.....A9-3, PA15  
 Schmidt H.....PC45  
 Schmidt M.....C8-4  
 Schneider S.....PD36  
 Schofield S.....A1-3  
 Scholl A.....A4-1  
 Schotter J.....D4-4, PA39,  
 .....PD28  
 Schranzhofer L.....B5-3  
 Schrittweiser S....D4-4, PA39,  
 .....PD28  
 Schuller P.....PA44  
 Schut T.....C1-2, PC146  
 Schut T.V.P.....PC134  
 Schwartzberg A...A2-4, C9-2

# Authors' Index

Schwarzkopf A.	B9-1	Singh M.	PD33	Stett A.	PC110
Schwerter M.	PC115	Sinuraya W.	PC08	Sthijns M.	D3-4
Sciurti E.	D1-1	Sinzinger S.	PA56	Stobbe S.	PA21, PC46
Scordo G.	PC75, PC152	Siopa D.	PC77	Stock T.	A1-3
Scotti G.	C3-2	Skaltsounis P.	PD65	Stokeley K.	PA61
Secme A.	D3-2	Skorenski M.	PA25	Stollenwerk J.	A1-1
Sedaghat Pisheh H.	D3-2	Skotadis E.	C4-4, PC63	Stomeo T.	C6-4, PC37, PC38
Segkos A.	PD46	Smiglak M.	PA25, PA59	Strehle S.	PA01
Segura J.	PC14	Smolka M.	D6-4	Strempel K.	C7-2, C9-3, PA17
Seitl L.	B3-3	Smyrnakis A.	B4-2, D6-2	Stricher R.	B10-4
Sekiguchi A.	PB41, PB76, PB77, PC86	Smyrnioti E.	PC52	Stroj S.	PC48
Selkirk A.	PB20	Snitka V.	PD50, PD53	Suárez T.	C4-1
Seok O.	PC04, PC05	Socha R.	PB16	Súchil Pérez O.	PC87
Seong W.	PC137, PD41	Sohn S.	PB17	Sudiarmanto	PC151
Sergio S.	D5-1	Sojic N.	PD12	Sugawara H.	PA31
Shahbeigi Roudposhti S.	PB12	Solak H.	A1-5	Sun A.	D2-5
Shalev G.	PA62	Soler M.	D2-2	Sun K.	PC20
Shamkhalianehar H.	D10-2	Soltys J.	PA18	Sung C.	PC21
Shapoval S.	PC145	Sommer R.	PC02	Suntalelat S.	B8-2, PB39
Sharma C.	B2-3	Son J.	PA53	Supadech J.	PB39
Sharma M.	PC35	Sone M.	PB84, PC99, P .....C108, PC112 , PC113,PC120, .....PD31	Supreeti S.	PA19
Shawrav M.	PC47	Song J.	PC21, PC42, PC43	Suzuki K.	PC113
Sheen G.	PC06	Song S.	PD41	Švarc V.	PB69
Shi J.	D1-2, PD19, PD74	Sonnleitner M.	D6-4	Svetovoy V.	PD03
Shi Y.	PC31	Sotomayor Torres C.	B8-3	Swett J.	B1-4
Shi Z.	A1-5	Souleille S.	A4-2	Swift M.	D3-3
Shibata T.	PD16, PD56, PD72, PD77	Sousa P.	PD59	Syed A.	PC56
Shields B.	PA14	Spagnolo B.	A5-4, A7-1, .....D5-1, D10-1	Szczęch M.	PD42
Shikazono N.	PA30	Spandonidis C.	PC150	Szczepanowicz K.	PB16, .....PB50, PD42
Shikida M.	PC58, PC62, .....PC65	Sparreboom W.	PD01	Szornel J.	A2-4
Shimizu T.	C2-5, PB65, .....PC126	Spende H.	C7-2, C9-3	Szpecht A.	PA59
Shimohira C.	PC65	Sripumkhai W.	B8-2, PB39	Szymanowska P.	PC136
Shin D.	PB57	Sriram K.	D8-1		
Shin H.	PA53, PD10	Staab J.	PA36		
Shingubara S.	PB65	Stadlober B.	D6-4		
Shioda A.	PB02	Stahlberg H.	A5-5		
Shirai M.	PA41, PA42	Stampanoni M.	A1-5		
Shiraishi K.	PC09	Stanca S.	PC45		
Shiratori S.	PB37	Starke G.	A5-1		
Shiu M.	B7-1	Stassi S.	D8-2		
Shon J.	PC01	Stathopoulos C.	PC52		
Shoshi A.	D4-4, PA39, PD28	Staufer U.	D7-2		
Shvets G.	PD63	Stavriniidis A.	PA45, PB23, .....PC18		
Si S.	PA56, PB42	Stavriniidis G.	C3-3, PC53, .....PC139		
Sidorov F.	PA71	Steele A.	B9-1		
Sierakowski A.	PC131, PC136	Steffen M.	PA55		
Šikola T.	PA20, PB69	Steglich T.	PA55		
Sileo L.	A5-4, A7-1, C6-4	Stehr M.	PD33		
Silhanek A.	PC24	Stein M.	PC118		
Silvestre C.	PA60	Steinbach T.	PC142		
Simon A.	D5-2	Steriotis T.	PB51		
Simon C.	PB50				

## T

Tabata O.	PC133
Taboryski R.	B2-4, B4-4, .....B6-3
Tada K.	PA41
Takada N.	D6-3
Takagi H.	PC151
Takama N.	B6-4
Takase K.	PB65
Takeuchi M.	PD67
Takigawa R.	PC156
Takishita K.	PD56
Tamm A.	PC82
Tampaxis C.	PB51
Tan S.	A7-2, PC89
Tanagi K.	PD16
Tanaka K.	C1-4, PD56
Tanaka M.	PC125
Tang H.	PC108
Tanigawa H.	PB41, PB76, .....PB77, PC155

- Taniguchi J. .... PA28, PA29,  
..... PA30, PA31, PA32  
 Taniguchi K. .... PC58, PC62,  
..... PC65  
 Tanner M. .... PD44  
 Tantussi F. .... C9-1  
 Tao Z. .... A2-1  
 Tarancón A. .... PC68  
 Tas N. .... PA10, PB40  
 Tatarintsev A. .... PA67  
 Tätte T. .... PC82  
 Taus P. .... PC47  
 Taylor H. .... B8-1, PB58  
 Telecka A. .... B2-4, B4-4  
 Terborg R. .... D6-1, PB85  
 Tessarollo F. .... PC122  
 Testa P. .... C4-5  
 Tez S. .... C10-3  
 Thanner C. .... A8-3, PA27  
 Theodorakos I. .... PC101  
 Theodosiou A. .... PA78  
 Thesen M. .... A4-3, D6-4,  
..... PA56  
 Thibault C. .... A4-2  
 Thomée E. .... PD82  
 Thomopoulos G. .... PB52, PB55  
 Thongsook O. .... B8-2, PB39  
 Tian I. .... PC123  
 Tiggelaar R. .... PA10  
 Tiron R. .... B3-2, C8-1  
 Tittl A. .... D2-2  
 Tokuoka K. .... PC99  
 Toma A. .... C9-1, PC38  
 Toma F. .... C9-2  
 Tomal W. .... PB50  
 Tong J. .... C6-2  
 Tong Y. .... PD29  
 Tonooka Y. .... PC27  
 Töpper T. .... B6-2  
 Tören P. .... D6-4  
 Torre B. .... D3-1, D8-2, PC26,  
..... PC44, PD52  
 Tourlouki K. .... PA08  
 Traksele L. .... PD50, PD53  
 Treiblmayr D. .... A8-3  
 Truckenmüller R. .... D3-4  
 Tsagaraki K. .... C3-3, C8-4,  
..... PB23, PB25, PC18  
 Tsakiridis O. .... PD38  
 Tsamis C. .... PC84, PC105,  
..... PD46  
 Tsanev T. .... PC74  
 Tsaousis V. .... PD26  
 Tse C. .... PB31  
 Tselekidou D. .... PA78  
 Tseng L. .... A1-3, A1-4  
 Tseng Y. .... C9-4  
 Tserepi A. .... B4-2, D6-2, PB53,  
..... PC63, PD18, PD61, PD64,  
..... PD65, PD79, PD83  
 Tsigkourakos M. .... PB73  
 Tsougeni K. .... D6-2  
 Tsoukalas D. .... C4-4, PB73,  
..... PC14, PC63, PC140  
 Tsounidi D. .... PD26  
 Tsouti V. .... PC66, PD69  
 Tsoutis K. .... PD69  
 Tsuchiya T. .... PC67, PC133  
 Tsuji K. .... C2-5  
 Tu Z. .... D10-4  
 Tuji K. .... PC126  
 Tukkineniemi K. .... D2-4  
 Turchetti M. .... C7-3  
 Turover D. .... PA63  
 Tzaneva B. .... PC74  
 Tzianou M. .... PB52, PB55
- U**
- Uchida H. .... PB76  
 Uchida K. .... PD72  
 Uddin R. .... PD54  
 Uggowitzter M. .... B2-3  
 Uhrmann T. .... PA06  
 Ukita Y. .... PD62  
 Ullah A. .... PD04  
 Ulliac G. .... PC138  
 Uraoka Y. .... PC25  
 Uslu D. .... D3-2  
 Utsumi J. .... PC156  
 Utsumi Y. .... PB10, PC13, PD67  
 Uvarov I. .... PD03
- V**
- Vainos N. .... B3-1, PA07, PA09,  
..... PC50, PC51, PC52  
 Valamontes E. .... PC56  
 Valdez-Pérez D. .... PB70  
 Valkai S. .... PD44  
 Vamvakaki M. .... A10-1, PD27  
 Vamvakas V. .... PA52  
 Van Blitterswijk C. .... D3-4  
 Van Boekel W. .... PC80  
 Van Deelen J. .... PC80  
 Van Der Velden G. .... D7-2  
 Van Dijken S. .... A4-1  
 Van Goozen Y. .... A5-2  
 Van Houselt A. .... PA10  
 Van Putten J. .... PD01  
 Van Roey F. .... A3-1  
 Van Tol R. .... A5-2  
 Vanetsev A. .... PC82  
 Vargkas E. .... PC63  
 Vaut L. .... PB28  
 Veigang-Radulescu V. .... C8-3  
 Veilleux G. .... B7-1  
 Vekinis A. .... PB86  
 Veres T. .... B7-1  
 Verna A. .... B7-4  
 Vernoux C. .... PC29  
 Vertchenko L. .... PB79  
 Vetrova I. .... PA18  
 Viasnoff V. .... PA35  
 Vidal S. .... PD59  
 Videkov V. .... PC74  
 Vidor F. .... PC10  
 Vieira De Castro J. .... B8-3  
 Vigne A. .... PD21  
 Vila-Comamala J. .... A1-5  
 Vincentini I. .... PD49  
 Vishnevskiy A. .... PA66  
 Vogler M. .... A4-3  
 Voigt A. .... A4-3, B10-2  
 Voigt P. .... PA16  
 Volkmann N. .... D3-3  
 Von Borany J. .... B3-2  
 Von der Heide C. .... PC94  
 Vona G. .... C2-3  
 Voss M. .... PB28  
 Vourdas N. .... PB52, PB55,  
..... PD18  
 Vrettou F. .... PB44
- W**
- Waag A. .... C7-2, C9-3, PA17  
 Wagner L. .... PD32  
 Walger T. .... C6-3  
 Wan D. .... D2-5  
 Wang C. .... C8-3, PC107,  
..... PC114, PD15, PD66  
 Wang L. .... D1-2, PD19, PD68,  
..... PD74  
 Wang P. .... PC39, PC127  
 Wang Q. .... PC31  
 Wang S. .... PC49  
 Wang T. .... C5-1, PC116  
 Wang W. .... PC57  
 Wang X. .... PB29  
 Wang Y. .... B7-4, C6-2, PC72  
 Wang Y. .... C6-2, PB03, PC119  
 Wang Z. .... PC31, PC56  
 Wanzenboeck H. .... PA44,  
..... PC47  
 Warisawa S. .... C1-4, PB13  
 Warszyński P. .... PB16, PB50,  
..... PD42  
 Wasisto H. .... C7-2, C9-3, PA17  
 Watanabe H. .... PC112  
 Watanabe T. .... A1-2

# Authors' Index

- Weaver J.....PC117  
 Weber A.....C4-5  
 Weeber J.....PC29  
 Wehmann H.....C7-2  
 Wei X.....PC64, PC123, PC124  
 Weidenfeller L.....PA19, PA64, PA73  
 Weigel W.....D6-4  
 Weinhart M.....PA06  
 Weis W.....D3-3  
 Wennberg A.....PC78  
 Wenzel H.....PC28  
 Werder J.....A6-2  
 Wetzel A.....B6-3, PB79  
 Weyers M.....PC28  
 Wiegerink R.....C1-2, PA65, PC134, PC146, PD01  
 Wiesbauer H.....A8-3  
 Witters L.....PA76  
 Witzigmann B.....C7-2  
 Wolf J.....A4-3  
 Wong H.....PA35  
 Woo C.....PC96  
 Woo K.....C10-1  
 Wu D.....PC31  
 Wu L.....B6-4  
 Wu S.....PB18  
 Wu T.....PD29  
 Wu X.....C5-4, PC95
- X**
- Xiao M.....PC107  
 Xie S.....A1-5, A6-2, A7-5, PA12  
 Xie Y.....C7-4, A10-2, PA69, PB26, PD58  
 Xiong H.....PC31  
 Xu J.....C2-5, PC126  
 Xu Y.....D10-3  
 Xuan Z.....PC49
- Y**
- Yachi M.....PC67  
 Yadav P.....PB01  
 Yamada K.....PC13  
 Yamaguchi A.....PB10, PC13, PD67  
 Yamamoto S.....PC25  
 Yamane D.....PC108, PC112, PC113, PC120  
 Yamashita R.....A3-3  
 Yamata A.....PD74  
 Yamazaki A.....PA02  
 Yamazaki Y.....PC133  
 Yanagimachi S.....PC151  
 Yang F.....PC116  
 Yang H.....PA70, PB34  
 Yang J.....PB15, PC93, PC103, PC116  
 Yang S.....B7-4  
 Yang W.....PC39, PC127  
 Yang Y.....C7-3, PB03, PC95, PC119  
 Yang Z.....D2-3  
 Yanik C.....PC128, PC129  
 Yano T.....PA31  
 Yasuda M.....PA41, PA42  
 Ye H.....PB59  
 Yeb Z.....PD66  
 Yeh J.....D8-1  
 Yeo N.....PB05  
 Yescas Gonzalez T.....D9-1, PD39  
 Yesilkoy F.....D6-1  
 Yi M.....C10-1  
 Yoo D.....PC54  
 Yoon G.....PC143  
 Yoon H.....PC71  
 Yoon S.....PC76, PC137, PD41  
 You J.....PC54  
 Yu F.....C7-2  
 Yu H.....PC39, PC127  
 Yu K.....PC54  
 Yu M.....A10-2  
 Yu R.....D2-1  
 Yuan Q.....PC116  
 Yuan Z.....D10-4, PD29  
 Yuksel M.....PC128, PC129  
 Yun S.....PB43  
 Yun T.....PC96
- Z**
- Zaccagnini P.....PC75  
 Zacharaki E.....PA07  
 Zacharatos F.....PC101  
 Zaheer M.....PB71  
 Zaidi S.....C9-3, PA17  
 Zajac A.....PA25, PA59  
 Zajadacz J.....PA38  
 Zandvliet H.....PA10  
 Zekentes K.....PA45  
 Zelmann M.....D9-1  
 Zemlyakov V.....PC145  
 Zenger T.....PA06  
 Zengerle R.....PD55  
 Zeniou A.....PB24, PD18, PD79  
 Zergioti I.....PC101, PC150, PD60  
 Zhai K.....PC57  
 Zhang H.....PC124  
 Zhang L.....A2-1, A7-5, PB62, PB63, PC81, PD47  
 Zhang P.....A5-3, D3-1, D8-2  
 Zhang R.....C2-4, PB59, PC147  
 Zhang S.....A7-5  
 Zhang X.....PC26  
 Zhang Y.....PB63, PB64, PC49, PC127  
 Zhao D.....PA14  
 Zhao H.....PC64  
 Zhao M.....PC57, PC64, PC111  
 Zhao X.....PC09  
 Zhao Y.....PA65, PC134  
 Zhi Y.....PC49  
 Zhikharev E.....PA71  
 Zhong S.....PB62, PB63, PC81  
 Zhou J.....PB62, PB63, PB64, PC81  
 Zhou X.....PC39, PC127  
 Zhou Y.....PC80  
 Zhu J.....A7-5, C5-1, PA12, PB29  
 Zhu M.....A10-1, C7-4, PA69  
 Zhu X.....PA11  
 Zhu Z.....PC34  
 Zhuang C.....PB19  
 Zhuangzhuang W.....PA12  
 Zieger G.....PC45  
 Zimmer K.....PA38  
 Zisis G.....PA52, PA-57, PB78, PB81  
 Zong L.....C7-4  
 Zuo K.....PD29  
 Zwolak M.....PB21

## Notes



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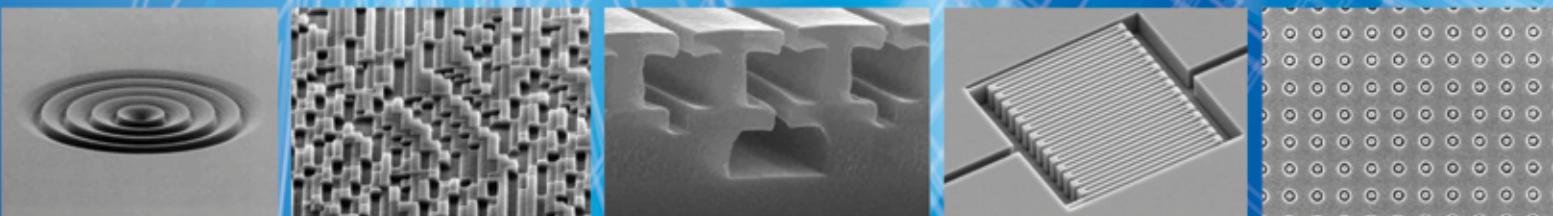
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